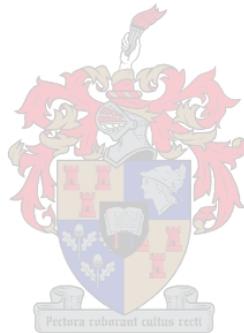


# **Pulse Power Device Characterization For Amplifier Design.**

Paul Fourie.



Thesis submitted in partial fulfillment of the requirements for the degree of Master of Engineering at the University of Stellenbosch.

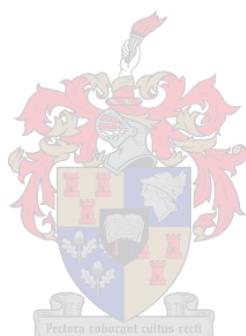
Supervisor: Dr. Cornell van Niekerk.

December 2004

## Declaration

I, the undersigned, hereby declare that the work contained in this thesis is my own original work, unless otherwise stated, and has not previously, in its entirety or in part, been submitted at any university for a degree.

Paul Fourie.



## Acknowledgements

Several people contributed to this work in various ways. It would not have been possible without their help. I would like to thank Dr. Cornell van Niekerk for his help, patience, encouragement and the fact that he never showed he was “gatvol”.

I would also like to thank Reutech Radar Systems who financially sponsored the first year of the work.

Further, I would like to thank Wessel Croukamp, Heinz Preuss and Robert Engelbrecht for their help in building and assembling some of the test setups. A special thanks also to my son Jaco for his help with the writing of the software that was needed at times.

Most of all I would like to thank Almighty God for making it all possible.



## Summary

Keywords: Radar, Class C, power amplifiers, load-pull, pulsed RF, microwave, TRL, MultiMatch, pulse power, device characterization.

Bi-polar Si transistors optimized for pulse conditions is still the most popular choice as amplification element in the final stages of solid-state radar amplifiers in L and S band. With the radar market being small, the design data for these devices is normally fairly limited and it is up to the designers to thoroughly characterize them for their designs. This is normally done through load-pull experiments. Professional automated load-pull equipment is very expensive especially at the higher power levels. In spite of being automated and under computer control, load-pull exercises still is very time consuming and as such expensive. For small companies that only occasionally need to design such amplifiers it is not economically viable to acquire such equipment and different strategies have to be found to stay competitive.

This report investigates such a strategy and its implementation.

A procedure to quickly and accurately characterize such devices was developed and two amplifiers were designed and build with this procedure and compared to their traditional counterparts for verification. The results were very promising and with a bit more work, the technique can likely be used to characterize these devices for design work outside of the parameters designated by the manufacturers.

# Opsomming

Sleutelwoorde: Radar, Klas C, drywings versterkers, lastrek, gepulsde RF, mikrogolf, TRL, MultiMatch, pulsdrywing, toestel karakterisering.

Bipolere Silikon transistors wat vir werking onder gepulsde toestande geoptimiseer is, is nog steeds die mees gewilde keuse as versterkingselement in die finale stadiums van vastetoestand radar versterkers in die L en S bande. Met die radar mark wat geredelik klein is, is die ontwerp inligting vir hierdie elemente gewoonlik redelik karig en is dit die taak van die ontwerpers om die elemente te karakteriseer vir hulle ontwerp doeleindes. Dit word normaalweg gedoen deur lastrek eksperimente. Geoutomatiseerde lastrek toerusting is baie duur, veral as dit onder hoë drywingstoestande moet werk. Al is die toerusting geoutomatiseer en onder rekenaar beheer, is lastrek oefeninge nog steeds baie tydrowend en daarom dan ook baie duur. Vir klein maatskappye wat net nou en dan nodig het om sulke versterkers te ontwerp is dit gewoon nie ekonomies regverdigbaar om sulke toerusting aan te skaf nie, en ander strategië moet gevind word om ekonomies kompetend te bly.



Hierdie verslag ondersoek so 'n strategie en die implementering daarvan.

n Prosedure om gepulsde bipolere transistore vinnig en akkuraat te karakteriseer is ontwikkel en twee versterkers is met die prosedure ontwerp en gebou. Die versterkers is geverifieer deur hulle met hulle tradisionele eweknië te vergelyk. Die resultate lyk baie belowend en met n bietjie meer werk kan die metode waarskynlik ook gebruik word om die transistors buite die toepassings gebied, soos deur die vervaardigers aangedui, te gebruik.

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## 1 Introduction

The goal of this project is to establish an improved design process for solid state high power pulsed RF and microwave amplifiers, suited to mainly radar applications at modest cost that would be affordable for smaller design establishments. The main thrust of the investigation is to find a way to reliably characterize a spectrum of devices over several sets of operating conditions in order to choose the most cost effective line-up for the required amplifier and its associated power supply. The aim is to get round the low frequency instabilities, transition instabilities and pulse length versus peak power tradeoffs with its associated thermal requirements. Once this is achieved, it becomes possible to design the required amplifiers within a short time frame with a high probability to get it right the first time. Cost must also be kept to a minimum.

Solid-state bi-polar power devices for microwave applications became commercially available during the 1970's [3,4,6,21,24]. The most severe restriction on the frequency response of solid-state devices is imposed by the carrier transport time through the different doping regions [8,17]. To work at high frequencies the diffusion lengths has to be as short as possible.

The voltage-current (VI) product however determines the maximum output power of the bipolar junction transistor (BJT) [2,3,11,29]. The maximum current is restricted by the conducting area and conductivity, which is a function of the doping of the layers [8,20,25]. Maximum operating voltage is determined by the Zener breakdown and punch through voltages. However the voltage breakdown depends not only on the nature of the junction involved but also on the external circuit arrangement [20,25]. For example, the breakdown voltage for the common-emitter circuit differs from that of the common base circuit, and the external base impedance influences the maximum operating voltage before breakdown. With the common-base configuration having the

higher breakdown voltage it is the preferred topology for the high power bipolar devices in pulsed mode, in other words for power levels above about 35dBm. Most commercially available packaged devices have then for this reason the base attached to the case of the package.

A bi-polar transistor is punched through if the space charge region of the collector junction reaches the emitter junction before avalanche can take place [8]. A high punch through voltage thus puts a limit on the upper frequency at which the device still has useful gain.

The most common way used by device manufacturers to increase the power capabilities of solid-state microwave devices is to use several transistors in parallel in the same package. (Single cell devices are hardly ever used.) Two methods of achieving a multi-cell topology have been observed:

- Several individual transistors are put down on a very high dielectric constant substrate on which matching and combining pads has been etched.
- The matching and combining pads are made as part of the wafer. By doing this a single basic device can be used in several topologies to create devices covering a few power and frequency bands. However, this means that the associated impedances become very low and there is a matching/ combining network inside the device package over which the amplifier designer has no control. This creates serious problems for wideband work or when an attempt is made to use the device slightly outside of the designated band of operation.

The market for high power radar devices is small, with the result that device manufacturers are not keen on spending money on elaborate testing and device characterization procedures [23]. This is largely left to the end users. (The majority of mass produced high power microwave devices is intended for the communication bands and these do not overlap with the designated radar bands.) Normally the device manufacturers provide a recommended foil pattern for the device with sometimes a few load-pull points included.

Examples of these are reproduced in chapter eight appendix B. If this does not fit into the users mechanical, thermal or power supply constraints; it is up to the user to solve the problem.

## 1.1 Thesis Overview

A literature study was performed to determine how this design process was approached in the past and to determine which routes for future development looked the most promising in the light that, for modern designs to be successful, the design cycle must be short with very few iterations to the final product. In addition, upgrades to the product must be easy.

As a starting point, a high power (Thru, Reflect, Line) TRL test fixture has been designed to accommodate the power load-pull measurements that needed to be made. This test fixture covered from 200MHz to 3GHz with the frequency band of interest being from 1.2GHz to 1.4GHz [12,13,14,15,16]. In conjunction with this test fixture, stub tuners and “biasing T’s” had to be designed [18]. A procedure then had to be developed to efficiently characterize devices.

To do the characterization of the input matches a current transformer and resonating circuit was developed to measure the pulsed collector or drain currents. It was found that this gave a good indication as to when the input was matched at the frequency point in question without having to optimize the output power at the same time [22]. The result of this is that the input and output impedances can be close to independently determined.

Two bipolar devices have been evaluated. The data book foil patterns of the bipolar devices have been implemented and the power output and other characteristics measured. These devices were then characterized with the proposed method, and new foil patterns designed with this data and the output power and other characteristics measured again. The results of the two methods could then be compared.

A driver amplifier to characterize the devices also had to be designed. This was done using a GaAs power FET.

Lately bipolar microwave power devices with power levels in the region of 500W per device with medium pulse lengths ( $\sim 150\mu\text{s}$  at 10% duty cycle) have become available. If one could adjust the biasing voltage levels, these devices could potentially be used for longer pulse lengths at lower output powers and/ or duty cycles. This then also creates the possibility of modular designs with the incorporation of suitable power combiners.

Another new trend is the availability of LDMOS FETs for pulsed microwave applications. These devices are currently becoming available with power levels in the region of 200W with long pulse lengths and duty cycles. ( $>300\mu\text{s}$  at 10% duty cycle). FETs have the nice feature that it is easy to match their gates for pulse power conditions [2,3,29]. Normally the low frequency stability problems can also be taken care of on the gate side of the device [2]. Generally, FETs are also more tolerant to mismatch conditions than bipolar devices. These characteristics make these devices very attractive for pulse power work. By using LDMOS FETs as drivers for high power bipolar devices it should be possible to design very efficient high power pulsed amplifiers.

### 1.1.1 Design Considerations

Tight control of the pulse shape and the associated spectral content are crucial to guarantee the satisfactory performance of radar amplifiers. A device used in class C operation is non-linear, not only over the RF cycle, but also over the pulse envelope cycle [8,11]. Stability of the device must be guaranteed over all these conditions to satisfy the phase and pulse shape requirements of the amplifier.

The high power levels that radar amplifiers operate at means that heat dissipation becomes a serious problem. A further complication of this is that as the device heats up during the first couple of hundreds of nano seconds of the pulse it causes a thermally induced pulse droop, up to about 1.5dB, depending on the geometry, power rating and package of the device. Depending on the system parameters it might require sophisticated feedback, biasing and power supply techniques to counter this effect. High efficiency, adequate heat sinking, proper biasing and

maybe even sophisticated feedback techniques are therefore also crucial for the satisfactory operation of these amplifiers.

For the design of these amplifiers one needs to take more into account than just a set of impedances to be matched as serious consideration must also be given to efficiency, heat dissipation and DC bias control to have control over stability and pulse shape.

### 1.1.2 Device Modeling

Heterojunction Bipolar Transistors (HBT) and lateral diffusion metal oxide semiconductor field effect transistors (LDMOSFET) have become very promising devices for different applications at microwave and millimeter wave frequencies. However, the mainstay of high power semiconductor devices for pulsed applications at L, S and C band is still bipolar junction transistors (BJT).

A useful condition for successful design work is the availability of an accurate large signal model (LSM) for the device intended to be used for the design. In recent years, several publications in respectable journals were devoted to the creation of a standard compact model for use in CAD tools and procedures for the extraction of the parameters needed for use in these models [1,2,3,7,8,22,26,27,28,32 - 45]. Despite the tremendous work already done on the subject we still do not have unified, accurate model standards in industry together with the needed automatic extraction procedures. The reason for this is that the device physics is very complicated, the range of currents to be modeled is broad, and the power densities at which the devices operate is very high. All this together with the thermal conductivity restrictions of the semiconductor materials makes the problem of the creation of a universal LSM for these devices more difficult. Many of the existing models are based on a solid physical background, but again because of the difficulties of the problem they end up with many empirical coefficients, that are difficult to extract. Furthermore, when the model is complicated, an additional difficulty to the extraction problems is that such a model could show problems with convergence.

In the light of the large volume of work done on device modeling, the original tack taken when this project started was then to design and develop circuitry to do pulsed measurements on the targeted devices with the intent to do parameter extraction and to use these parameters then in one of the available CAD tools [1,2,3] to design the intended amplifiers. However, the availability of the needed test equipment and the previously mentioned difficulties forced the abandonment of this idea

### 1.1.3 Current Design and Manufacturing Techniques

The majority of microwave power amplifier designs are implemented using microstrip or coplanar techniques and fin-line at millimeter wave frequencies [2,3,11,24]. The substrates used are normally from 20mil to 60mil thick with relative dielectric constants ( $\epsilon_r$ ) varying from about 2 to 10. The active devices used for amplification are large occupying a fair portion of a wavelength with connector tabs from 3mm to 15mm wide. The majority of Si bi-polar transistors manufactured for high power radar applications at L, S and C band, have port impedances with a real component of  $4\Omega$  or less with a similar imaginary component [11].

Normally line-transformers are used to impedance match these devices [11]. Usually these lines have impedances of less than  $10\Omega$  and are a quarter of a wavelength long only when the impedance to be matched is real, which is hardly ever the case. Hence, the majority of these matches start with a line transformer that is wider than it is long and have enormous steps in width to get to the  $50\Omega$  lines. In the light of this, linear circuit analyzers are useless for the analysis or synthesis of these matches, the reason being that analytical models for such large step transitions are still dubious. For this reason electromagnetic simulators are used to analyze these matches and the synthesis of these matches is still more of an art than a science. Part of the goals of this thesis is to investigate an alternative approach.

### 1.1.4 Device Data Format.

Very few establishments have the luxury of load-pull equipment for high power measurements. This means that the only design data available to the designer is that which is supplied by the

device manufacturer and this still is the starting point of the majority of radar amplifier designs [21]. The result can be a costly exercise consisting of several iterations before an acceptable design is obtained.

- **Small Signal Data.** For some of the devices specified for continuous wave (CW) operation the manufacturers supply small signal S-parameters or the S-parameters can be easily measured. Nevertheless, this is not very useful for power amplifier design. A power amplifier designed with small signal S-parameters and optimized for gain, usually delivers from 2dB to 4dB less output power than a properly designed power amplifier [1,2,3,29]. However, techniques have been developed to generate transistor models from the small signal S-parameters and then use the model to design a power amplifier or oscillator [1,2,3].
- **Matching Foils and Impedance Data.** The majority of manufacturers of high power BJT's for pulse power applications provide a test foil pattern as the only impedance design data for their devices. It is difficult to scale these patterns to other substrates if it cannot be implemented exactly as suggested due to the large impedance steps. A further complication is that these foil patterns are optimized for a specified supply voltage, pulse length and duty cycle. Should one need to change any of these parameters, there is no data available and one can only make an intelligent guess as to what is to be changed and how. Fortunately, some manufacturers occasionally also provide a few impedance points as well. This then at least makes it easier for the designer to target an area of the Smith chart for his impedance matching. With the impedance data it is also quick to determine if the device is well suited for the intended application by inserting this data into an amplifier synthesis package such as MultiMatch and establishing the difficulty of obtaining a suitable match and topology. However it must also be stated that often the provided impedance data and foil patterns are not very reliable or accurate [21] and hence the need for device and match characterization.

### 1.1.5 Device Tolerances

**Parameter spread within batches.** With modern device manufacturing techniques and automated matching and tuning of the devices the parameter spread within batches can be tightly controlled with the result that devices from the same batch can be readily exchanged.

**Batch to batch parameter spread.** For the RZ1214B35Y device from Philips it was observed that devices from a much older batch than the one from which the device characterization was done, behave differently in the reference amplifier foil pattern and was even more difficult to optimize over a broad band than the new device. This is a serious problem if the amplifiers that are to be designed have to be maintained for a long time as is needed by military equipment. (Lifespan of more than fifteen years.) Batch to batch device tolerances is hardly ever specified by manufacturers of these devices. What are normally specified are device tolerances within a batch implying that one should initially buy enough components from the same batch to also accommodate the envisaged maintenance needs [6,23].

### 1.1.6 Design Techniques to Control Device Parameter Uncertainties

The MTI (moving target improvement) factor is a very important design parameter for modern pulse Doppler radars. This calls for tight control of the following amplifier parameters: pulse droop, pulse top ripple, in pulse phase variation, pulse to pulse amplitude variation and pulse to pulse phase stability. All these parameters are influenced to a more or lesser degree by device characteristic uncertainties. Several methods are used to control the parameter spread and device uncertainties in an attempt to keep the amplifier performance across a range of temperatures and conditions within the set tolerances.

- **Device combination.** An often-used approach is to design balanced amplifiers in an attempt to control the device tolerances and the input and output interdependencies. This is even extended to millimeter wave frequencies [29]. An extension of this approach is implemented by manufacturers such as MA Com and Fujitsu who have some amplifier

devices that have two transistors on the same carrier and is intended for a push-pull application. (See Figure 1. An example of a device intended for a push-pull design.) This technique desensitizes the amplifier from external impedance changes that can affect the pulse shape, efficiency and stability. It also provides some averaging of the performance parameters.

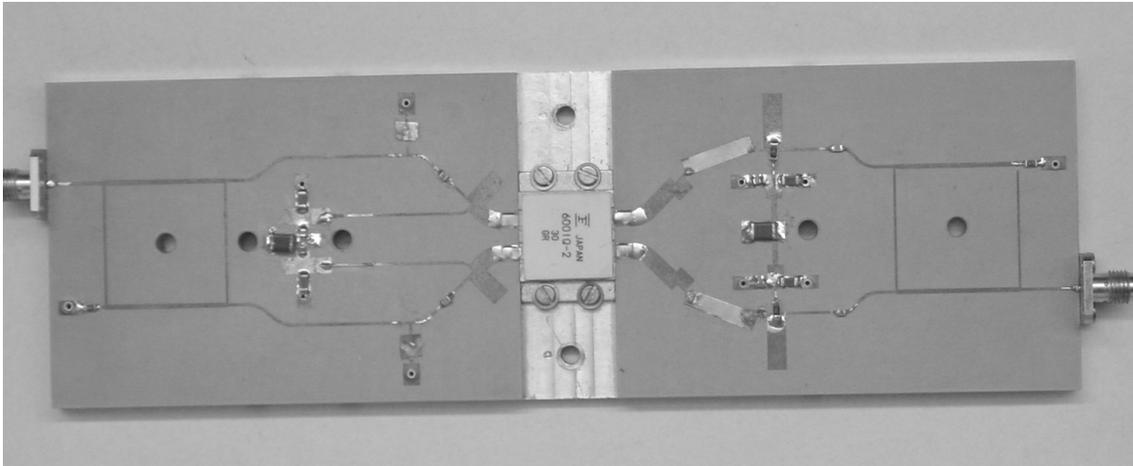


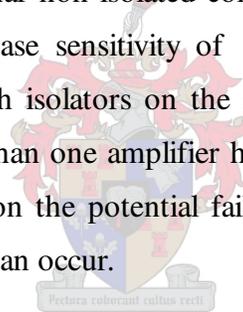
Figure 1. An example of a device intended for a push-pull design.

- **Amplifier Combination.** An extension of the previous technique is the combination of amplifiers. Yet this is easier said than done, as the design of high power combiners is a tricky affair.

When co-planar and microstrip structures are used, binary planar combination structures is the preferred method of power combining. The main advantage of these structures is that they provide excellent isolation between amplifiers and can be made with very little loss if care is taken with the choice of topology and materials used. A further advantage of these structures is that heat dissipation is easy to control and optimize with these structures. For in phase power combination at moderate power levels, the Wilkinson combiner is most commonly used, as this structure is easy to design and implement if moderate insertion loss can be tolerated. A fair contribution to the insertion loss in a Wilkinson combiner is caused by the displacement current through the balance resistor. This loss can be reduced if the Wilkinson combiner is modified to become a Geysel

combiner at the expense of a bit more real estate that is needed. At high power levels, external dump-loads are preferred with the result that branch line and rat race couplers become the preferred topologies for power combination provided one can tolerate the extra real estate needed. A further advantage of these couplers are that uneven splits are fairly simple to implement giving one the freedom of any number of amplifiers that can be combined with good isolation.

Another approach that is sometimes used is to use non-isolated power combiners with isolators on all the amplifier outputs. This approach works well if cavity radial combiners are used in conjunction with long amplifier chains with lots of gain. (The popularity of this approach is due to the mismatch characteristics of the cavity combiners and the ample volume that is created by this geometry for the thermal management of the amplifiers.) However if planar non isolated combiners are used this is a potential recipe for disaster due to the phase sensitivity of this type of structure and the practical uncertainties that come with isolators on the amplifier outputs as situations can occur where the power of more than one amplifier have to be dumped in the dump-load of a single isolator. Depending on the potential failure mode of the dump-load, a potential catastrophic chain reaction can occur.



Another popular way to combine amplifiers for large systems is spatial combination where every radiator in a large antenna array is driven by its own amplifier. This is only practical for large systems since combining efficiency stays constant. For small systems, circuit combiners have superior performance at much lower cost.

**Sophisticated feedback and power supplies.** The thermal characteristics of the device are a function of the package and mounting construction [8]. The designer has no control over this. In instances where the thermal droop exceeds the pulse shape specification the pulse shape has to be controlled by the power supply circuitry with the aid of a feedback loop. In cases like this and where very short pulses are needed it is crucially important to choose an amplifier topology that is control friendly [2,3], otherwise, the cost to develop the power-supply could well exceed that of

the amplifier. A control friendly topology is one where there is very little inductance between the capacitor bank on the collector of the device and the device tab as well as very little inductance between the emitter tab and ground for a bipolar device that is used in common base configuration. The amount of inductance that can be tolerated would be dictated by the operational power level of the intended device, its chosen supply rail voltage and the rise and fall times of the intended pulse. For a 200W device driven from a 40V supply rail one would need to supply in the order of 12A within the rise time of the intended pulse. For this to happen in less than 50ns is not uncommon. To find such a control friendly topology and guarantee good efficiency and impedance matching is a difficult and non-trivial exercise and an amplifier synthesis package such as MultiMatch is an invaluable tool to aid this process [1].

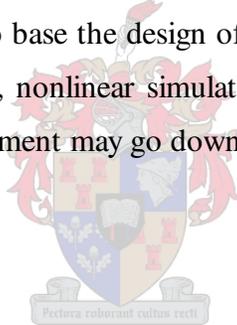
## 1.2 Summary

Design techniques for solid-state bipolar radar amplifiers have stayed the same for the last twenty years. The majority of attempts at improvement are concerned with better and cheaper device characterization methods [11,21]. LDMOS FETs have recently matured to the point where they have become serious contenders for inclusion in the driver stages of pulse power amplifiers. A lot of effort is going into the non-linear modeling of these devices and it is likely the route that will be followed in future regarding these devices [1,3]. However, for high power applications with stringent thermal constraints, BJTs are still the preferred design technology [21] and a design process for their use is presented in chapter three.

## 2 Test Fixture Design for Device Characterization

### 2.1 Introduction

Load-pull data has been the mainstay for microwave and RF power amplifier design for many years. It essentially converts an intractable nonlinear problem into one that can be attacked and solved using linear techniques and even linear simulators [1]. It gives the designer a simple target area on the Smith chart on which to base the design of the impedance matching networks. With the recent availability of good, fast, nonlinear simulators and improving large signal models, it could be argued that load-pull equipment may go down the road to oblivion. This however is not evident yet; especially for BJTs.



#### 2.1.1 Load Pull Techniques

A power sweep measurement on an active amplification device will indicate that there is some kind of functional relationship between output power and output match. From this it follows logically that more than two data points should be measured. Such a measurement is termed a load-pull measurement. The results of these measurements are normally plotted as contours of constant power on a Smith chart.

In its simplest form, a load-pull test setup consists of the device under test (DUT) with some form of calibrated tuning devices on its input and output. The input is normally only adjusted to optimize gain. However, bipolar transistors show significant dependency between output power and input load. This complicates load-pull measurements on bipolar transistors, as both input and output loading have to be adjusted simultaneously.

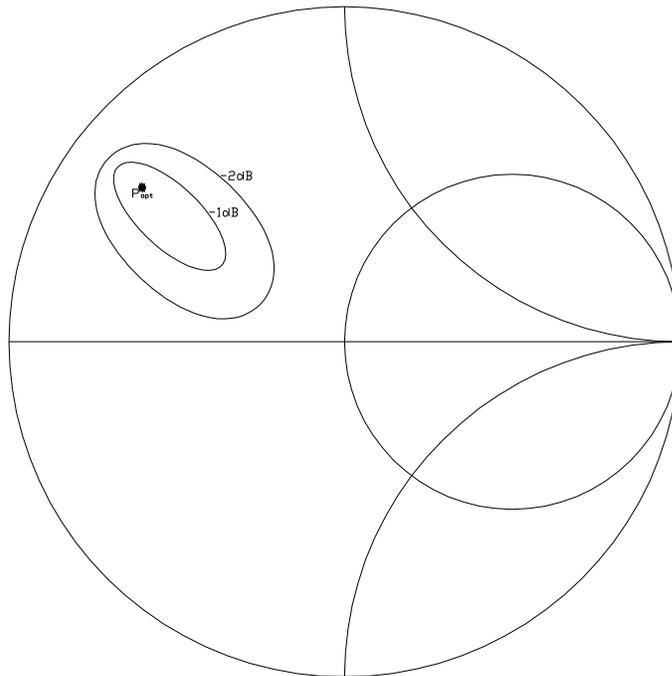


Figure 2. Typical Load-pull data.

A typical set of load-pull data is shown in Figure 2. Such a set of data may take weeks, days or minutes to compile, depending on the degree of complexity, expense, and time invested in the load-pull measurement equipment. The results show closed contours, marking the boundaries of specified output power levels. For most practical purposes, the power amplifier designer is concerned mainly with the  $-1\text{dB}$  and  $-2\text{dB}$  contours, which represent levels relative to the maximum or optimum power output of the device at the test frequency.

The most obvious immediate observation in looking at the data in Figure 2 is that the constant power contours are not circular, unlike noise and linear mismatch (gain) circles. The reason for this is that they physically are areas of intersection between constant resistance and constant conductance circles [3]. This result can be verified by studying the concept of a load line match and idealizing it [1,2,3].

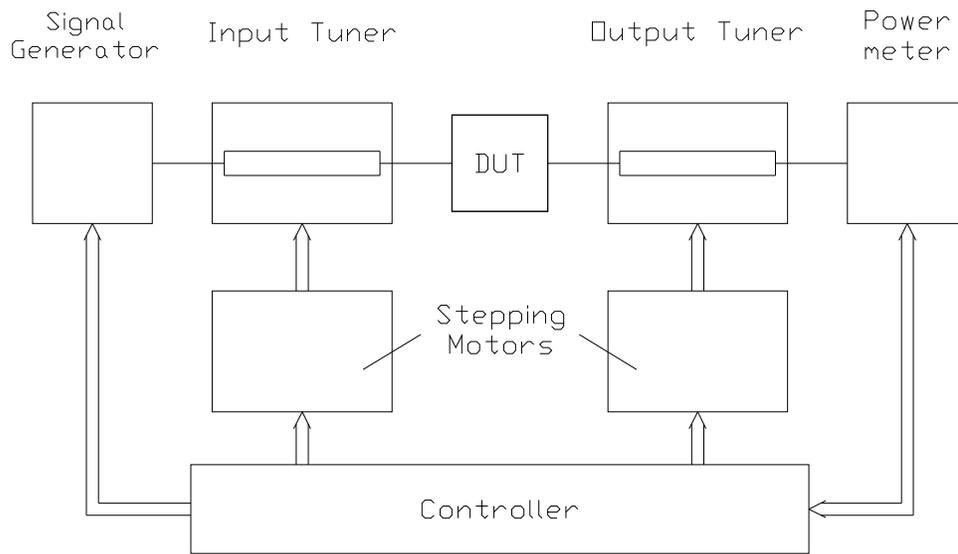


Figure 3. Typical commercial load-pull configuration.

- Commercial Load-Pull Equipment.** Most commercially available load-pull test setups use some form of computer controlled tuning device. A typical block diagram is shown in Figure 3. Such a system would likely rely on off-line calibration, whereby the impedances of literally thousands of tuner settings are measured with a calibrated network analyzer and stored. Mechanical tuners have to be accurately resettable, which presents some design challenges. They typically are controlled by stepping motors, which introduce additional mechanical tolerance problems and put some substantial time limits on each measurement. A further complication of mechanical tuners is their inherent loss. With the low port impedances of power devices, a loss of fractions of a decibel could potentially mask the impedance that one is trying to measure. (The loss can be represented by a small resistance comparable to the real part of the impedance that one is trying to measure.) An alternative technique is to use so called active tuning. With this technique a test signal is applied to the output of the device and tuning effects are simulated by varying the phase and amplitude of the applied signal. This technique however is normally used at very high frequencies where the design of mechanical tuners becomes extremely difficult [3].

At this juncture, it is assumed that the matching problem is essentially a linear one and that the output current waveform that drives the tuner is perfectly sinusoidal. This is hardly ever the case as amplifiers designed to work in class C is normally driven at least one decibel into compression. Devices used in class C are highly non linear, not only over the RF cycle, but also over the pulse envelope cycle. This raises some complex issues regarding the predictability and repeatability of the tuner at harmonic frequencies. However, at least in principle, tuners can be calibrated at harmonic frequencies as well.

#### 2.1.1.1 DETERMINATION OF PORT IMPEDANCES

The optimum impedance to be matched is normally acquired through some variation of a load-pull experiment [2,3,11,18,21,24,29,30,31]. To get to this “optimum” impedance, load-pulling can take all the parameters deemed crucial, such as output power and efficiency, into account and normally an attempt is made to get as close as possible to the conditions of the intended application. Having said this, it must still be remembered that this “optimum” impedance is specified with the following understanding:

- The real device is highly non linear, not only over the RF cycle, but also over the pulse envelope cycle [8,11]. Furthermore, just defining the impedance becomes difficult, to say nothing of measuring it.
- If it were possible to measure the port impedances under power conditions by applying a high level of RF power to the device and looking at the reflected signals, those impedances would be a complex function of the power and it would be quite different from the conjugate of the optimum input impedance and load under small signal conditions [2,3,7,11,22,26,27,28,30,31]. Some kinds of RF devices, particularly bipolar transistors, show significant dependency between output power and input load. It is, in practice, quite difficult to differentiate between true source-pull effects and simple input matching. Devices that show the most prominent source-pulling effects usually operate close to their maximum usable frequency, and this situation is best avoided by using a

higher frequency technology [3]. Most often, however, devices for pulse power work are optimized to work close to their maximum usable frequency with the result of a strong dependency between input and output.

Commercially available load-pull equipment is very expensive. If ones business necessitates the design of pulse power microwave amplifiers only occasionally, the expense of such equipment cannot be justified. A test fixture was designed in an attempt to provide a more affordable solution. Such a test fixture would have to include the means to represent the intended application closely and characterize the device under test (DUT) accurately.

## 2.2 Microstrip TRL Test Fixture

The backbone of this test fixture is a microstrip TRL (Thru-Reflect-Line) structure into which the required measurement modules fits, namely:

- Active device mounting inserts.
- High current biasing inserts.
- Current sensing and gating circuitry.
- Impedance transformation inserts.
- Stub tuner inserts.



The design of each of these inserts will be treated in detail. The basic fixture is shown in Figure 4.

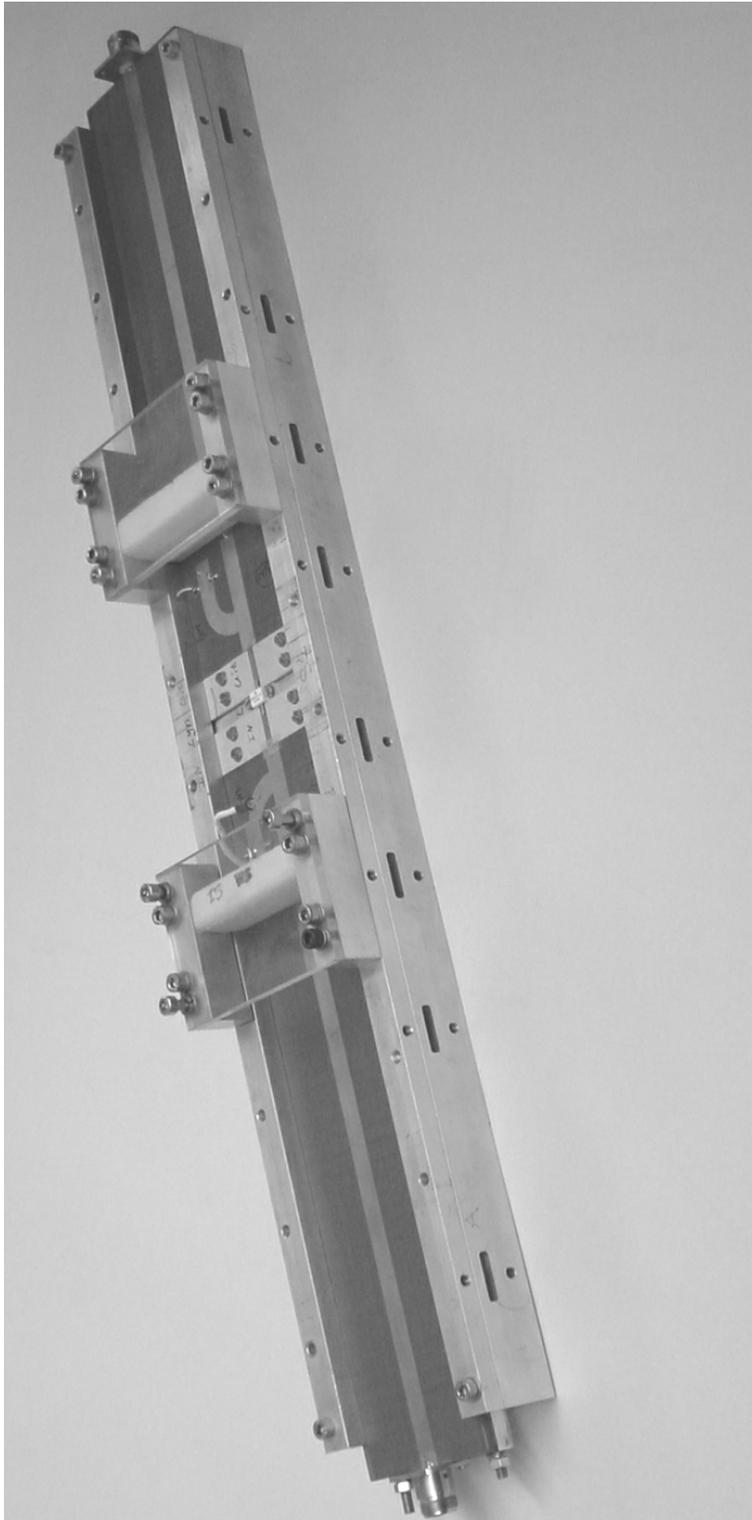


Figure 4. Basic Test Fixture.

## 2.2.1 TRL Test Fixture Requirements

- **Microwave power and direct current (DC) constraints.**

The DC and microwave power design parameters for the test fixture is as follows; be able to accommodate pulse power solid state devices up to 750W peak power with a duty cycle of 10% and a maximum pulse length of 350μs. The DC supply for these devices would normally be between 40V and 60V but for some of the lower power devices (50 dBm and less) it can be as low as 10V. This implies that it must be able to safely handle peak currents of 40A.

Since the RF input and output lines can also carry the DC supply current they must be of adequate dimensions with enough copper area. The copper area needed can be estimated from the empirically determined formula [9];

$$I = 0.048 T^{0.44} A^{0.725} \quad (1)$$

Where the units are

I    Ampere

T    Temperature Rise in °C

A    Cross sectional area in square mils (square THOU)

Since pulsed conditions places greater stress on substrates than DC conditions [9] one will do well to be conservative. With this formula a 9mm wide 2oz/ feet<sup>2</sup> copper track can carry 25.8A average current with a 20°C rise in temperature. This should be adequate for the maximum-pulsed current conditions envisaged [9]. (Forty amps peak with a low duty cycle.)

Due to the relatively high power levels and the potentially high voltage standing wave ratio (VSWR) that could exist on the lines, N-type launchers were chosen to be on the safe side.

- **Mechanical considerations.**

The first requirement of the TRL calibration approach is the ability to insert and replace calibration standards of different physical dimensions with ease. Closely linked to this requirement is the ability to insert and remove the devices to be tested with ease after the measurement planes have been fixed at the end of the transmission lines through calibration. As both the calibration standards and devices to be measured have to fit between two transmission lines, a so-called split-block design is normally used for TRL test fixtures. Good guidelines on the mechanical design of TRL fixtures can be found in reference . [10].

Connection repeatability and a stable measurement environment are crucial parameters for any calibration procedure. Therefore one should also try to keep the feed lines about the same width as the DUT tabs as substantial differences in width can lead to numerous measurement and repeatability problems [11,21]. The devices to be measured have tab widths that vary from about 3mm wide to about 15mm wide. With this in mind, a test fixture with microstrip lines of about 9mm wide would be a good choice.

For accurate error correction, the system must be stable and the connection interface repeatable. The radiated electric fields around the microstrip lines in the fixture may change somewhat between calibration and measurement (due to the changes in grounding and transmission line alignment caused by the fixture separation during calibration and device measurement). Most of the microwave signal propagates through the dielectric between the surface conductor and the ground plane below the dielectric.

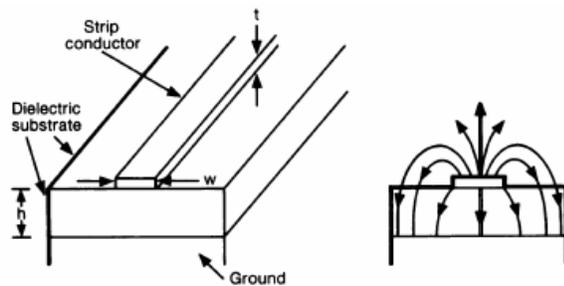
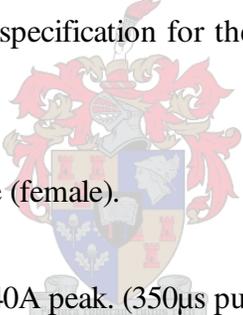


Figure 5. Microstrip transmission line geometry and electric fields.

However, as shown in Figure 5, some of the signal is supported by electric fields in the air above the substrate. As objects are introduced into the electric fields above the surface or when the fixture is separated, the propagation characteristics of the microstrip transmission line will change. To minimize this effect, the test environment should be repeatably the same during calibration and measurement. Further, the test environment should be similar to that of the final application. In practice, this means that the ends of the mating blocks must be machined very flat and measures must be taken to get their heights exactly the same as to keep the discontinuity in the transmission medium to a minimum. Measures must also be taken to minimize the disturbance (discontinuity) of the electrical connection between transmission lines while maintaining good and repeatable electrical contact.

### 2.2.2 TRL Test Fixture Specification.

From the discussed requirements, a specification for the basic TRL test fixture can be extracted. The guide specification is as follows:

- 
- Preferred connectors. N-type (female).
  - Current handling capability. 40A peak. (350 $\mu$ s pulse, 10% duty cycle).
  - Ideal microstrip width. ~9mm.
  - Ideal channel width containing the microstrip lines. <20mm.
  - Preferred physical length of guiding structure. ~500mm.
  - Simplicity in exchanging calibration standards and devices to be characterized.
  - Measurement repeatability. Better than 30dB.

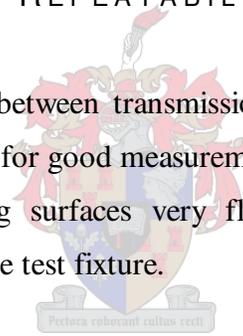
### 2.2.2.1 CHOICE OF SUBSTRATE

The diameter of the dielectric material of a N-type connector is close to 9mm. When an N-type connector is used as launcher onto microstrip, the ideal height for the microstrip dielectric material would be about 4.5mm to minimize the step in ground conductor.

With these requirements and restrictions in mind, Aluminium backed 125 mil (3.2mm) Arlon 5278 with 2 oz/ ft<sup>2</sup> copper, which was left over from another project was chosen as substrate for the TRL test fixture. This substrate has a relative dielectric constant ( $\epsilon_r$ ) of 2.6, which means 50  $\Omega$  microstrip-lines are 8.85mm wide. The effective dielectric constant for this line is 2.2 and a wavelength at L-band is then about 200mm. This proved to be an adequate choice.

### 2.2.2.2 MEASUREMENT REPEATABILITY

Good stable electrical connection between transmission conductors and the continuity of the ground plane is of vital importance for good measurement repeatability. The ground continuity is ensured by machining the mating surfaces very flat and by maintaining tight tolerances throughout the manufacturing of the test fixture.



Electrical connection between microstrip transmission lines is provided by a thin piece of conductor (0.2mm thick brass shim) on the end of a dielectric block bridging the conductors, as shown in Figure 6. Low loss machinable foam with a dielectric constant of 1.09 and dissipation factor of 0.0004 from the Cuming Microwave Corporation (RH-5) was found to work well as dielectric blocks.

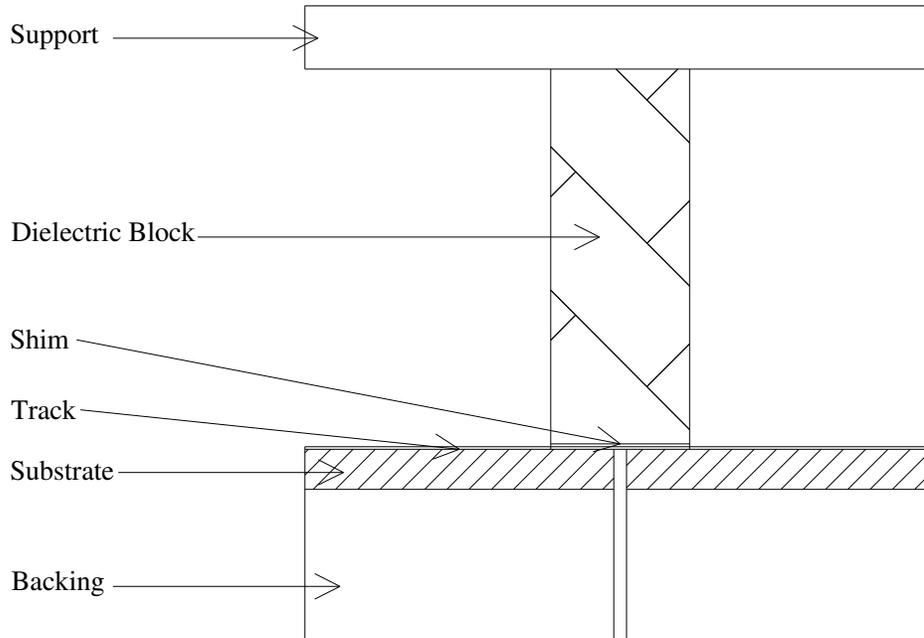


Figure 6. Line connecting detail.

While making the connection, the dielectric block and brass shim will disturb the fields above the surface. The impedance of the line is partially dependent on the total thickness of the surface conductor. As the bridging conductor is pressed into place, there is unavoidably a small impedance discontinuity. Therefore, the dimensions of the shim and dielectric block should be kept to a practical minimum. (Bigger connections need bigger shims with wider blocks). The alignment of the shim was found to be a critical factor for good measurement repeatability. It was found that the shim must be exactly the same width as the narrowest line and it must line up squarely on both sides. A slight step in height between the two lines to be connected was found to have an even bigger influence on measurement repeatability than a slight miss-alignment in the connecting shims. For this reason the flatness of the components of the measurement fixture must be well maintained. With care and practice, a measurement repeatability of better than 40dB can be achieved. A step in height of about 0.1mm will drop this figure to less than 20dB and a miss-alignment of about 0.5mm on 10mm wide lines will drop this figure to about 30dB.

### 2.2.3 TRL Calibration Standard Requirements

When building a set of standards for a user-defined environment, the requirements for each of these standard types must be satisfied. An important note here is that TRL does not require a perfect short or open, just that the source of the reflection at the two measurement planes are identical and that the characteristic impedance of the through and line standards are the same.

<b>Requirements for TRL standards</b>	
<b>Standard</b>	<b>Requirements</b>
<b>Reflect</b>	Reflection coefficient ( $\Gamma$ ) magnitude (optimally 1.0) need not be known. Phase of $\Gamma$ must be known within $\pm 1/4$ wavelength. Must be the same $\Gamma$ on both ports. May be used to set the reference plane if the phase response of the REFLECT is well known.
<b>Zero Length Thru</b>	S21 and S12 are defined equal to 1 at 0 degrees (typically used to set the reference plane). S11 and S22 is defined equal to zero.
<b>Non-Zero Length THRU</b>	Characteristic impedance $Z_0$ of the THRU and LINE must be the same. Attenuation of the THRU need not be known. Insertion phase or electrical length must be specified if the THRU is used to set the reference plane.
<b>LINE</b>	$Z_0$ of the LINE establishes the reference impedance after error correction is applied. Insertion phase of the LINE must never be the same as that of the THRU (zero or non-zero length). Optimal LINE length is $1/4$ wavelength or 90 degrees relative to the THRU at the center frequency. Useable bandwidth of a single THRU/LINE pair is 8:1 (frequency span/start frequency). Multiple THRU/LINE pairs ( $Z_0$ assumed identical) can be used to extend the bandwidth to the extent that transmission lines are realizable. (They might become impractically short.) Attenuation of the LINE need not be known. Insertion phase or electrical length need only be specified within $1/4$ wavelength.

### 2.2.3.1 TRL STANDARD DESIGN.

- **Reflect standard.** The simplest REFLECT would be an open circuit. This can be achieved by simply separating the two TRL test fixture halves. A short circuit could also be used. With the relatively wide transmission lines that were used it was found that an open circuit radiate quite a bit of energy. The preferred reflect standard for this project was therefore a short circuit.
- **Thru and Line standards.** The LINE standard is a short microstrip line inserted between the fixture halves. Complete microstrip models indicate that physical length and electrical length are related by not only the dielectric constant, but also the thickness of the dielectric, and the dimensions and conductivity of the surface and ground conductors [20]. However, precise specification of the electrical length is not required in TRL, particularly when a zero-length THRU is used to set the reference plane. A quasi-TEM method can be applied to estimate the electrical length. Quasi-TEM infers that the propagation velocity is essentially constant (non-dispersive) but offset by the effective dielectric constant [17].

This effective dielectric constant is a function of the line's dimensions and material. The recommended electrical length for a LINE standard is between 20 and 160 degrees with respect to the THRU [10]. In order to cover a greater than 1:8 frequency span, multiple lines must be used. If the frequency span is less than 1:64, then two THRU/ LINE pairs will be sufficient. The desired frequency span must be divided, allowing one LINE standard to be used over the lower portion of the frequency span and a second to be used for the upper band. The optimal break frequency is the geometric mean frequency  $\left[\sqrt{(f_1 \cdot f_2)}\right]$  of the total frequency band that needs to be covered. The geometric mean of 0.2 GHz and 3GHz is about 0.8GHz. The optimal line lengths to cover the whole band would thus be about 26mm and 100mm.

A compromise was made and the two line lengths were chosen as 60mm and 30mm for the lower and upper bands with a zero length THRU. Relative to a zero length THRU, a 60mm line at 0.2GHz is about 22 degrees long and at 1.5GHz, it is about 160 degrees long. The 30mm line is about 27 degrees long at 0.5GHz and at 3GHz; it is about 160 degrees long. This fixture can thus potentially be used between 200MHz and 3GHz, provided that no unwanted modes are generated.

#### 2.2.3.2 DEVICE MOUNTING INSERTS

The active devices to be tested are mounted on carrier blocks that can then be easily inserted and extracted from the test fixture. For every different device, or at least for every different package that are used for device packaging, a carrier block have to be designed and made. Once the active device is mounted on the carrier block, it can be characterized in the test fixture with repeatability and ease. An example of such a carrier block is shown in Figure 7. The other passive structures that might also be needed for the device characterization was mounted on similar blocks, like the quarter wave transformers that can also be seen in Figure 7.

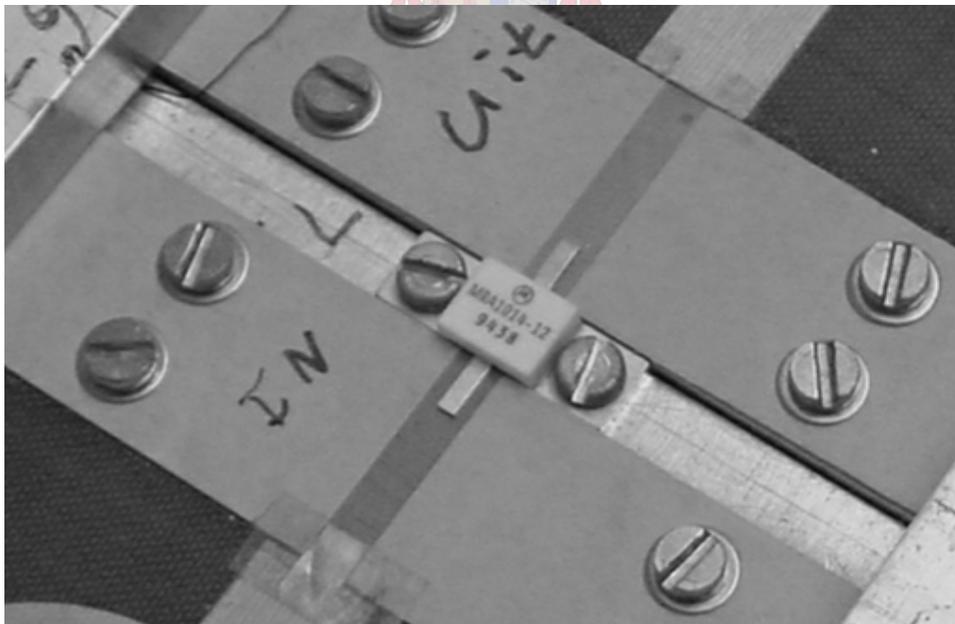


Figure 7. Carrier block detail.

### 2.3 Stub Tuner for High Standing Wave Ratio Load-Pull Measurements

The design criteria for the tuner is: Be capable to synthesize SWR's of more than a 100 ( $R_0 < 0.5\Omega$  in a  $50\ \Omega$  system), have a  $360^\circ$  target tuning area on the Smith chart and have a 750W pulsed power-handling capability.

The key requirement for power load-pull is accurate, very low impedance synthesis at high RF power levels. Computer controlled electromechanical slide screw tuners have been the designated state-of-the-art solution for some time [18]. Good electromechanical slide screw tuners can accurately generate a SWR of the order of 15:1, which corresponds to the real part of the internal impedance of the transistor to be measured, of about  $3.3\Omega$  in a  $50\ \Omega$  system. (This corresponds to a reflection coefficient  $\Gamma=0.875$ ). Beyond this reflection coefficient level, the calibration and repeatability of these tuners may cause accuracy and measurement repeatability problems [18]. The main restriction of these tuners is insertion loss. A small insertion loss can mask the low impedance that one is trying to measure. For reflection coefficients very close to one, this problem is normally solved by the use of quarter wave transformers in conjunction with the slide screw tuners or by the use of active tuners. The use of quarter wave transformers limits one to a small tuning area of the Smith chart [18], which can be a serious restriction. Active tuners are normally only used for low noise (low power) applications, as they are notorious for their instability and oscillation problems.

Another approach proposed by Focus Microwaves is to transform the very low impedance to be measured, in two steps, using stub tuners, to get to the needed  $50\Omega$  impedance level [18]. This approach makes a  $360^\circ$  target tuning area on the Smith chart possible with potentially a very low insertion loss. If the insertion loss and the reactance of the stubs can be kept low enough, such a structure can potentially be used for the task at hand. Manually tuned stub tuners can be made at moderate cost with relative ease and this approach was taken. (Sliding line tuners are complex and difficult to manufacture, with the associated cost penalty).

### 2.3.1 Principle of Operation

An equivalent circuit model of a two-stub tuner is shown in Figure 8. The majority of power transistors normally require a large capacitor directly on the collector or drain terminal [11]. For this reason transmission line TL1 in Figure 8 should be kept as short as is practically possible and the series inductance in the stubs should be minimized so that C1 can represent this capacitance. Further one would strive to get the sum of the electrical lengths of TL1 and TL2 to be close to  $90^\circ$  at the center of the frequency band of interest (1.3GHz). This will allow the inverse impedance of C2 and L2 to be placed at port 1. Both inductive and capacitive loads can thus be created. (A  $360^\circ$  tuning area on the Smith chart.)

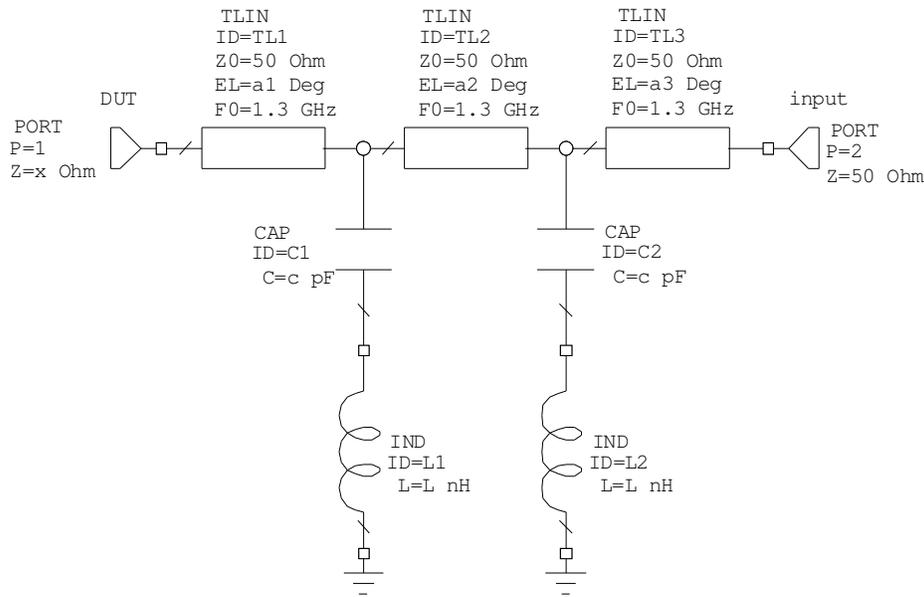


Figure 8. Equivalent circuit model of a two-stub tuner.

Another way to view the operation of the tuner is as follows: C1 and L1 generates a reflection vector that is added to the reflection vector generated by C2 and L2 with the phase addition of TL2 included. This combination generates a total reflection factor that reaches one at the reference plane of C1 and L1 [18]. The insertion loss of transmission lines TL1 and TL2 degenerates this reflection factor and places a limit on the minimum impedance that can be

characterized. The reflection factor that can be generated is also restricted by the series LC resonators of the two tuning stubs. Ideally, one would like a pure limitless capacitance that can vary from zero to infinity. In practice, this capacitor is restricted by the physical dimensions of the electrical conductors of the transmission medium and by the limits of the separation distance of the conductors forming the capacitor. The inductors should ideally be zero and one should take care with their physical construction as their value proved to be the major restriction limiting the performance of the constructed tuner.

### 2.3.2 Realization

Stripline was used as the transmission medium. To keep impedance discontinuities to a minimum the  $50\Omega$  stripline conductors need to be close to the same width as the microstrip conductors of the TRL test fixture, preferably about 0.2mm narrower to ease the mechanical line up procedure and improve the repeatability of the connection [11]. Height wise the ends of the stripline conductors must lie flat on the microstrip conductors of the TRL test fixture with about a 1mm overlap. To minimize loss 0.5mm thick Copper was chosen as the conductor material and low loss machinable foam with a dielectric constant of 1.09 and dissipation factor of 0.0004 from the Cuming Microwave Corporation (RH-5) was chosen to support the conductor in the cavity.

The tuning stubs were realized by modifying the moveable parts of moderately priced micrometers and mounting them in the roof of the structure. This construction can be seen in Figure 9. The ends of the micrometer measuring rods were covered with thin sheets (0.02mm) of mica to electrically isolate them from the stripline conductors at very small spacing. The 8mm diameter of the measurement rods of the micrometers, meant that the maximum capacitor value that could be realized is about 38pF, translating to a reactance of about  $3\Omega$  at 1.3GHz, putting a restriction on the maximum reflection coefficient that can be generated. (The minimum capacitance is a couple of tens of femto farad.) Ideally, one would like the inductance represented by the piece of measurement rod to be zero. In practice, the distance to the grounding point in the structure and the maximum distance from the line limit this. Originally it was assumed that the capacitive coupling where the rod came through the roof would be an

adequate grounding point, but this proved not to be the case and the amount of series inductance in the stubs of the original design made the tuner practically unusable. Mounting grounding fingers in the roof of the structure solved the problem and this improved matters to the point where a reactance down to less than  $3.5\Omega$  could be measured.

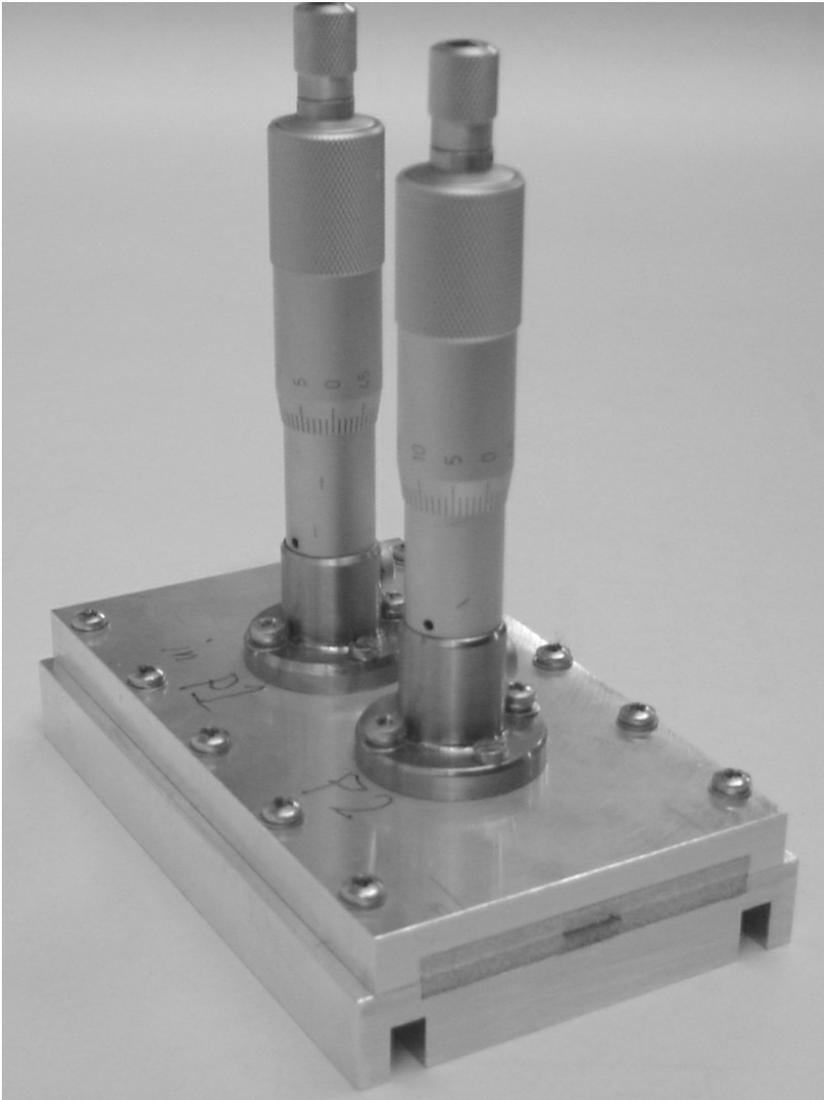


Figure 9. Realization of two-stub tuner.

The ideal situation would be for the tuning stubs to sit very close to the measurement planes. In practice, this distance is limited to more than 30mm, the distance chosen, by the support

structures of the test fixture. The spacing between the two tuning stubs were chosen to be about 35mm as space had to be provided for the mounting of the grounding fingers while the condition of  $90^\circ$  from measurement plane to tuning stub also had to be satisfied. This was found to be an acceptable approximation of the requirements discussed in the section dealing with the operational principals.

## 2.4 Impedance Transformation Inserts

The most widely used method of broadband impedance matching between two real impedances is the quarter wavelength multisection impedance transformer. The design of these transformers is treated in detail in several textbooks and will not be repeated here [19,20].

Traditionally quarter wave transformers are used to transform the low impedances of microwave power transistors to an intermediate impedance level around which the load pull tuners that are available can tune. However, this type of solution presents three major inconveniences: limited bandwidth of less than 10%, a fixed tuning direction (typically, but not always,  $180^\circ$ ) and a fixed transforming ratio [18]. For every new transistor and frequency range of interest a new set of transformers have to be designed manufactured and characterized. Fortunately, these transformers are flexible and fairly low cost and easy to implement, making their inclusion quite feasible when needed. Single step transformers of this kind were also designed and made for this project but later found not to be really necessary. However, with the load pull tuners in their present state, if devices with impedance levels below about  $3.5\Omega$  have to be characterized, such transformers will have to be used. An example of the use of quarter wave transformers can be seen in Figure 10.

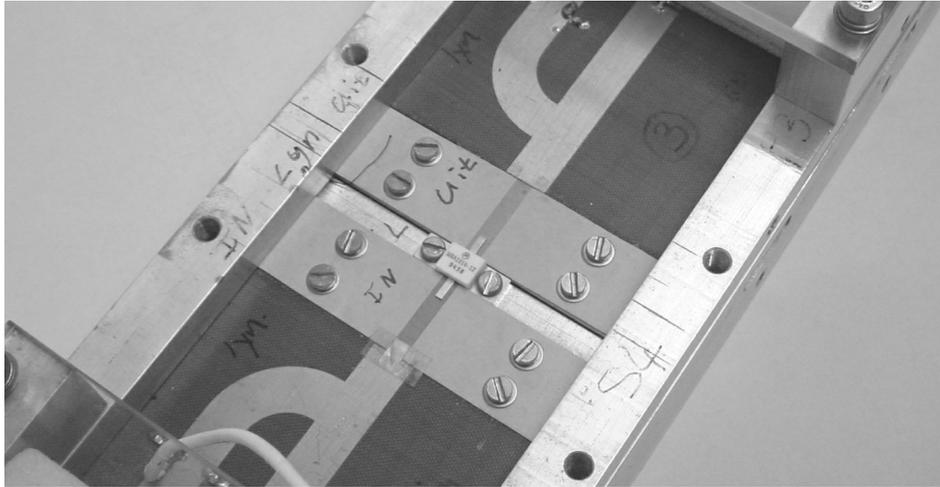


Figure 10. Device under test with quarter wavelength transformers.

## 2.5 DC Biasing

Just as the tracks of the TRL test fixture must be capable of handling 40A peak currents, the inserts used for DC biasing (bias T's) must also be capable of this and were therefore chosen to have the same track widths as the TRL lines. The DC biasing inserts must isolate the DC and microwave circuitry. In concept, using an inductor with a reactance much bigger than the characteristic impedance of the RF feed line can do this. However to construct an inductor with enough inductance and a high enough self-resonance point that can handle the needed current, is difficult, and if one only needs to cover a moderate bandwidth, it might not be worth the effort. A schematic of a bias T is shown in Figure 11.

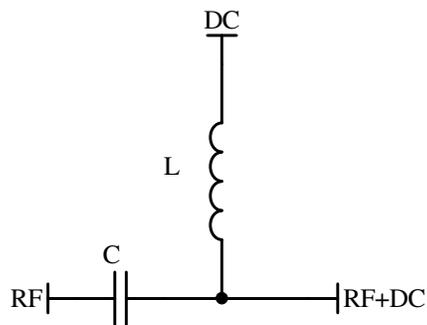


Figure 11. Bias T schematic.

The energy stored in an inductor is a function of the inductance and the square of the current.

( $W = \frac{LI^2}{2}$ ) This makes the use of an inductor to bias high current short pulse circuits problematic.

Therefore, it is a good idea to keep all inductors that carry DC current for pulsed work to a minimum.

If only moderate bandwidth is needed, a better approach would be to use low impedance shorted quarter wave lines for the biasing of the devices that need to be tested. Since the frequency band of interest for this project is from 1.2GHz to 1.4GHz (~ 15% bandwidth) shorted quarter wave lines were used for this purpose. The microwave shorts at the end of the quarter wave lines were implemented with two microwave capacitors in parallel. The implementation is shown in Figure 12. The quarter wave stubs still has a fair bit of inductance with the result that relatively long pulses had to be used for the characterization work. In an attempt to minimize the thermal effects, the duty cycle was kept very low. (300 $\mu$ s pulses with a 1% duty cycle.)



Figure 12. Biasing insert detail.

Because of constraints to the channel width, the electrical length of the biasing inserts, from input to after the DC blocking capacitor on the output side, were made to be about  $100^\circ$  at 1.3GHz. The result of this was that the biasing inserts had to be used in positions where the impedance was already transformed to be close to  $50\Omega$ . If this was not done these inserts transformed the impedance to a very high impedance level that compromised the device characterization. The ideal would have been to bias the devices to be characterized as close to the device as possible in a similar fashion as would be used in the intended application. This however is not possible with the current test fixture and biasing inserts.

## 2.6 Current Sensing Circuitry

Some kinds of RF devices, particularly bipolar transistors, show significant dependency between output power and input load. The result of this dependency is that the input and output matches for bipolar devices are traditionally optimized simultaneously making pulse power amplifier design work for these devices notoriously difficult. One of the goals of this project is to establish a different approach and to simplify the design of pulse power amplifiers.

### 2.6.1 Principles of Operation

It would be highly desirable to find a way to uncouple the optimization of the input and output circuits of bipolar RF power transistors. The input match mainly affects the gain of the amplifier and the other parameters are controlled by the output match [2,3]. It has been found that the collector or drain currents give a good indication of the status of the input match, especially for devices biased in class C, regardless of whether it mainly gets converted to RF power or heat on the collector side [7,8,27,28]. This feature is exploited to uncouple the optimization of the input and output sides. If the parameters of the device to be measured allow it, the simplest way to measure the current pulses is to do a differential measurement over a small resistor with a digital oscilloscope. Often with the high power devices that run off supply rails in the region of 50V or 60V, the inductance of a resistor suitable for a differential current measurement can't be tolerated and a different approach to measure the current is needed. The approach adopted here was to use a current transformer with a single turn (a thick short conductor through the center of a toroid)

on the primary side. There is no need to measure the current exactly; one only needs to maximize the current as this indicates that the input match is close to its optimum. Only a representative estimate of the current is therefore needed. There is however a need to characterize devices under short pulse conditions, say pulses of  $0.5\mu\text{s}$  or less. To be able to do this a current transformer with a single turn on the primary side can be used with a resonating circuit that has been optimized for pulse length and duty cycle on the secondary side. With this approach the series inductance in the DC feed can be minimized with the added advantage that the current indication can be observed on any oscilloscope. A further refinement of this circuit would be the inclusion of a buffer amplifier as shown in Figure 13.

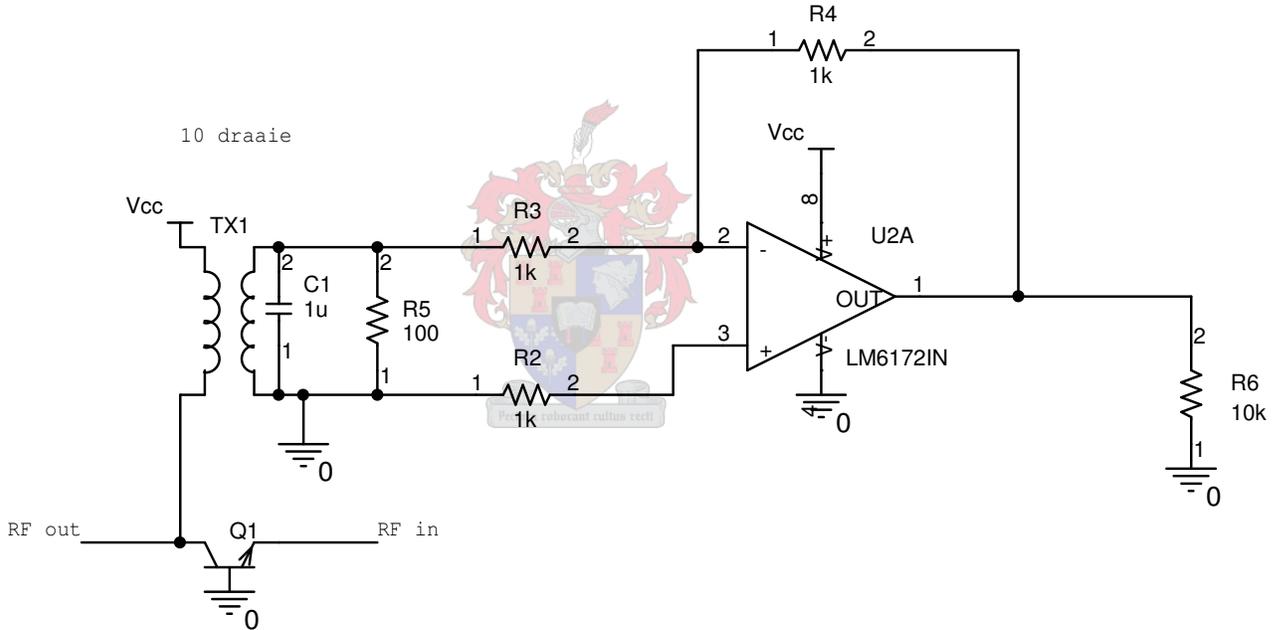


Figure 13. Example of a current sensing circuit.

The number of secondary turns of the transformer and the decay time of the resonating circuit can be adjusted to suit the test conditions. The material and size of the toroid used for the current transformer will have to be chosen to accommodate the magnitude of the expected currents. For the smaller currents, when the maximum inductance tolerable or when saturation of

the core is a problem, a buffer amplifier can be added behind the resonating circuit. The prototype circuit, still without the buffer amplifier is shown in Figure 14.

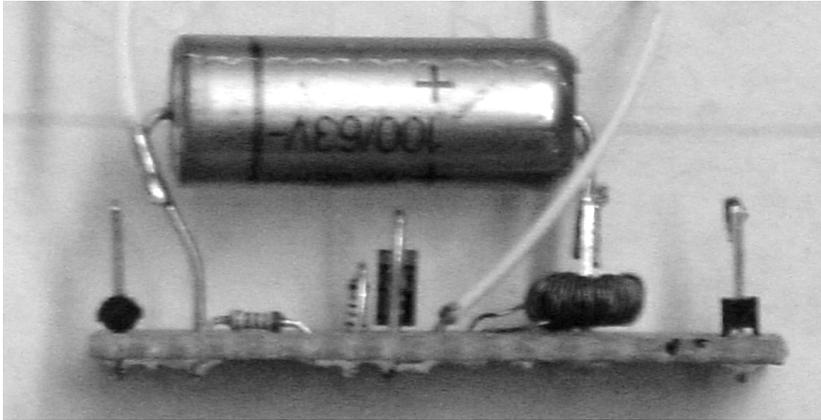


Figure 14. Practical implementation of a 10A sensing circuit.

## 2.7 Time gating circuitry.

Pulse power devices need to be protected against excessive pulse lengths and duty cycle [6]. Spurious oscillations which can occur, especially during the development cycle, is a serious threat, as these would destroy the pulse power devices instantly. The easiest way to guard against this is to pulse the supply in such a way as to produce RF pulses with the desired shape and duty cycle.

A 10W linear driver amplifier had to be designed for this project. This amplifier was implemented using a dual GaAs FET intended for a push-pull configuration. This amplifier is shown in Figure 15.

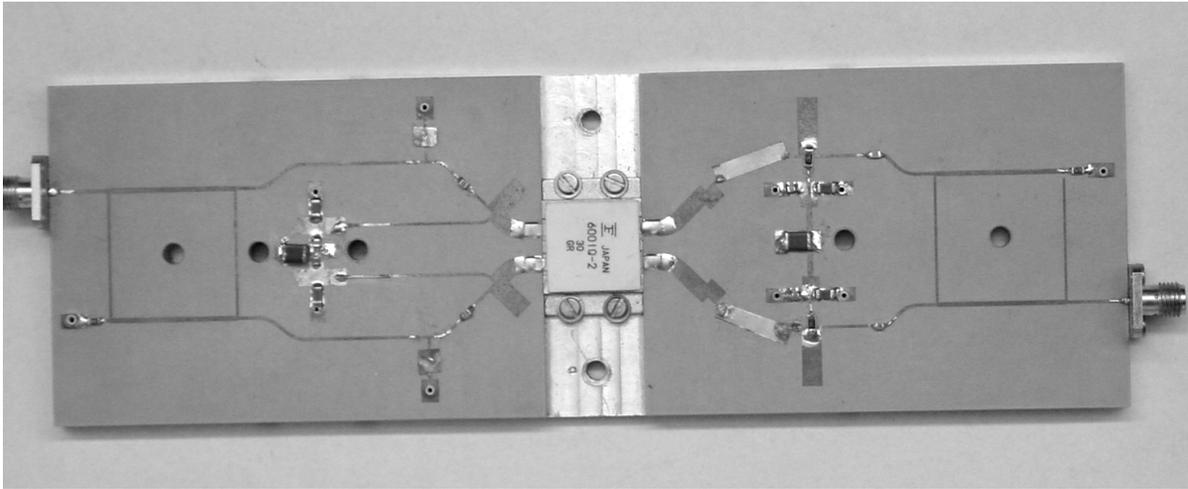


Figure 15. GaAs driver amplifier.

The biasing control to guard against potential destructive oscillations during power up conditions of this amplifier was done using a MAX881R chip that is designed to bias GaAs FETs. (See Appendix B.) The POK line from this chip switched a power FET (Q5 in Figure 16) controlling the supply to the microwave FET. The shutdown line on the MAX881R (marked Gen in Figure 16) was used to time gate the microwave FET. This same circuit was later used to protect the pulse power bipolar devices against spurious oscillations and excessive duty cycles by driving the shut down line with a pulse generator and thereby switching the supply to the collector. A schematic of this circuit is shown in Figure 16. However for devices intended to work with short pulses,  $10\mu\text{s}$  or less, a different circuit with faster switching capabilities will have to be designed as the MAX881R can not switch fast enough using the shut down line. The circuit to bias and time gate the FET is shown in Figure 17.

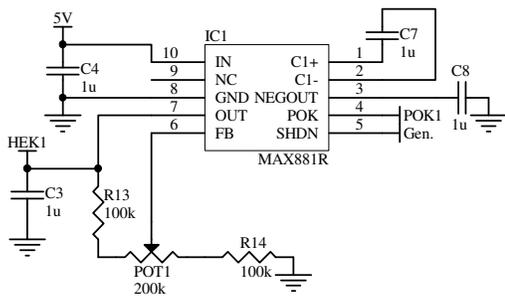
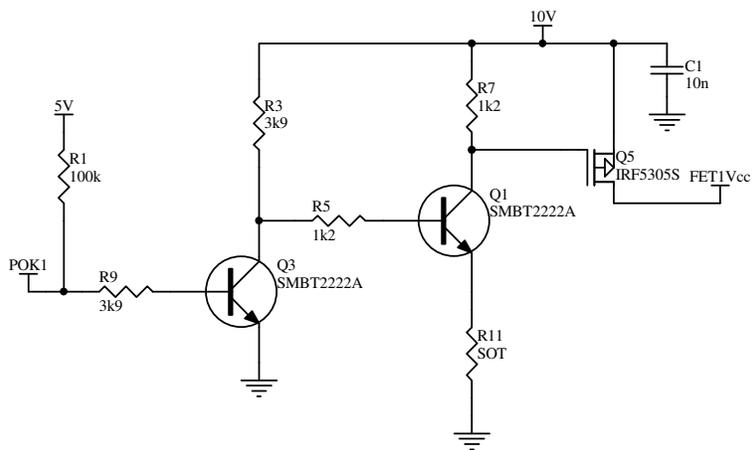


Figure 16. Schematic of time gating circuit.



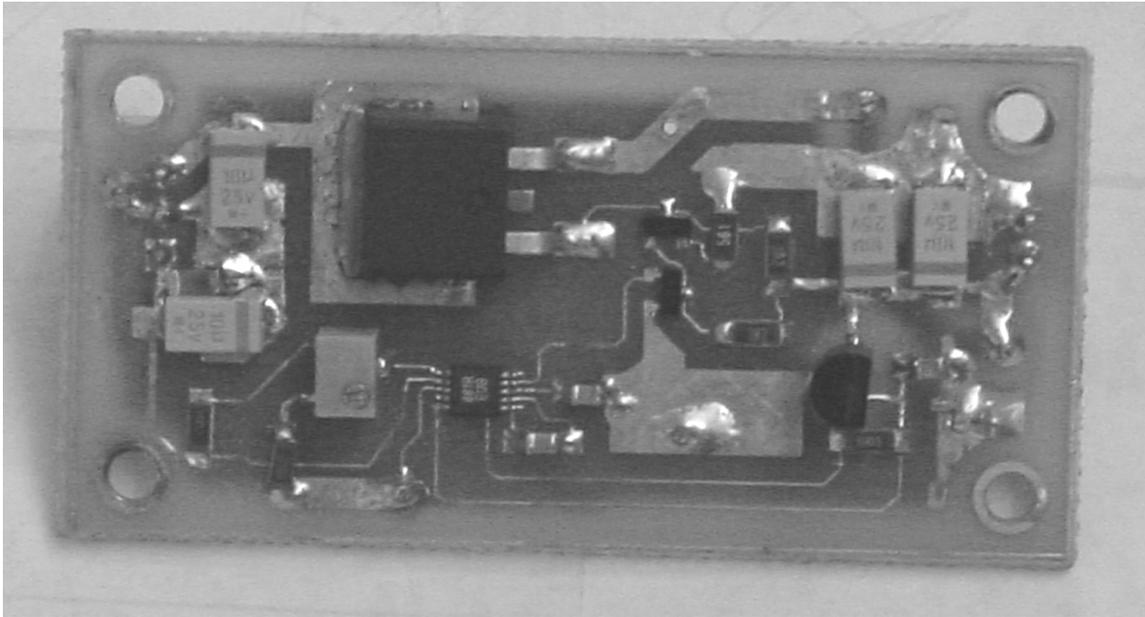
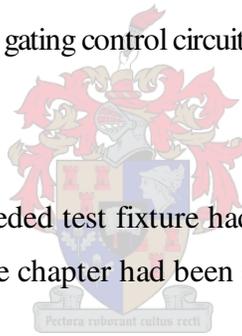


Figure 17. GaAs FET biasing and time gating control circuit.

## 2.8 Conclusion

In this chapter the design of the needed test fixture had been treated in detail, covering the basic TRL fixture including its inserts. The chapter had been concluded with the design of the required test fixture.



## 3 Design and Tuning Procedure for Pulse Power Radar Amplifiers

### 3.1 Introduction.

The current need for broadband amplifiers for radar and electronic countermeasures presents many design challenges to the microwave engineer. The techniques stemming from traditional narrow-band design, easily implemented for designs up to 100MHz bandwidth or so, are inadequate for broader frequency ranges. Normally these amplifiers also have to work under pulsed conditions that change rapidly which further complicate matters.

Optimal match seeking programs are an indispensable aid for large signal broadband design [1, 2]. If success is to be assured, the designer must have a conceptual understanding of promising circuit topologies. Meaningful design constraints must be set so that the optimal design can be selected from the many possibilities. Unless the transistor can be fully simulated, one requires a description of what the transistor desires for input and output loading to satisfy the desired design constraints. These design constraints often include parameters as diverse as pulse shape, efficiency, stability, and phase linearity. The question now is how to translate these requirements into design constraints for the computer aided impedance search.

### 3.2 Large-Signal Transistor Characterization.

Broadband large signal amplifier design is considerably more complicated than small signal design. Bandwidth for small signal stages would normally be specified as the frequency range over which the gain is maintained within some specified deviation from a nominal value. In small signal design, the input and output circuits could be varied mutually to

achieve the set bandwidth specification, while well-defined stability boundaries are assured. In the large signal stages under consideration here, the output circuit must principally satisfy good collector efficiency and adequate saturated power, maintain the pulse shape within the set boundaries and preferably ensure unconditional stability, although stability problems are normally easier to fix on the input side. The output match also affects power gain although this is normally in conflict with the principal objective of saturated power. Consequently, power gain often must be sacrificed from 1dB to 2dB from the maximum value [3, 4].

### 3.2.1 Radar Specific Large Signal Amplifier Design Considerations

#### 3.2.1.1 MTI RADAR

The Doppler frequency shift produced by a moving radar target may be used to separate small desired moving targets from large undesired stationary objects (clutter). A radar that uses this technique for target extraction is called a MTI (moving target improvement factor) radar. MTI is a necessity in high-quality air-surveillance radars that operate in the presence of clutter.

- **Description of operation.** A sample of the transmitted pulse is used as a reference to coherently demodulate the received pulse. In a perfect system, moving targets would produce varying demodulated outputs whereas stationary objects would produce constant demodulated outputs. By now looking at the correlation of the sample pulse and the received pulse, stationary objects can be separated from moving targets. MTI radars that make use of the phase variation in the received signal are called coherent MTI radars. The performance of a MTI radar is specified by the MTI improvement factor. The MTI improvement factor is defined as: the signal-to-clutter ratio at the output of the MTI system divided by the signal-to-clutter ratio at the input, averaged uniformly over all target radial velocities of interest.
- **Limitations to MTI performance due to pulse-to-pulse equipment instabilities.** Pulse-to-pulse changes in the amplitude, frequency or phase of the

transmitter signal, changes in the stalo (stable local oscillator) or coho (coherent oscillator) oscillators in the receiver, jitter in the timing of the pulse transmission and changes in the pulse width can cause the apparent frequency spectrum from perfectly stationary clutter to broaden and thereby lower the MTI improvement factor of an MTI radar. The limits to the MTI improvement factor due to pulse to pulse instabilities in the transmitter are listed below [5]:

Transmitter Frequency	$(\pi\Delta f\tau)^{-2}$
Transmitter phase shift	$(\Delta\phi)^{-2}$
Pulse width	$\tau^2/(\Delta\tau)^2B\tau$
Pulse amplitude	$(A/\Delta A)^2$
<p>Where <math>\Delta f</math> = interpulse frequency change.  <math>\tau</math> = pulse width.  <math>\Delta\phi</math> = interpulse phase change.  <math>B\tau</math> = time-bandwidth product of pulse compression system.  <math>\Delta\tau</math> = pulse-width jitter.  <math>A</math> = pulse amplitude.  <math>\Delta A</math> = interpulse amplitude change.</p>	

- From this, an MTI improvement factor of 60dB, which is not uncommon in modern radars, translates to the following [5,6]:

Interpulse phase change ( $\Delta\phi$ )	0.001 rad (0.057°)
Interpulse amplitude change ( $\Delta A$ )	0.004 dB
Pulse-width jitter ( $\Delta\tau$ )	5.5 ns (150 $\mu$ s pulse in a 5MHz system)

- **Non-coherent MTI.** The composite echo signal from a moving target and clutter fluctuates in both phase and amplitude. In coherent MTI radar systems the

amplitude fluctuations are removed by the phase detector. It is also possible to use the amplitude fluctuations to recognize the Doppler component produced by a moving target. Radar systems using the amplitude variation to separate clutter from wanted targets are known as non-coherent MTI radars or sometimes with the better descriptive name, externally coherent MTI radars. This technique is used when accurate velocity measurement is a key parameter of the radar, the disadvantages are that one then needs a linear receiver and the benefits of limiters being incorporated in the receiver is also lost.

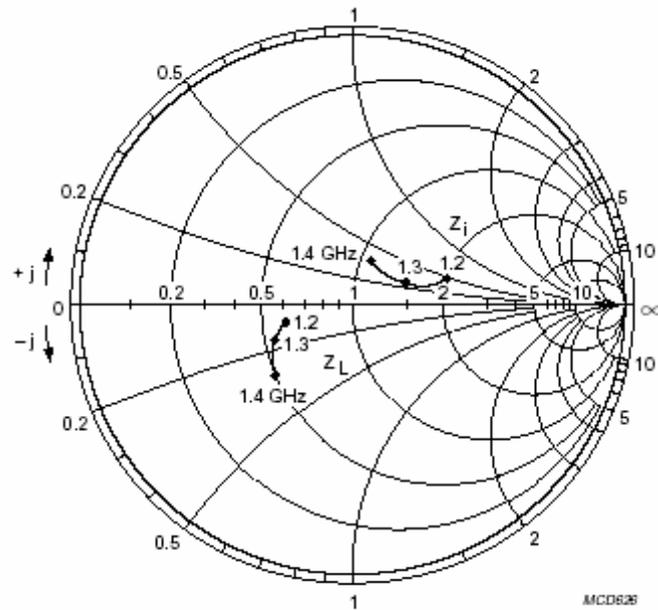
- **Limitations to MTI performance due to in-pulse transmitter instabilities.** With digital signal processing capabilities becoming moderately priced, radar systems with dual path receivers are fast becoming the norm (coherent and non-coherent MTI receivers). In these radars the desired pulse characteristics are largely determined by the characteristics of the expected targets and the capabilities of the digital signal processing hardware and associated software. A pulse droop of  $<0.5\text{dB}$  and pulse top ripple of  $<0.3\text{dB}_{\text{p-p}}$  specification is common [5,6,23] for MTI improvement factors of 45dB to 65dB depending on the other parameters of the system.

The inductance in the output circuit has a strong influence on the pulse to pulse and in pulse stability parameters. The input circuit design is primarily concerned with power gain conservation and gain flatness [2,3]. The input circuit has little or no influence on the saturated output power or collector efficiency, although in a common base class C amplifier it can affect the pulse shape characteristics, especially if there is a fair bit of inductance in the current path to ground [3, 4].

### 3.2.1.2 DESIGN DATA FORMAT

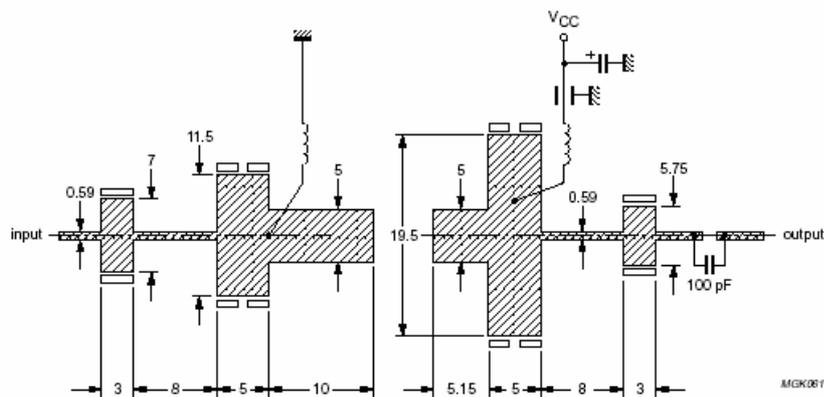
Transistor manufacturers offer some input and collector loading information for pulse power transistors on their transistor data sheets. This is normally presented as a set of input and output impedance points on a Smith chart or in table form or most often it is simply a suggested foil pattern. Examples are shown in Figure 18 and Figure 19. The

complete data sheets for the devices that were used for this project is reproduced in chapter 8 appendix B.



Class C operation;  $V_{CE} = 50 \text{ V}$ ;  $P_L = 35 \text{ W}$ ;  $Z_0 = 5 \Omega$ ;  $t_p = 150 \mu\text{s}$ ;  $\delta = 5\%$ .

Figure 18. Input and optimum load impedance as functions of frequency, typical values.



Dimensions in mm.  
Substrate: Epsilam.  
Thickness: 0.635 mm.  
Permittivity:  $\epsilon_r = 10$ .

Figure 19. Wide band test circuit for class C operation at 1.2GHz to 1.4GHz.

There are several vague points in such data namely [4], the exact test setup that was used in obtaining this data is hardly ever specified, resulting in a fair bit of phase uncertainty.

When the real component of impedance is low, ( $1\Omega$  to  $5\Omega$  for the devices investigated), the concern is that losses in the matching circuitry is obscuring the measured impedance data as discussed in chapter two in the section dealing with the design of the stub tuner. In addition, there is no data for other frequencies, stability or output power levels as a function of supply voltage. Further, how does one stipulate permissible deviations from the specified impedance points so that acceptable efficiency, saturated output power, power gain and stability can be assured? This is important since there is no realizable broadband circuit design that can present the optimum loading over the entire frequency range.

This data is not completely useless though, as it can be used in an optimum match seeking CAD package such as MultiMatch [1,2] to quickly determine the expected difficulty in obtaining impedance matches with a suitable topology for the task at hand. To try to use the published foil patterns, using electromagnetic simulators, to determine the needed impedance data, leaves one with even more uncertainties. At best, it takes out some of the guesswork in finding a suitable starting point for the device characterization.

Thus, the art and science of “load pull” was founded and remains with us to this day in the form of not inexpensive but very powerful computer-controlled measurement systems. For instance, a set up that can handle moderate power and impedance levels will set one back in the region of sixty thousand dollars. In contrast, the total test fixture developed for this thesis cost less than six thousand dollars.

Load pull measurements generate contours of constant power as a function of impedance and frequency [3, 4]. Besides being expensive, load pull measurements can also be very time consuming and tedious. The method proposed here is to try to get round this and come up with a modestly priced, accurate solution, specifically with pulsed amplifiers in mind.

Commercial load-pull set-ups normally use tuners with extremely good tuning repeatability. These tuners are then characterized by taking thousands of measurements with different settings and storing the measured data in a data basis. The measured impedance is then determined by looking at the tuner setting and extracting the relevant

impedance data from the data basis. Sliding line tuners are normally used for this purpose. To construct these tuners with the needed repeatability characteristics is difficult and therefore expensive. In contrast, the method proposed here does not rely on the repeatability of tuner settings, but instead every impedance point of interest is measured. The challenge here is to find a method to measure these impedances fast, accurately and repeatably enough.

### 3.3 Proposed Characterization Method

For bipolar devices under saturated power conditions, it is found that  $S_{12}$  is not negligible. It was pointed out in chapter two that the input matching circuitry has little influence on saturated output power or efficiency. This suggests that the input and output matching circuits can be optimized independently [2,3,21,22,26,27,28] as discussed in chapter two under the section dealing with the design of the current sensing circuitry. The saturated output power efficiency is a function of how closely the output voltage waveform approximates a square wave and what happens to the harmonics [2,3,29]. It is also found that the collector current is a good indication of how hard the transistor is switched on, regardless of whether this heats up the device under test or produces output RF power [7,27,28]. For a device that is switched on (biased) by the drive signal, the collector current is then also a good indication of the status of the input match. This forms the background of the suggested characterization procedure of optimizing the input and output sections independently.

#### 3.3.1 Input impedance characterization.

The proposed characterization method is very much dependent on the test fixture which was designed for this project. The design and other details of this fixture were dealt with in chapter 2. Here only the proposed characterization procedure is presented. For the proposed characterization method the input impedance match is needed for the output characterization. Therefore, it is proposed to start with the input match, in contrast to the normal procedure for power amplifier design where one starts on the output side with a power amplifier design [1,2,3].

**Test fixture preparation.** Once a sample of the device to be characterized has been obtained, the test fixture can be prepared to characterize this particular device. The first step would be to make a device carrier insert if one does not already exist. If the width of the device tabs mean that the characteristic impedance of the connecting lines will be lower than  $20\Omega$  for the substrate intended to synthesize the amplifier on, it is recommended that connecting line inserts, using this substrate, are made as well. These connecting line inserts might also contain the biasing structures. The ideal would be to bias the device as close as possible to the way it would be done in the intended application with the crucial components the intended low effective series resistance (ESR) capacitors and the time gating circuitry that would be used for protection against spurious oscillations and excessive pulse length and duty cycle. However, chances are that compromises will have to be made. The value and type of low ESR capacitors chosen would depend on the acceptable pulse droop, maximum expected pulse length, duty cycle and the expected temperature range of operation. Devices operating at moderate power levels would normally be used as drivers for high power devices. These driver stages would normally be designed to drive the following stages at least 1dB into gain compression under all foreseen conditions. This relieves the pulse droop constraints with the result that smaller value ESR capacitors can be used on these stages. (At the expense of sacrificing power gain and sometimes efficiency also.) Using this approach, the gain slope requirements are addressed in the final amplifier stage.

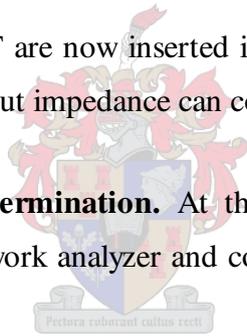
If the bias-T inserts discussed in chapter two are used for biasing, the impedance transformation action of the biasing inserts, as discussed in chapter two under the section dealing with the design of the biasing inserts will also have to be taken into account and it will have to be decided where the best place for their insertion in the test fixture would be, before or after the stub tuner. These choices would also dictate whether a quarter wave transformer would be needed and if so it will have to be designed and manufactured. Once all these preparations are in place, the characterization of the needed inserts and the actual device characterization can commence.

**Test fixture calibration.** The first step in the calibration of the test fixture would be to calibrate the network analyzer that one intends to measure with. Once this is done, a zero length through connection can be made on the TRL test fixture. (The TRL test fixture is described in chapter two.) The integrity of the basic test fixture can now be verified by measuring this transmission line (test fixture). If  $S_{11}$  of this measurement is much worse than  $-20\text{dB}$  across the frequency band of interest, there is something wrong with the test fixture and this problem must be cleared before one can continue with the calibration. A bit of insertion loss is no problem and can even be advantageous. Once the integrity of the basic TRL test fixture has been confirmed the actual calibration of the test fixture can commence.

**Test fixture insert characterization.** With the test fixture calibrated the S-parameters of the test fixture inserts that will be used, can now be measured and saved.

The needed inserts and the DUT are now inserted into the test fixture and the actual characterization of the device input impedance can commence.

**Desired input impedance determination.** At this stage, the complete TRL test fixture is removed from the network analyzer and connected in the test configuration shown in Figure 20.



Before the device input can be characterized, a few measurement parameters must be determined and verified. The first would be to determine an appropriate drive level. A good starting point would be to take the published saturated power and to subtract the published gain. If a supply rail voltage that differ from the published value is to be used this figure can be adjusted accordingly within practical limits. The power level decided on must continuously be monitored and maintained at the set level. (It is unlikely that the driver amplifier response is perfectly flat.)

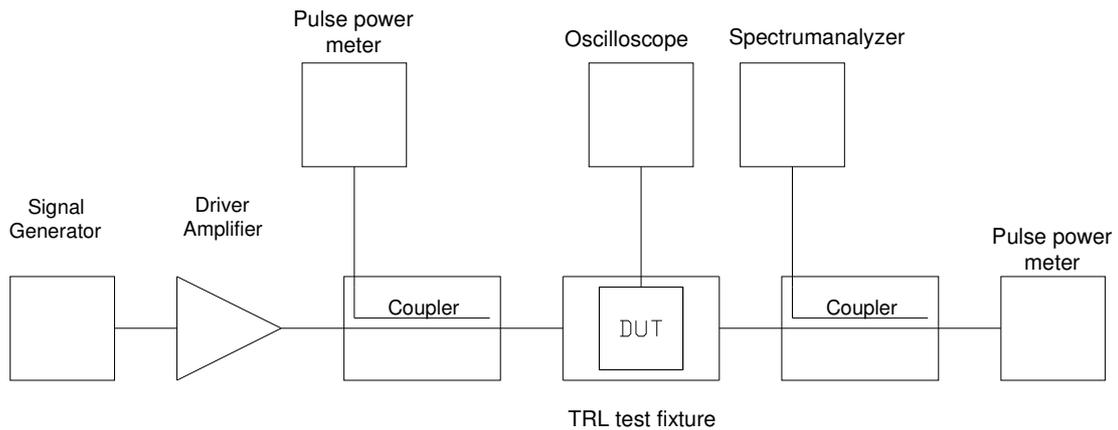


Figure 20. Device characterization test set-up using the TRL test fixture.

Secondly, an estimate of the expected collector current is needed. Again, a good starting point would be to use the published figures in the data-sheet. From this expected current a representative load (resistor value) can be calculated. With the resistor value calculated an appropriate resistor can be obtained or constructed and inserted in place of the DUT, between the output of the time gating circuitry and ground. By pulsing the supply, the expected output of the current sensing circuit can now be observed on the oscilloscope. This gives a target area to aim for when the actual device is characterized. The test resistor is now removed and replaced by the DUT.

Everything is now in place to characterize the input impedance. With the signal generator set up to generate the frequency of interest at the power level required to produce the desired power level at the output of the driver amplifier, the stub tuner insert can be adjusted until a satisfactory collector current peak is obtained.

If a test foil pattern is published for the device, one can use this to guess a starting set-up for the stub tuner, otherwise start with the stub closest to the device turned fully in and the other stub fully out.

As stated in chapter two under the section dealing with load-pull techniques, there will be a contour of impedances at each frequency point delivering satisfactory power gain.

These contours are circles, the so-called constant gain circles [2,3]. The challenge on the input side is to try to find the optimum impedance point, or at least a point on a constant gain circle close to the optimum point in a domain where the gain circles are spaced relatively far apart. (Slow gain variation with changes in impedance, or stated differently, the gain is insensitive to a small variation in impedance.) Once a satisfactory impedance point is found it must also be verified, using the spectrum analyzer that there are no spurious oscillations present. The DUT can now be removed from the test fixture. Connect the output line to the input portion of the test fixture set-up, without disturbing any of the other test fixture settings, and then reconnect the test fixture to the network analyzer. The S-parameters of the test fixture can now be measured. (Since the S-parameters of all the inserts except the stub tuner have been measured before, any de-embedding needed can be done. From the S-parameters of the tuned section, the output impedance of the required section can be calculated. This is the impedance that the device would like to see as an input loading and the conjugate of this impedance can be used as an “input impedance” to synthesize an impedance match.

This procedure is now repeated for every frequency point of interest. The characterization of the input impedance of each of the devices evaluated took less than two hours using the proposed procedure.

**Notes on spectrum analyzer measurements.** A bit of care is needed in the selection of a spectrum analyzer to be used. To satisfy the measurement requirements needed to verify the spurious specifications of some radar amplifiers, especially the ones derived from the electronic warfare (EW) requirements, a dynamic measurement range of 90dB would be needed. Because spurious frequency components must normally be measured to more than 70dB below the carrier, a spectrum analyzer with a tracking filter is recommended. (To protect the spectrum analyzer front-end against saturation by the fundamental.) If such a spectrum analyzer is not available, a notch filter to remove the fundamental can be constructed to do low level spurious measurements with confidence.

To observe the close in spectrum, the sweep time of the spectrum analyzer might have to be set to a large value (several seconds) depending on the pulse characteristics. (The close in spectrum is a combination of sync functions around the carrier.) On older purely analogue spectrum analyzers, this leads to a difficult and awkward observation. It would be easier to use a spectrum analyzer with a digital storage function.

A digital (sampling) spectrum analyzer with some built in signal processing functionality is also very useful to observe the spurious frequency components that get generated at some point during the leading or trailing edge of the pulse and that die away before the pulse top is reached or shortly thereafter. The early observation of these can be a big help in choosing a matching topology and determining the kind of compromises in the choice of a matching topology that one might get away with.

**Input match foil pattern generation.** MultiMatch, an amplifier synthesis computer-aided design (CAD) package was used to generate the impedance matches for this project. This CAD package can also be used as an optimum match and match topology seeking CAD package [1,2]. MultiMatch uses the method of Q's [2] to synthesize impedance matches. It then does a systematic search through the generated matches of different topologies and then displays the most promising ones. The search criteria used is under control of the user as well as the number and type of solutions displayed [1].

Matching networks are synthesized in MultiMatch with the goal to minimize the difference between the target transducer power gain (GT), set for the matching problem and the actual gain obtained with the networks synthesized. The highest gain error in the passband is minimized in MultiMatch (mini-max error versus least square error). This error is referred to as the MRD (the maximum relative deviation from the specified gain response).

Other error values displayed by MultiMatch are: The average mean square error (AMS), and the worst-case MRD value associated with a solution when its element values are varied with the tolerance values specified. This error value is listed as the MRDwc.

The sequence, in which the solutions obtained are listed, is determined by the MRD of each solution, and not the MRD<sub>wc</sub>. A later solution may, therefore, be less sensitive to component changes and possibly represent a better solution to the matching problem. In addition, a later solution might have a topology better suited to the pulse shape and DC requirements than the earlier ones. It is therefore recommended that at least twenty solutions be displayed.

The DUT “input impedance” is entered into MultiMatch as a load to be matched. Set GT equal to one for all frequency points in the passband. (If for some reason one needs a gain slope, this can be taken care of by adjusting GT.) If a biasing and connecting line insert representing the actual application was made and characterized, a sensible starting point would be to try to find an impedance match that matches the DUT including the biasing structure. To get an idea of the difficulty of the problem it is suggested that one starts with an unconstrained mixed (micro strip and lumped elements) three-element topology. One would strive for a MRD of less than 1% [1,2]. If the best MRD obtained with the three-element topology is more than 10%, it is an indication that this is a difficult matching problem. Before spending too much time and effort in an attempt to find a multi-element topology match, it might be a good idea to remove (de-embed) the biasing structure and to see if this might be an easier matching problem. If there is a marked improvement in the MRD obtained without the biasing structure, use this option for trying to find a suitable match and matching topology. For only a slight improvement or no improvement at all, go back to the first option.

MultiMatch also includes a linear simulator. If a biasing structure insert representing the actual application could for some reason not be included in the characterization process, it can be added now using the linear simulation features of MultiMatch. The characterized one can also be added, extended or moved around if need be. A note of caution here would be appropriate; stay within the recommended model parameters [1].

Proceed by adding matching elements until the MRD is smaller than 1% with an acceptable topology that would satisfy the DC biasing, pulse shape, stability and

component tolerance criteria. From stability and pulse shape considerations, it would be desirable to have the least possible inductance in the direct current (DC) feed path of the transistor. The preferred topology would be one with a small inductor right on the emitter of the common base transistor [2]. This would minimize the chance of low frequency oscillations and would make steep rise and fall times feasible. If it is intended to control the pulse shape by driving the collector with a controlled current source, this inductor would be crucial. In addition, potential bias resonances can be moved to frequencies high enough not to create problems. The device data sheets normally give an indication of the input capacitance of the transistor and this can be used to find an ideal upper limit for the input inductance. One would also have to ensure that there is enough copper to accommodate the expected current levels [9] and that the match fits into the mechanical constraints of the intended application. If one gets to a seven element topology and the MRD is still more than 1% the device is probably unsuited to the task or at least one has to find a new set of input impedances to be realized.

Once one is satisfied with the intended input match foil pattern generated in MultiMatch it can be exported to a mechanical CAD package and readied for the manufacture of the input match insert for the TRL test fixture. It is also suggested that the MultiMatch generated foil pattern is exported to another linear simulation CAD package and that the performance of the match is verified. If very low impedance lines are used, for example less than  $20\Omega$  lines, it would be a good idea to verify the match with an electromagnetic simulation package as well [11].

Once the input impedance matching insert has been manufactured, it can be inserted into the test setup and its performance verified. (It is verified that the collector current levels is similar to the ones measured during the characterization procedure with the same drive levels.) The stability should also be verified ensuring that there are no appreciable spurious signals generated.

### 3.3.2 Output impedance characterization.

It would be prudent to do a complete recalibration of the test fixture and to re-measure the S-parameters of all the test inserts needed for the characterization of the output impedance of the DUT. The test fixture calibration and insert measurement techniques have already been discussed under the section dealing with the DUT input impedance characterization. As a confidence check the S-parameters of the input-matching insert should also be measured, its input impedance calculated and then compared with the impedances measured and used for the synthesis of the input impedance match.

**Desired output impedance determination.** The TRL test fixture is removed from the network analyzer and the input matching insert and the DUT is inserted into the test fixture. The width of the device tabs and the substrate that is intended to be used for the amplifier synthesized, would dictate the output biasing scheme, the test inserts needed and the position of the stub tuner. The ideal would be to have an appropriate connecting line and biasing insert followed by the stub tuner. If this can't be accommodated in the test fixture or for some reason this insert is not available, a compromise using the available test inserts will have to be made. Care should be taken that the effect of the potential transforming action of any low impedance lines used, does not influence the validity of the measurements. With the TRL test fixture calibrated, the S-parameters of all the inserts measured and the needed inserts mounted in the TRL test fixture, the DUT output impedance characterization can commence.

The TRL test fixture is connected into the same test set-up as shown in Figure 20. It should be noted here that with this proposed device characterization procedure, there is no risk to do damage to the network analyzer by injecting excessive power into it. During the output impedance, characterization it should be ensured that the same drive levels and biasing conditions used for the input characterization is maintained. An idea of the expected output power level can be obtained from the transistor data sheet. The same principles used to get to an initial setting for the stub tuner when the input impedance characterization was done, can be used on the output side.

There might be instances where every last bit of available power need to be squeezed from the device with the result that the optimum impedance point need to be found, however a much better approach would be to find a suitable impedance point on the one or two dB power contour as described in chapter two under the section dealing with load-pull techniques. The output impedance characterization is potentially more complex than the input impedance characterization. While adjusting the stub tuner in the attempt to find a suitable impedance point, the output power, efficiency, pulse shape and frequency spectrum have to be monitored. It must also be ensured that an impedance point is found in a domain where there is a slow gain variation with changes in impedance. Once a satisfactory impedance point is found, the input impedance insert and the DUT can be removed from the test fixture. Connect the input line to the output portion of the test fixture set-up, without disturbing any of the other test fixture settings, and then reconnect the test fixture to the network analyzer. The S-parameters of the test fixture can now be measured. From the S-parameters of the tuned section, the input impedance of the required section can be calculated. This is the impedance that the device would like as a load and the conjugate of this impedance can be used for the output match synthesis.

This procedure is now repeated for every frequency point of interest. The characterization of the output impedance of each of the devices evaluated took less than three hours using the proposed procedure.

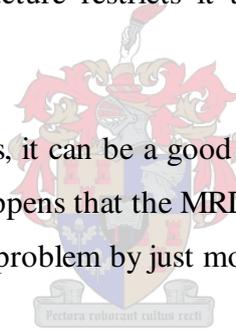
**Output match foil pattern generation.** The DUT output impedance is entered into MultiMatch as a load to be matched. The same general procedure used for the generation of the input match foil pattern can be used to generate the output match foil pattern.

The pulse shape and biasing need to be controllable with relative ease to eliminate the need for a very sophisticated power supply. (With very tight supply rail constraints and a bad choice in biasing topology, the development cost of the power supply can easily exceed that of the amplifier.) This means that there should be the least possible inductance in the DC feed to the collector. It is of vital importance to minimize this inductance if the pulse shape is to be controlled by driving the transistor with a

controlled current source as this normally calls for a very complex power supply with several feedback loops and measurement points. A further benefit is that potential bias resonances can be moved to frequencies high enough not to create problems. The device data sheets normally give an indication of the collector-base-capacitance of the transistor and this can be used to find an ideal upper limit for the output inductance. One would also have to ensure that there is enough copper to accommodate the expected current levels [9] and that the match fits into the mechanical constraints of the intended application.

Because of the relatively large pulsed currents involved; conducted electromagnetic interference (EMI) can become a serious problem. To guard against this care must be taken to control the ground return paths of these currents. Therefore, it must be ensured that the DC grounding of the low ESR capacitors feeding the collector is very short and that the physical structure restricts it to be very close to the transistor grounding point.

With difficult impedance matches, it can be a good idea to look at the MRD values at each frequency point. It often happens that the MRD values change rapidly at the band edges. One might then solve the problem by just moving the band edge by a couple of MHz.



Once one is satisfied with the intended output match foil pattern generated in MultiMatch, the same export and verification procedures used for the input match foil pattern can be used.

**Amplifier verification.** Once the output impedance matching insert has been manufactured, it can be inserted into the test setup and its performance verified. At this stage the performance of the complete circuit can be verified and all the parameters should be measured to confirm that the combination of the input and output impedance matches perform satisfactorily. The sensitivity of the matches to small dimensional changes should also be verified, especially if the circuit is to be mass-produced. For one-off or circuits for which only a few are going to be produced a bit of tuning that might be needed to optimize the matches could likely be tolerated.

Mass produced circuits however, should meet all desired specifications and be insensitive to small dimensional changes. Sensitivity to dimensional changes can be verified by adding small pieces of metal foil to various points of the matching circuit foil patterns.

Bipolar transistors normally exhibit a fair amount of source and load pulling effects. One of the goals of this characterization procedure was to try to minimize this effect and to uncouple the output from the input during the characterization process. It must now be verified that a domain has been reached where the amplifier response is reasonably insensitive to small impedance changes on the input or output side. This is related to small dimensional changes and can be verified by adding small pieces of metal foil to various points of the matching circuit foil patterns.

If the intended use of the amplifier would be in frequency agile radar with rapidly varying pulse lengths and frequencies, the amplifier response under these conditions should also be verified at this stage. Particular attention should be paid to the output spectrum ensuring that it stays clean and spurious frequency free. This measurement is a challenge. It is recommended that it gets done in a test setup where all instruments can be computer controlled with a sampling (digital) spectrum analyzer that can make its output available on the bus. The sting can then be taken out of this measurement by writing control and signal processing software that is optimized for the specific radar characteristics.

Any circuit deficiencies can now be rectified. If the changes required doing so are minor, the design can be exported to the intended application. With relatively large or many changes, another iteration, incorporating the changes would be needed.

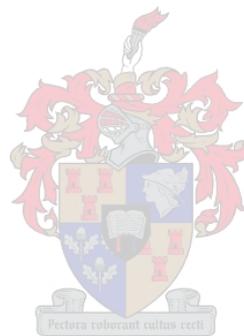
### 3.4 Multi Stage Amplifier Design

The proposed design and tuning procedure is simple and of modest cost. It would also be a simple matter to extend this procedure to the design of multistage amplifiers without the need for isolators between stages. The inter-stage impedance matching circuit can be generated by first inserting a stub tuner between the output of the first stage and the input of the second stage. By adjusting the tuner, the second stage collector current can be

maximized at an appropriate level. The impedances looking into each tuner port can now be measured. MultiMatch can match any complex impedance to any other complex impedance. This can now be used to generate the inter-stage match. The procedure can be repeated for as many stages as is needed. The input match of the first stage, the intermediate matches and the output match of the last stage are generated as described in the sections dealing with match synthesis.

### 3.5 Summary.

In this section a device characterization method of modest complexity and cost has been developed. From this characterization method, a procedure using MultiMatch to design the required amplifiers have been put forward. It has also been shown that it would be easy to extend the characterization and design method to the design of multistage amplifiers.



## 4 Experimental Verification of the Proposed Design

### Method

#### 4.1 Introduction

In this chapter, the experimental results and verification of the processes, manufactured structures and amplifiers designed with these processes and structures, are presented and evaluated. These results are then discussed in the light of the goals set in chapters two and three and potential improvements are proposed.

#### 4.2 TRL Test Fixture Verification

The first step in the calibration of the test fixture would be to calibrate the network analyzer that one intends to measure with. (Short-Open-Load-Through, SOLT calibration.) Once this is done, a zero length through connection can be made on the TRL test fixture. (The TRL test fixture is described in chapter two.) The integrity of the basic test fixture can now be verified by measuring this transmission line (test fixture). An example of this measurement is shown in the upper trace of Figure 21. The existence of a standing wave (mismatch) on the line can be clearly seen. As discussed in chapter two, a bit of insertion loss is no problem and can even be advantageous. The measurement displayed as the upper trace of Figure 21 suggests that the TRL test fixture in question is well constructed and reflection measurements with a dynamic range of more than 40dB should be possible [10,12,14,15,16] across the frequency band of interest. Once the integrity of the basic TRL test fixture has been confirmed the calibration can commence.

Although an HP- 8510 network analyzer (built in software for TRL calibration) has often been available for this project and the majority of measurements were done using it, for this section it was decided to use a network analyzer without an internal TRL calibration

option to demonstrate that the calibration can be done doing the mathematical manipulations oneself. The MATLAB m files presented in chapter 7 Appendix A were used for the mathematical manipulations. The mathematical background to these m files can be found in the literature [10,11,12,13,14,15,16].

There are three basic steps for a full two-port TRL calibration namely a THRU, REFLEC and LINE measurement. A THRU measurement can be done by directly connecting the two test ports together or by connecting them together using a piece of transmission line. For the REFLECT step, identical one-port high reflection coefficient standards are connected to each test port. For the LINE step, a length of transmission line or lines (different in length from the THRU measurement) is inserted between port one and port two. Using these measurements together with the mathematical manipulations, the TRL test fixture was calibrated.

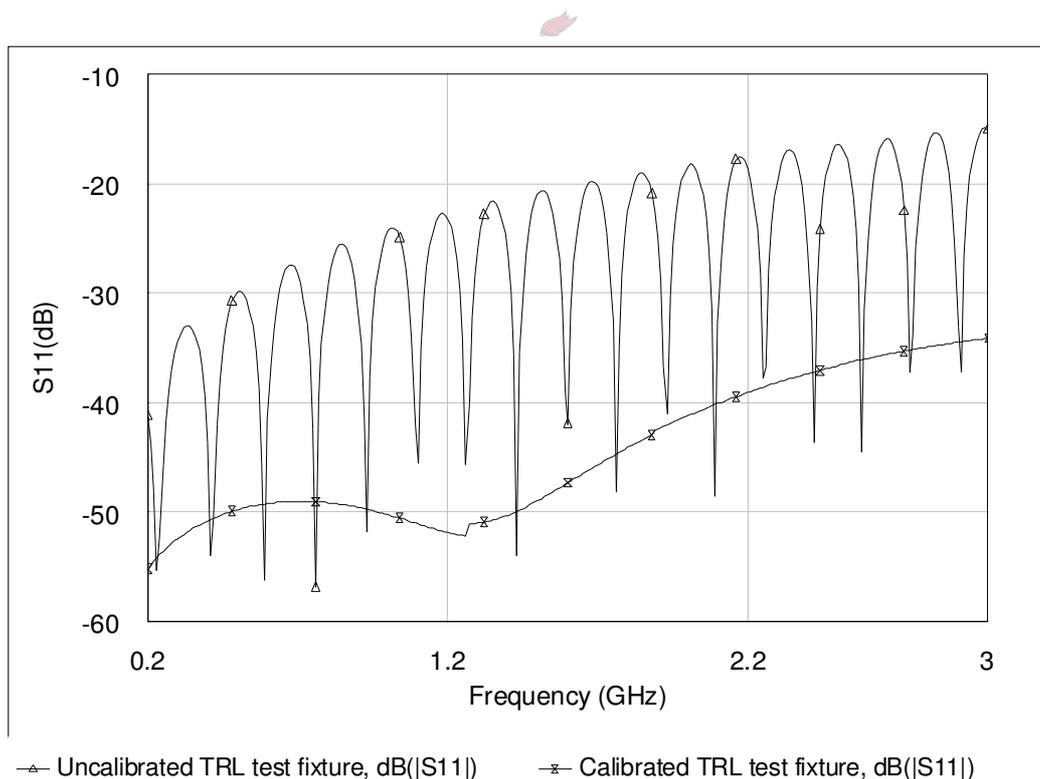


Figure 21.  $S_{11}$  measurement for TRL validation.

The LINE (30mm and 60mm microstrip lines) and REFLECT (double short) standards, were used for the TRL test fixture calibration. A zero length THROUGH was used. After

the calibration was done, the THROUGH connection was remade and  $S_{11}$  of the test fixture was re-measured. The result of this measurement is shown as the bottom trace in Figure 21. This measurement indicates that it would be possible to measure reflection coefficients of less than  $-30\text{dB}$  across the entire frequency range of the TRL test fixture. The insertion loss was also verified to be only fractions of a dB across the entire frequency range. To get an indication of the phase response of the TRL test fixture a known length of line would be needed for comparative phase measurements. These measurements were done when the repeatability of the connection method of the test fixture was verified. As a further indication of the quality of the calibration, the insertion loss (Figure 22) and phase measurement (Figure 23) after calibration of the through connection is also shown.

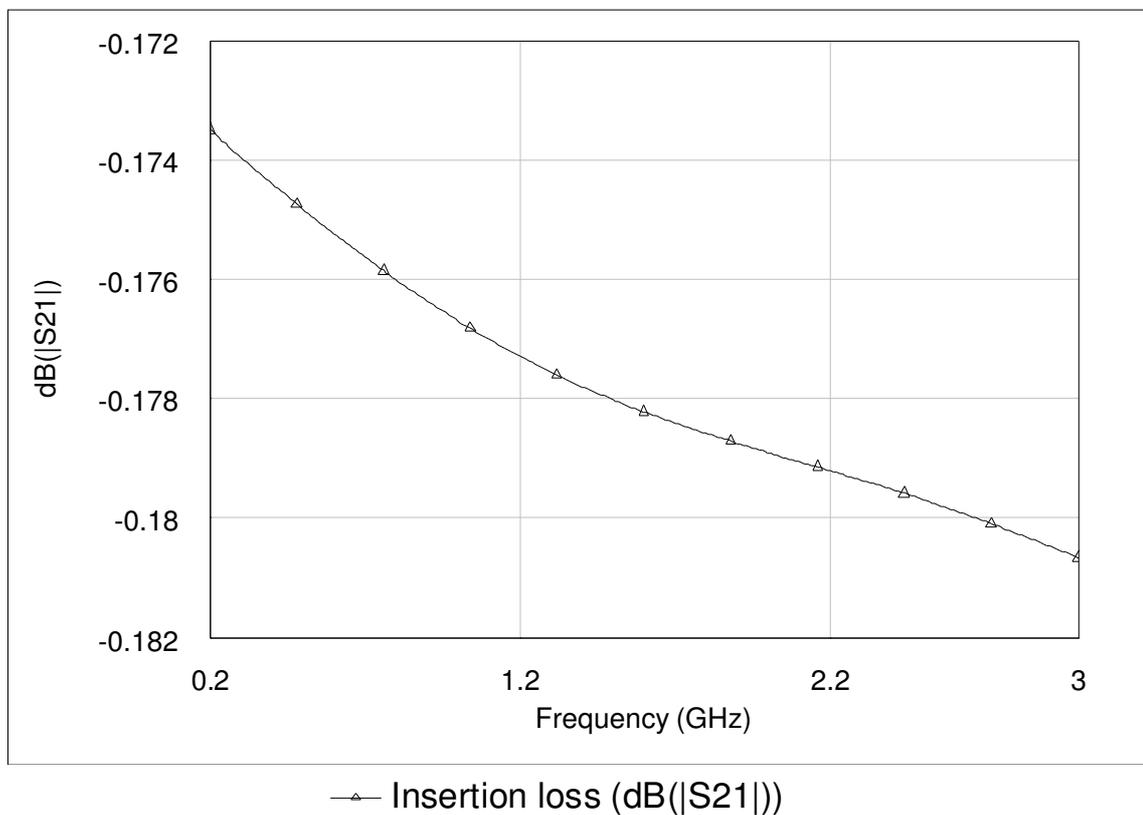


Figure 22. Zero length THRU insertion loss.

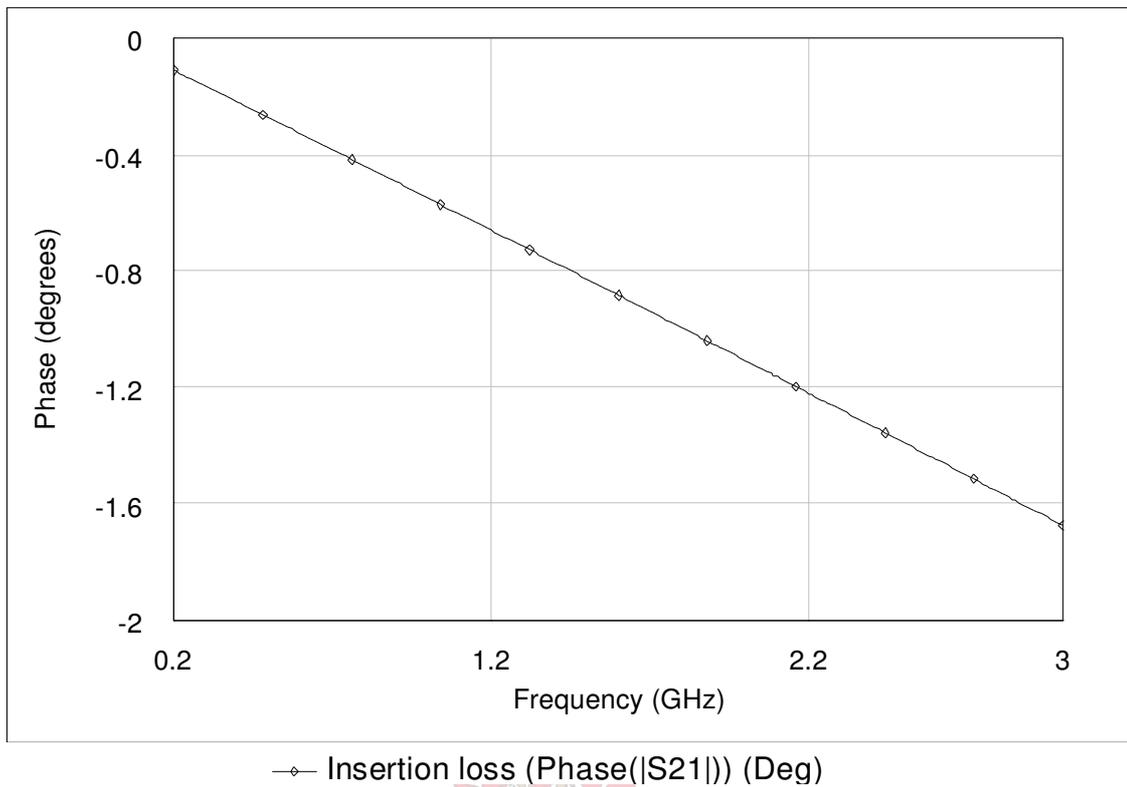


Figure 23. Zero length THRU phase measurement.

#### 4.2.1 Performance Checking

Once a calibration has been performed, and error correction applied, some confidence in measurement integrity must be derived. In coaxial connector families, verification kits exist. These kits contain devices whose characteristics are precisely and independently known. When these devices are measured, the difference between the displayed results and the known values indicate the level of measurement accuracy. In non-coaxial cases, unfortunately, these verification devices may not exist. As a result, it will be difficult to state the absolute accuracy of such measurements. An indication of the absolute accuracy of the calibration can be seen in Figure 22 and Figure 23. (A zero length THRU has no insertion loss and zero degrees phase shift.)

However, there are some performance checks that can be made to provide some insight into the measurement integrity.

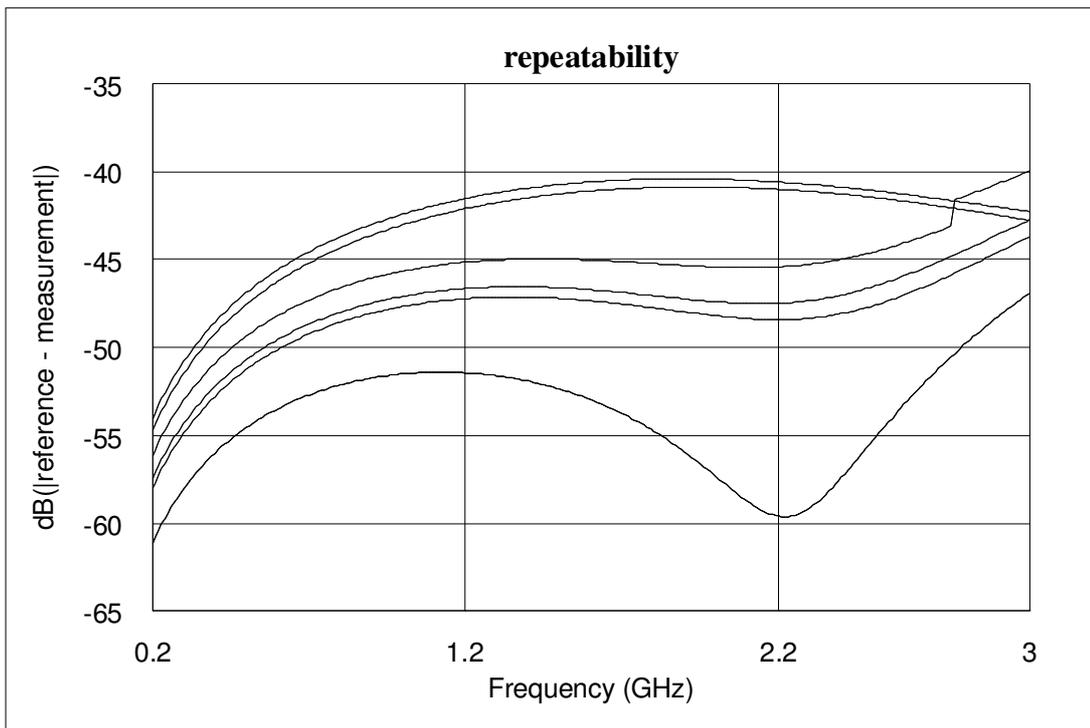


Figure 24.  $S_{11}$  repeatability verification.

Connection repeatability is the largest single factor that will limit the effectiveness of the TRL test fixture calibration. It is a relatively simple matter to evaluate repeatability. This can be done by taking a single S-parameter measurement and storing its response. (In this case  $S_{11}$  was chosen.) The connection is then broken, the same device is reconnected and the measurement is redone. The difference between the two measurements is an indication of the repeatability of the measurement.

The device chosen to check repeatability was a line from an earlier version of a similar TRL test fixture.  $S_{11}$  of the line was measured and stored as a reference. The connection was broken and remade and the measurement repeated. The measurement was then subtracted from the reference and the magnitude (in dB) of a couple of these difference measurements is shown in Figure 24. The repeatability is shown to be better than  $-40$ dB across the frequency span covered by the TRL test fixture. (Figure 24).

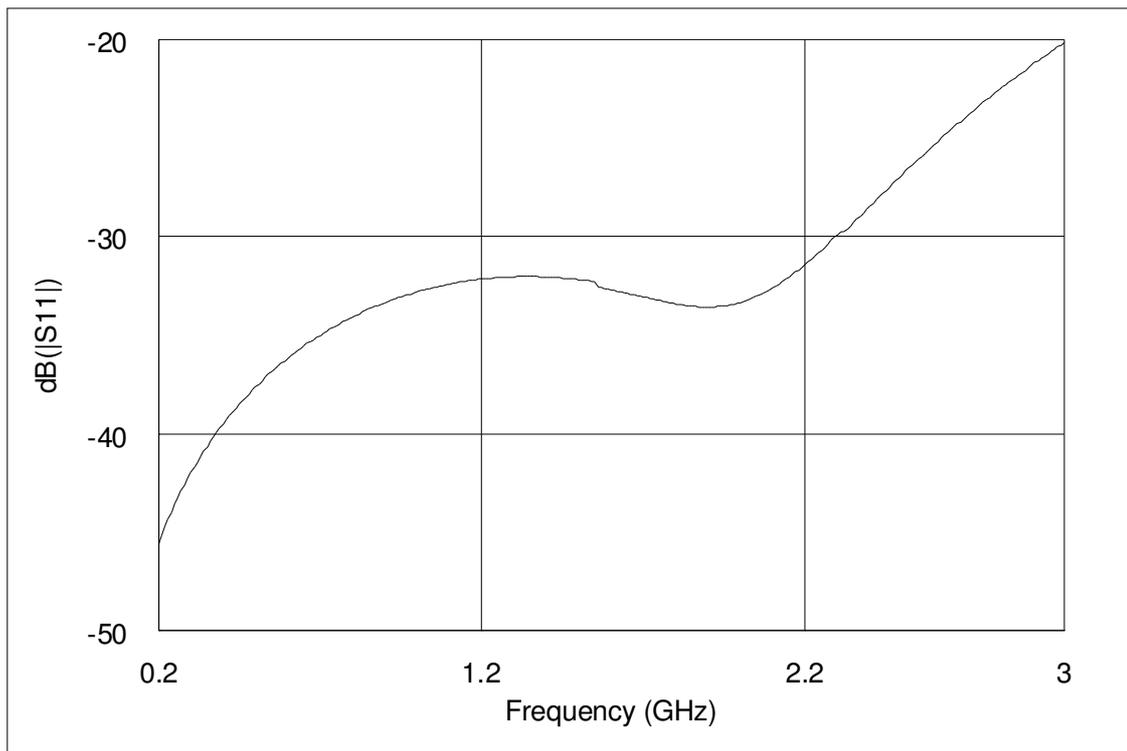


Figure 25.  $S_{11}$  measurement of reference line.

Second to repeatability, the systematic errors are another major source of measurement uncertainty in network analyzer measurements. Some of the effective systematic errors can be measured if an ideal transmission line is available. This transmission line must not be one of the LINES that were used during calibration. Since an ideal transmission line by definition has infinite return loss, any return loss that is measured may be considered an error (to the extent that this line is considered perfect). As an indication as to how well the systematic errors have been removed, the return loss of the same line as measured before is shown in Figure 25. The measured return loss is better than 32 dB across the frequency band of interest. The line used is not perfect. It has a calculated characteristic impedance of  $48\Omega$  at 1.3GHz. From this the calculated reflection coefficient ( $\Gamma$ ) is about  $-34\text{dB}$ , suggesting that the systematic errors have been well taken care off.

Figure 23 shows that good phase measurements can be made. As long as the cables connecting the TRL test fixture to the network analyzer isn't disturbed too much, the repeatability of phase measurements can also be very good.

### 4.3 Stub Tuner Evaluation.

To evaluate the tuner performance 1206 chip resistors and small capacitors were connected between the end of a short line (10mm) and ground. The REFLECT standard of the TRL test fixture used to create a short circuit, was used to establish a good ground connection.

The stub tuner tuning range was verified using resistors of more than  $50\Omega$  as well as resistors of less than  $50\Omega$  combined with small capacitors as loads to be matched to  $50\Omega$  using the stub tuner. The loads matched and the results obtained are shown in Table 1. The ideal would be to cover a tuning range of  $360^\circ$  as discussed in chapter two under the section dealing with the design of the stub tuners. To verify this, an impedance in each of the four quadrants of the Smith chart was matched to  $50\Omega$ . (The chip resistors does have a small amount of inductance as well.) The results show that the stub tuner does indeed have a tuning range of  $360^\circ$ .

Table 1.

<b>Stub tuner tuning range verification</b>		
Tuned reflection coefficient (dB)	Matched Impedance ( $\Omega$ )	Load matched
-30	51.0 -j1.2	1k
-30	50.5 +j2.2	470r
-30	47.8 +j0.5	270r
-30	48.5 - j2.3	150r
-30	51.9 - j1.5	100r
-30	50.2 + j1.7	27r
-40	49.1 -j 0.6	10r
-40	51 - j0.4	4r7
-30	46.2 + j2.1	2r2
-30	47.5 - j1.3	1r
-30	48.6 +j1.8	5r + 12pF
-30	49.9 -j1.6	5r +1.2nH
-30	52.5 -j0.6	220r + 1pF

To get an indication of the limits of impedances that could be characterized by the stub tuner a range of resistors were matched to  $50\Omega$  using the stub tuner. It was found that impedances between  $4.7\Omega$  and  $150\Omega$  were easy to match to  $50\Omega$  at 1.3GHz. Matching a  $2.2\Omega$  or  $270\Omega$  resistor is still not too difficult but anything less than  $2\Omega$  or more than  $300\Omega$  became a challenge with  $1\Omega$  and  $1k\Omega$  the absolute limit. The higher valued resistors are particularly difficult to match as the one stub is turned in very close to its maximum to match these resistors. Examples of these exercises are shown in Table 1. The main restriction was found to be the sensitivity of the tuner when a very low or very high impedance match was attempted.

To get an indication of the masking effect due to the insertion loss of the stub tuner, the  $2.2\Omega$  resistor was removed and the impedance looking back into the stub tuner was measured. The measured value was  $(1.89-j9)\Omega$  at 1.3GHz. Taking the conjugate of this meant the load was a  $1.89\Omega$  resistor in series with about a  $1nH$  inductor. This gives a good indication that reactances down to at least  $2\Omega$  can be characterized using the stub tuner.

#### 4.4 Device Characterization, Amplifier Design and Evaluation

Two devices were characterized, the 1014-12 from GHz Technology and the RZ1214B35Y from Philips.

The 1014-12 is a common base transistor capable of providing 12W of class C, RF power over the band 1GHz to 1.4GHz. This transistor is designed for broadband microwave class C amplifier applications. It includes input pre-matching and utilizes gold metalization and diffused emitter ballasting to achieve high reliability and ruggedness. The data sheet for this device is reproduced in chapter 8 appendix B. This transistor is intended to run off a 28V supply rail. However to demonstrate that it can be used at other supply voltages as well it was characterized at 28V and at 14V.

The RZ1214B35Y is a common base transistor designed for class C, wide band pulse power microwave amplifier applications over the band 1.2GHz to 1.4GHz. This transistor has a multicell geometry, internal input matching, diffused emitter ballasting resistors and gold metalization for ruggedness. Its base is connected to the package flange. The

transistor is optimized to run of a 50V supply rail delivering 35W of RF peak power at L band. The data sheet for this device is reproduced in chapter 8 appendix B.

The data obtained from the characterization process was used to design input and output matches for the experimental amplifiers and the performance of these amplifiers were then compared to the performance of the reference amplifiers based on the manufacturers supplied foil patterns.

#### 4.4.1 Characterization of the GHz1014-12.

This device was characterized at a supply voltage of 28V as suggested by the manufacturer and at a supply voltage of 14V for which the manufacturer supplied no data. The supply rail of a class C amplifier that is well driven into saturation can be lowered by up to about 3dB without to much degradation to the amplifier performance. Beyond this point the amplifier performance starts to degrade sharply [2,3]. Alternatively stated, if the supply rail voltage is lowered by  $x$  dB, the saturated output power also drops by about  $x$  dB without to much change in the output impedance up to about 3dB below the starting rail voltage. A supply rail of 14V is 6dB below the recommended supply rail voltage and the device characteristics should thus be quite different from the characteristics at 28V. From these characterizations it was possible to evaluate the amplifier designed with the data obtained at 28V and to quantify the shift in input and output impedances with a variation in supply voltage.

Table 2. GHz1014-12 (Load pull data)							
Supply voltage (28V)							
Pulse width (300us)							
Duty cycle (1%)							
Frequency (GHz)	Power in (dBm)	Power out (dBm)	Gain (dB)	Device input impedance		Device output impedance	
				Re	Im	Re	Im
1.2	34	41.8	7.8	3.2	4.8	6.8	1.1
1.25	34	41.6	7.6	3.6	4.5	4.4	1.1
1.3	34	41.4	7.4	4	4.3	2.5	-0.03
1.35	34	41.1	7.1	4.4	4.4	1.6	-1.1
1.4	34	41	7	4.6	4.6	1.1	-2.2

The characterization procedures described in chapter three were used to obtain the impedances that the device would like on its input and output terminals. The conjugate of these impedances as well as the other parameters measured during the characterization process are presented in Table 2 for comparative purposes. These impedances were now used to design, as described in chapter three, matching foil patterns for the input and output circuits. The matching foil patterns were manufactured, inserted into the test fixture and the performance of the integrated amplifier was evaluated. The measured performance figures of this amplifier are represented in Table 4 for comparative purposes.

#### 4.4.1.1 REFERENCE AMPLIFIER (GHZ1014-12).

The foil pattern supplied on the data sheet was scaled with the help of an electromagnetic simulator (Microwave Office) for a different substrate. (Rogers 6010, 25mil with ½ oz Cu.) An amplifier was built using this foil pattern. This amplifier was evaluated but due to the amount of spurious frequencies generated, the ringing on the supply lines and the bad pulse shape it was decided to try to improve the DC supply of this amplifier by taking it through a second iteration. The DC supply was improved by using RF shorted quarter wave DC feed lines. The remains of this amplifier are shown in Figure 26. (It was butchered in an attempt to get it to work from a 14V supply line.) This second generation amplifier was evaluated and the test results were recorded in Table 3 for comparison to the amplifier designed with the measured load pull data.

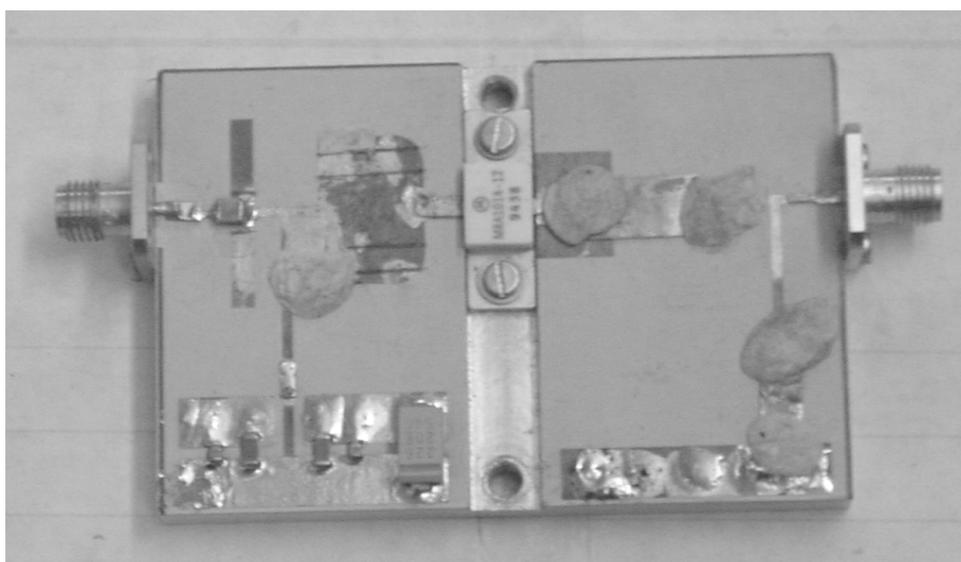


Figure 26. Remains of the reference amplifier (GHZ1014-12)

Table 3. GHz1014-12 (Data book foil pattern)								
Supply voltage (28V)								
Pulse width (300us)								
Duty cycle (1%)								
Frequency (GHz)	Power in (dBm)	Power out (dBm)	Gain (dB)	Efficiency (%)	Conjugate foil input impedance		Conjugate foil output impedance	
					Re	Im	Re	Im
1.2	34	41.3	7.3	55	3.4	6.1	6.2	1
1.25	34	41.6	7.6	62	3.4	5.8	4.1	1
1.3	34	41.2	7.2	53	3.4	5.4	2.6	0.1
1.35	34	40.8	6.8	48	3.4	5.1	1.6	-0.9
1.4	34	40.5	6.5	54	3.4	4.8	1.1	-1.9

#### 4.4.1.1.1 Evaluation of Pulse Shape and Spectral Purity.

(GHz1014-12, reference amplifier.)

The microwave chokes as suggested by the manufacturer has an inductance of about 75nH. These together with about 55µF total capacitance on the DC feed to the collector were used on the first attempt of a reference amplifier. The resonance frequency of this combination is 78kHz. Although the output power, gain and efficiency of the amplifier were about what was expected, the amplifier produced many spurious oscillations. The pulse shape looked really bad with the ringing (~80kHz) that was observed on the DC supply, amplitude modulated on to the leading edge and pulse top of the output RF pulse. Because of this, a second reference amplifier as described in the previous paragraph was produced. (Figure 26.) The ringing on the DC supply of the second amplifier was down to about 75mV, which is still unacceptable for a radar amplifier, but good enough for comparison purposes. The amplifier however still produced many spurious oscillations with two very strong frequency components at about 900MHz and 60MHz. It was initially suspected that these might be inter modulation products coming from the signal generator or driver amplifier as the amplifier was stable when the input was terminated into 50Ω without a drive signal present. However, it was verified that this was not the case. The exact frequency of the spurious oscillations was a function of the drive frequency and their level was slightly less than 18dB below the carrier. With a drive signal present the

amplifier also produced spurious signals in the 500MHz to 800MHz frequency band. This however was always more than 40dB below the carrier.

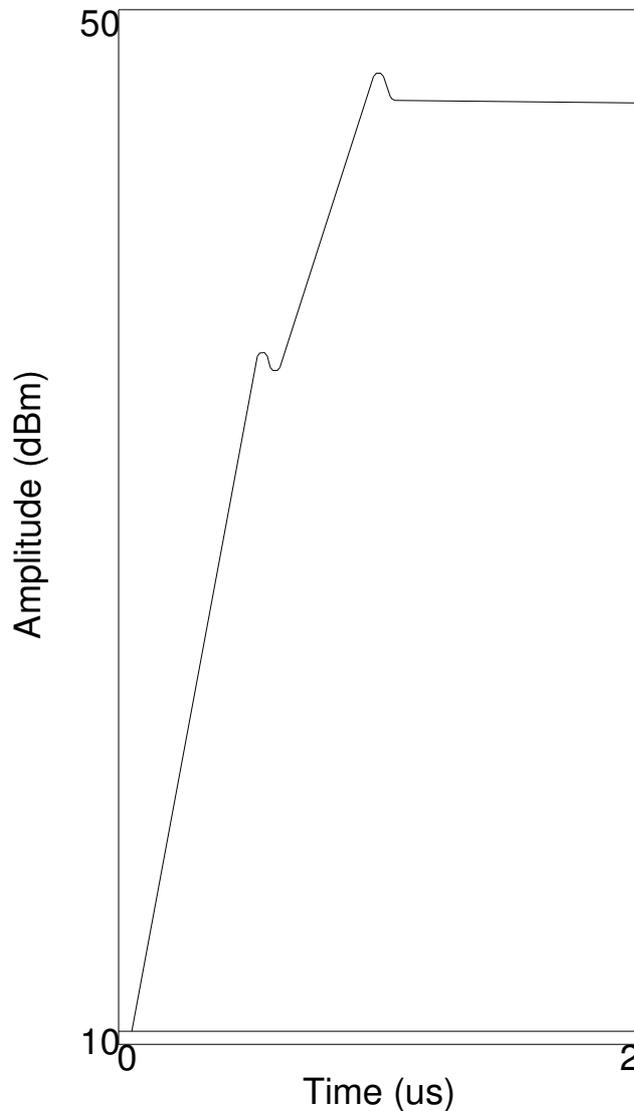


Figure 27. Leading edge of the reference amplifier output pulse.

A peak power meter with a diode type detector was used for the peak power and pulse shape measurements. The leading edge of the output pulse, measured at 1.3 GHz, with two clearly distinguishable disturbances is shown in Figure 27. Figure 27 also shows that the rise time of the output pulse is quite slow, about one  $\mu$ s. The pulse droop was about 1.5dB. This is a function of the capacity of the storage capacitor on the output of the time

gating circuit (DC bias) and can be improved by increasing this capacitance. The observed fall time, about 100ns, is much longer than expected. (The drive pulse had a 10ns rise and fall time.) For a class C amplifier one would expect the fall time to be less than that of the drive pulse as the device normally switches off sharply once the drive signal falls below the switch on voltage level. The reason for the long fall time is likely due to some low frequency (DC) phenomena registered by the diode sensor of the peak power meter. Decreasing the size of the 100pF DC blocking capacitors should improve this situation.

The shape of the leading edge of the pulse is likely due to the ringing of the DC supply and/ or the spurious signals observed at 60MHz and 900MHz. A digital sampling spectrum analyzer was available for the low frequency measurements. (Up to 3GHz.) With this spectrum analyzer and a bit of control software as discussed in chapter three, it was possible to determine that the spurious signal at 900MHz only existed during the leading edge of the pulse. However, none of the time gated windows that could be implemented could isolate the 60MHz spurious signal. The spurious signals could be due to short-lived instabilities as the drive signal moves through certain levels [11]. Certainly, the observed spectrum hints toward such an explanation but this is still speculative and not yet proven.

It must also be noted that the pulse shape and frequency spectrum of the amplifier was measured at each frequency of interest. The pulse shape changed very little with a change in frequency, with the main change being the peak power. (Pulse top). The relative position of the disturbances on the leading edge of the pulse varied slightly with drive frequency. However, no clear pattern could be seen between their relative position and the exact frequency and levels of the 60MHz and 900MHz spurious signals.

The amplifier harmonics was measured up to 10 GHz. The second harmonic was consistently the worst, however this was always more than 55dB below the carrier for any frequency across the band of interest. The harmonics grew progressively worse towards the upper end of the frequency band of interest, with the second harmonic 56dB below the carrier at 1.4GHz. (1.2GHz to 1.4GHz).

Note: The measurement of the spurious oscillations and harmonic signals is quite time consuming. To guarantee that the noise floor is low enough, only a narrow frequency span

can be scanned at any time. The center frequency then has to be swept across the entire frequency range of interest and all the observed frequency components have to be recorded. (1MHz to 10GHz) The observation of the close in spectrum is even more time consuming as this has to be done with a very narrow frequency span and a slow time sweep. (Several seconds.) This has already been discussed in chapter three in more detail.

The gain, efficiency and output power measured for the amplifier is recorded in Table 3. To verify that the transistor parameters changes quite a bit with a variation in supply voltage, the supply voltage was lowered to 14V and an attempt was made to tune (optimize) the amplifier for reasonable output power across the band of interest. This however did not succeed and the effort essentially destroyed the amplifier, proving that the transistor characteristics did change drastically by lowering the supply rail voltage by 6dB. The result of this effort can be seen in Figure 26.

#### 4.4.1.2 EVALUATION OF THE (GHZ1014-12) AMPLIFIER WITH A MULTIMATCH DESIGNED FOIL PATTERN.

The measured impedances were put into MultiMatch for amplifier synthesis and the most promising topologies chosen. (Table 2 served as input.) The foil patterns of these topologies were generated and exported to an electromagnetic simulator (Microwave Office) for further verification. The same substrate as used for the reference amplifier was chosen for this amplifier to simplify the size comparison. (Rogers 6010, 25 mil, 1/ 2oz Cu.) The foil pattern of the input match was manufactured first and used in the test fixture to obtain the device output impedances. Figure 28 shows the generated input match foil pattern.

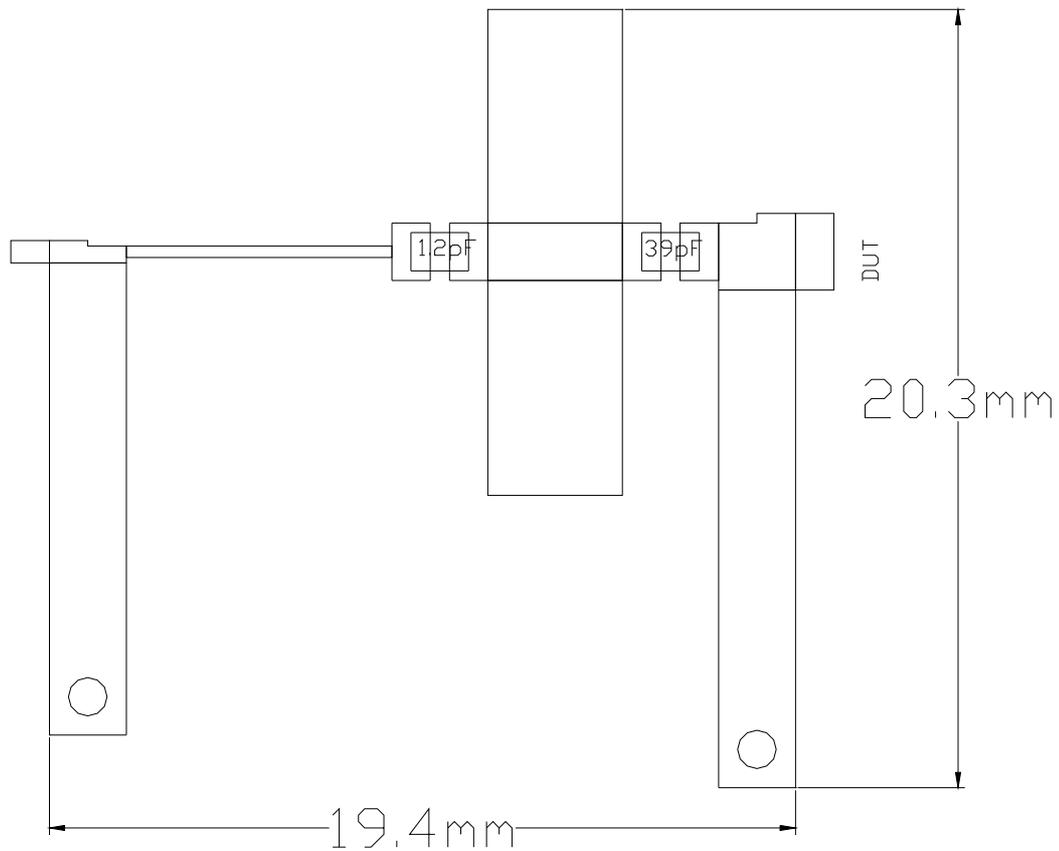


Figure 28. Input match foil pattern generated by MultiMatch from the load pull data measured for the GHz1014-12.

The shorts at the ends of the two-shorted stubs in Figure 28 were implemented with short pieces of Copper wire soldered on both sides of the PCB. This grounding technique can be easily simulated and proved to give good results. The two series capacitors shown in Figure 28 are part of the six-element match and components with a 1% tolerance were used to be on the safe side. The topology for the input match comes close to the ideal of a small bias inductor very close to the emitter tab. The roughly  $24\Omega$  characteristic impedance at 1.3GHz of this biasing line should also give reasonable protection against low frequency oscillations [2].

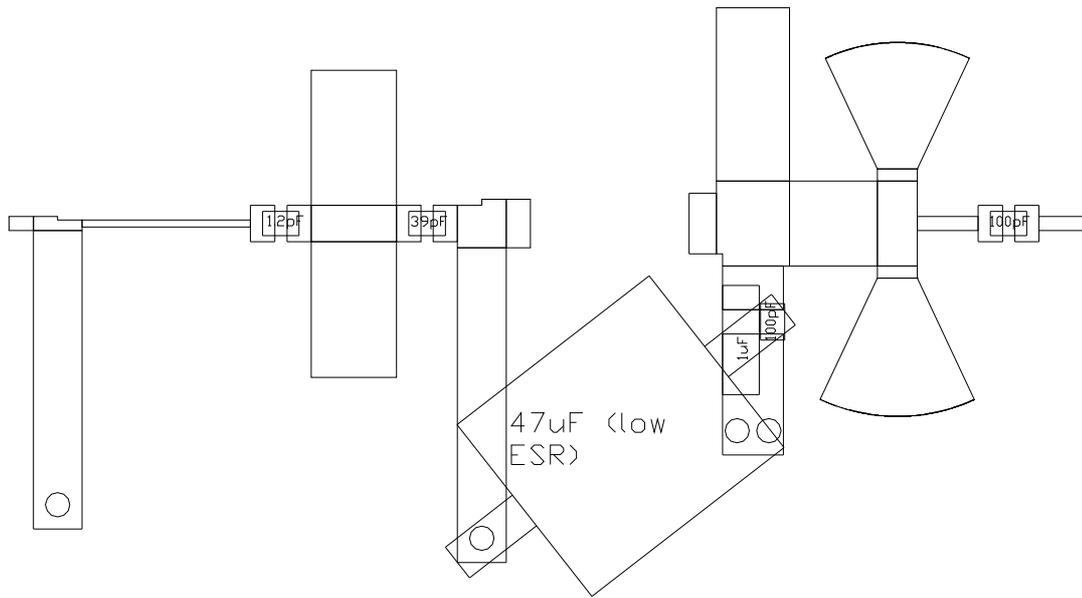


Figure 29. Complete foil pattern for the MultiMatch generated GHz1014-12 amplifier.

The topology for the output match comes as close to the ideal as one can wish for. It is also small and compact. Further more, it creates the opportunity to mount the low ESR capacitor, used on the output of the time gating circuit to control the pulse droop, in a close to optimum position. The value of this topology is reflected in the measured pulse shape and spectrum of this amplifier. The foil pattern of the complete amplifier is shown in Figure 29.

The spectrum of this amplifier is extremely clean. The measurement floor of the measurement setup was 70dB below the carrier. (The precautions needed to enable one to have such a dynamic range were discussed in chapter three.) No spurious frequency components could be observed above 70dB below the carrier. The harmonic performance of this amplifier was slightly worse than the reference amplifier with the second harmonic again being the highest at 48dB below the carrier at 1.3GHz.

Note: A pulsed signal means that the close in spectrum of the signal would be made up out of a combination of sync functions. The position of the nulls and peaks would be determined by the repetition frequency and the duty cycle. To be able to measure this a very slow sweep time might be needed for the sweep of the spectrum analyzer. However,

the sync functions at worst would die away within a couple of MHz from the carrier. An amplifier of several hundred MHz bandwidth with spurious components so close to the carrier would be dangerous and would likely have to be redesigned. (In band spurious can't be fixed by any of the normal techniques to kill out of band oscillations.)

The generated foil patterns were broken up and the various pieces were analyzed in an electromagnetic simulator (Microwave Office). The S-parameter files of these simulations were pulled into a linear simulator (Microwave Office) and the complete matches were analyzed for comparative purposes. The results are presented as part of Table 4.

Both foil patterns were also evaluated for sensitivity to small dimensional variations. This was done by adding small pieces of shim to various points on the foil patterns. Both patterns were found to be quite tolerant to small dimensional changes. The optimized input and output matches are shown in Figure 30.

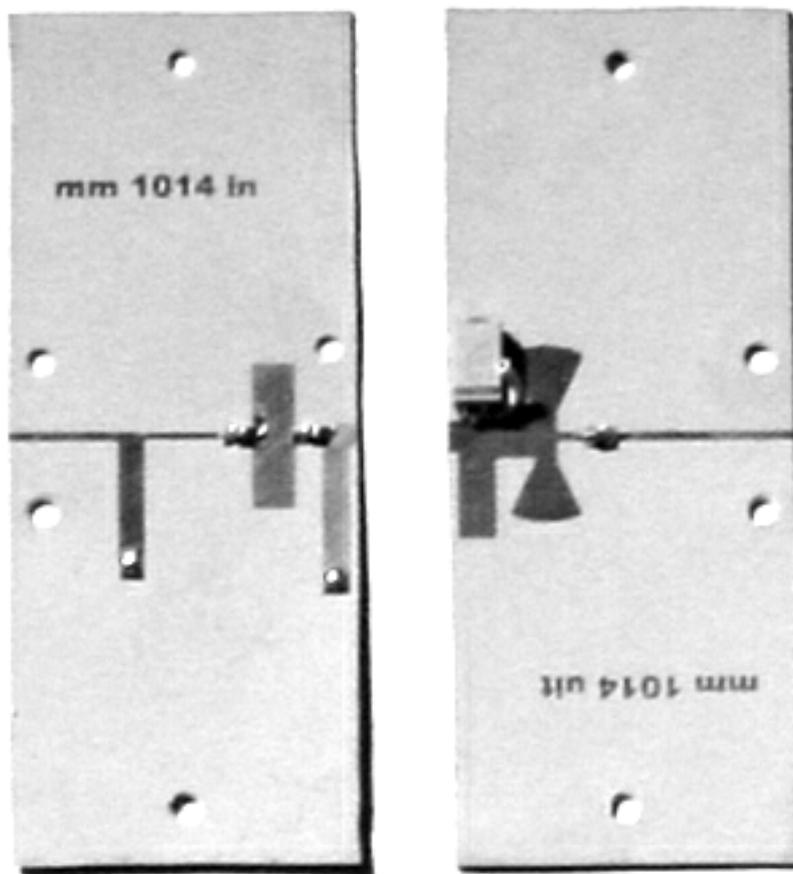


Figure 30. Optimized foil patterns for the MultiMatch generated GHz1014-12 amplifier.

Table 4. GHz1014-12 (MultiMatch generated amplifier)								
Supply voltage (28V)								
Pulse width (300us)								
Duty cycle (1%)								
Frequency (GHz)	Power in (dBm)	Power out (dBm)	Gain (dB)	Efficiency (%)	Conjugate foil input impedance		Conjugate foil output impedance	
					Re	Im	Re	Im
1.2	34	41.5	7.5	58	3.1	5.7	6.28	1.22
1.25	34	41.3	7.3	60	4.1	4.2	4.5	0.72
1.3	34	41	7	59	4.9	3.9	3.09	-0.39
1.35	34	41.1	7.1	61	4.7	4.2	2.18	-1.63
1.4	34	41	7	60	3.7	4	1.61	-2.79

#### 4.4.1.2.1 Evaluation of Pulse Shape. (GHz1014-12, MultiMatch Generated Amplifier.)

The pulse shape of this amplifier was also evaluated for comparative purposes. A pulse with 10ns rise and fall times was used as input. The rise time of the output pulse was measured as 120ns with a very clean leading edge. The leading edge of this pulse measured at 1.3GHz is shown in Figure 31. The pulse droop was measured as 1.3dB. From this it is clear that the pulse shape performance of this amplifier is vastly superior to the performance of the reference amplifier. The main reason for this is very likely the excellent matching topologies that could be found for this amplifier. A further benefit of the good matching topologies is the relatively flat power-gain of this amplifier, although it is unlikely that the flat gain can explain the pulse shape. The pulse shape is mainly influenced by the amplifier stability and the inductance in the DC feed path.

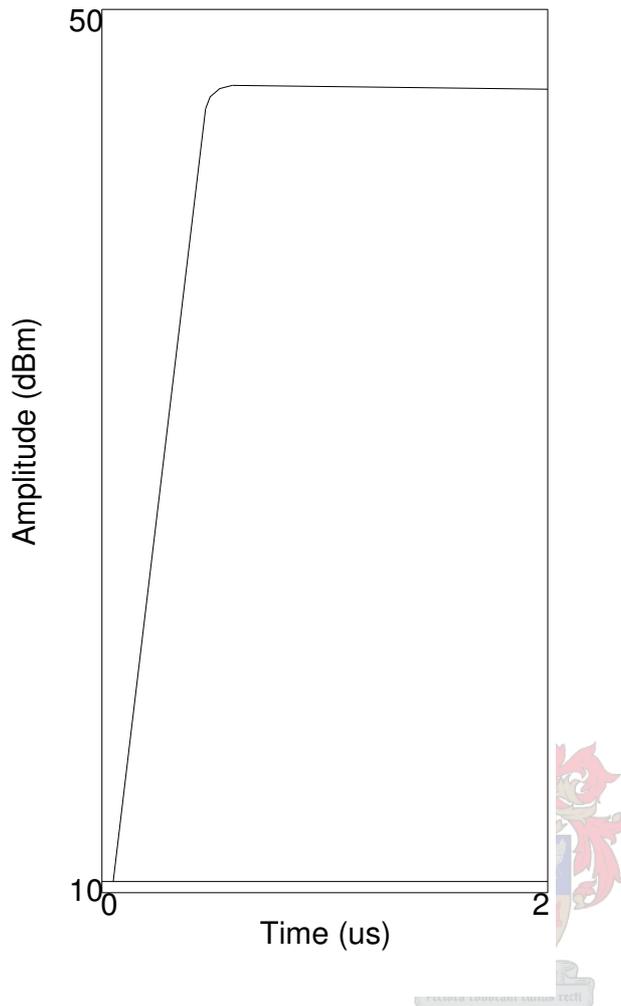


Figure 31. Leading edge of the MultiMatch generated amplifier output pulse.

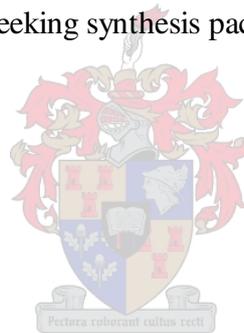
### **MTI Performance Evaluation.**

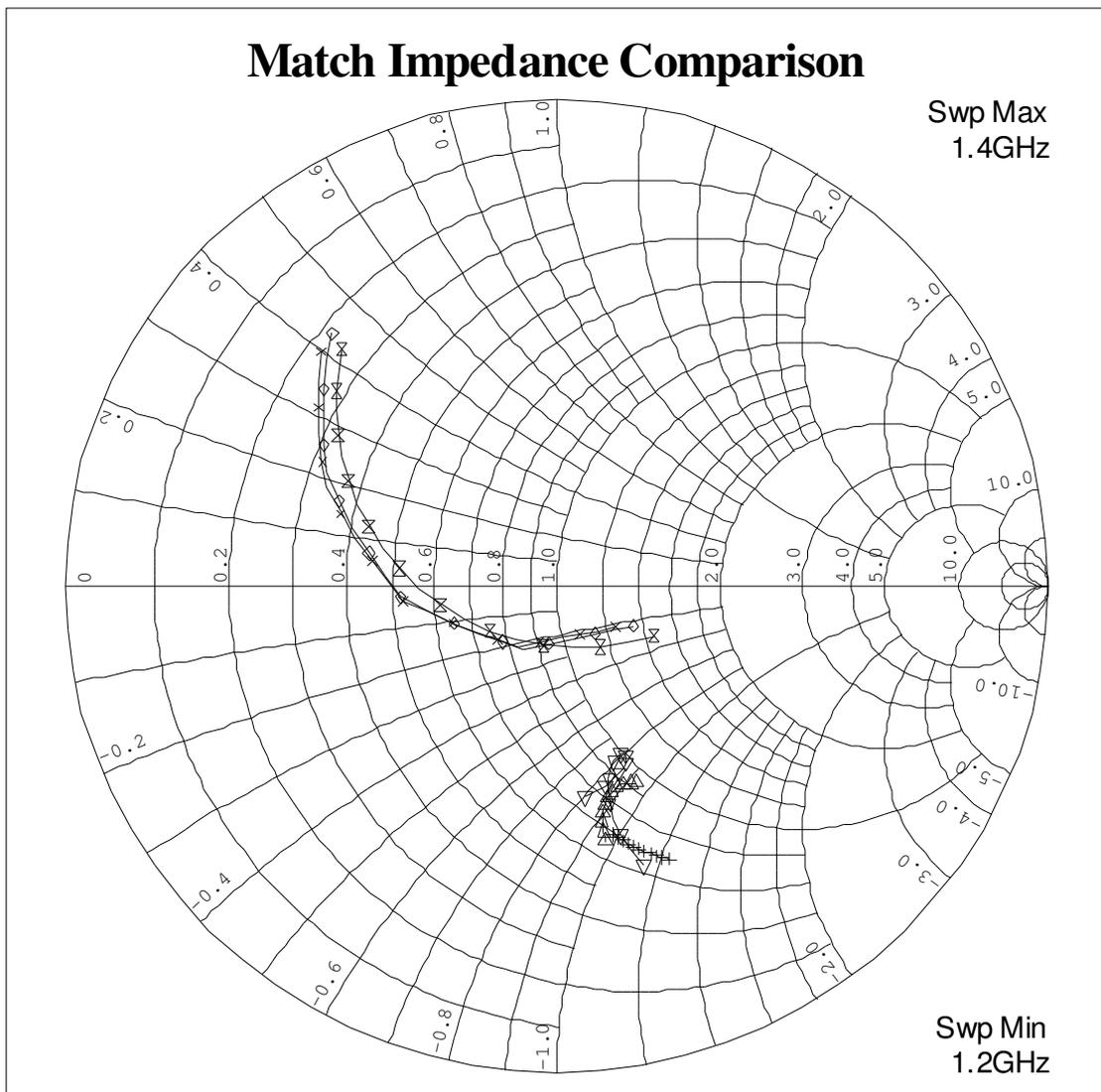
The in pulse stability parameters of a radar power amplifier with respect to its MTI performance, is of much lesser importance than the pulse to pulse stability parameters. An in pulse amplifier deficiency can easily be compensated for by adjusting some of the other system parameters. The crucial stability parameters regarding MTI performance are the pulse-to-pulse stability parameters. The measurement of these parameters is very difficult and expensive and is normally verified by verifying the overall system MTI performance. However, a good indication of the pulse-to-pulse MTI performance of an amplifier can be obtained from its pulse shape and spurious response. Amplifiers with a very smooth and clean pulse shape with good spurious performance normally have excellent pulse-to-pulse

phase and amplitude stability. By looking at the pulse shape and spurious performance of this amplifier, it should have excellent MTI performance.

#### 4.4.1.2.2 Impedance and Output Power Evaluation. (GHz1014-12)

A graphical comparison of the measured load-pull impedances as well as the impedances of the various foil patterns is shown in Figure 32. From the graphical presentation of the impedances, it is evident that all three sets of impedances lie fairly close together. It was already shown by just looking at the pulse shape characteristics that the performance of the MultiMatch generated amplifier is superior to that of the reference amplifier. The topologies to achieve these impedance matches are quite different though and here in lies the strength of an optimum seeking amplifier synthesis package such as MultiMatch. As a result, the proposed method to synthesize pulsed amplifiers depends heavily on the availability of such an optimum seeking synthesis package.





- x— Data Book foil pattern (1014 output).
- △— Conjugate measured load-pull impedance (1014 input)
- ◇— Conjugate measured load-pull impedance (1014 output)
- ▽— MultiMatch Generated foil pattern (1014 input)
- +— Data Book foil pattern (1014 input).
- ⊗— MultiMatch Generated foil pattern (1014 output)

Figure 32. A graphical comparison between the measured load-pull, data sheet foil pattern and the MultiMatch generated foil pattern impedances. (5Ω Smith Chart.)

The small spread in input impedances also indicate that the pre-matching of the transistor is very good and it likely would be very difficult to try to use this device outside of the designated frequency band.

The MultiMatch generated input match foil pattern and the data book input match foil pattern is about the same physical size. However, the MultiMatch generated output match foil pattern is only as big as the first line transformer of the data book foil pattern. A size comparison can be made by looking at Figure 30 and Figure 44 in chapter 9 Appendix C. The block on the left in Figure 44 is the data book input match and the block on the right is the output match. The MultiMatch generated foil patterns mount onto the same carrier inserts as can be seen from the mounting holes. Although the MultiMatch generated foil pattern is smaller than the data sheet foil pattern, it can be seen by comparing the figures in Table 3 and Table 4 that the real improvement over the data sheet based amplifier lies in the pulse shape, spectral performance, gain flatness and efficiency of the MultiMatch generated amplifier. Regarding output power, it can be seen from Figure 33 that the power gain of the MultiMatch generated amplifier is reasonably flat with 0.5dB variation. However, both the data-book and MultiMatch generated amplifiers produced power gain that stayed within 0.5dB of the load-pull figures. To decide which amplifier has superior performance regarding output power would depend on the specific application.

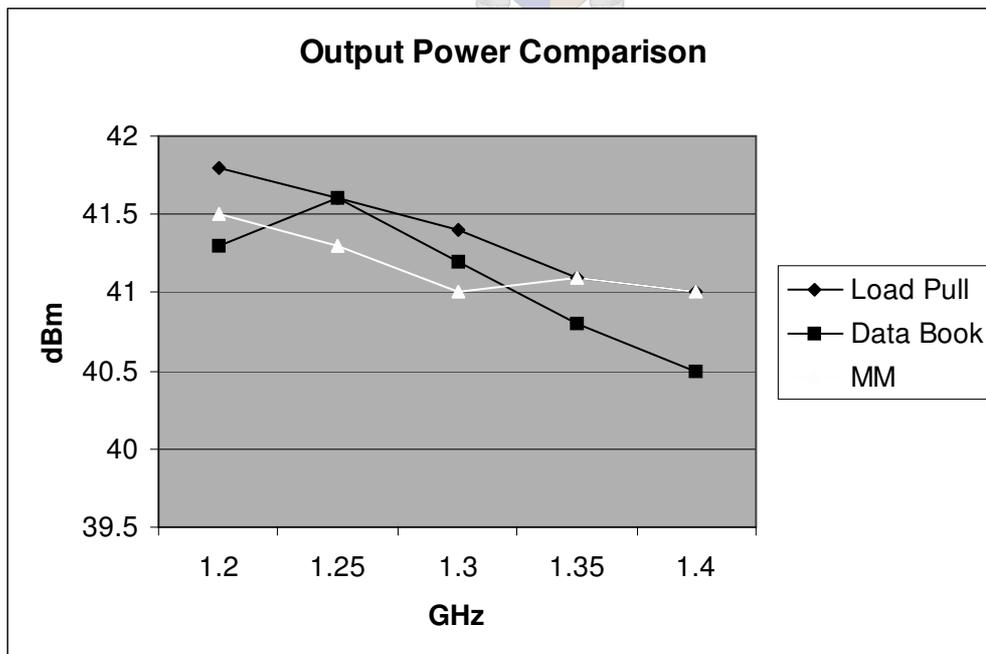


Figure 33. Output Power Comparison (GHz1014-12).

#### 4.4.2 Reduced Supply Rail (14V) Characterization of the GHZ1014-12

The device input impedance was measured as before. It was found to be fairly close to the input impedance that was measured with the device biased at 28V. This is unexpected in the light of the effort it took to try to optimize the reference amplifier for operation at 14V. (This can likely be explained by the interdependency of the input and output loading.) Because the input match only affects the gain, the same input match foil pattern generated by MultiMatch for the GHZ1014-12 biased at 28V, was used to characterize the output impedance of the device with a 14V supply rail. The results are presented in Table 5.

Table 5. GHZ1014-12 (Load pull data)							
Supply voltage (14V)							
Pulse width (300us)							
Duty cycle							
(1%)							
Frequency (GHz)	Power in (dBm)	Power out (dBm)	Gain (dB)	Conjugate foil input impedance		Conjugate foil output impedance	
				Re	Im	Re	Im
1.2	28	35.9	7.9	3.3	6.16	6.3	4.68
1.25	28	36.1	8.1	3.64	5.63	4.55	4.41
1.3	28	35.7	7.7	4.04	5.44	3.14	3.05
1.35	28	35.4	7.4	4.42	5.61	2.22	1.92
1.4	28	35.6	7.6	4.7	5.73	1.58	0.78

By comparing the figures in Table 2 and Table 5, it can be seen that the power gain stayed almost the same with the lower supply rail voltage and the saturated output power was reduced by about the same 6dB of the supply rail voltage reduction. It can also be seen that only the reactance of the input impedance changed a little, the real part of the input impedance stayed almost the same. This is the likely explanation why the gain stayed almost the same, since the gain is mainly influenced by the input loading of the amplifier. A graphical representation of the measured output power is shown in Figure 34.

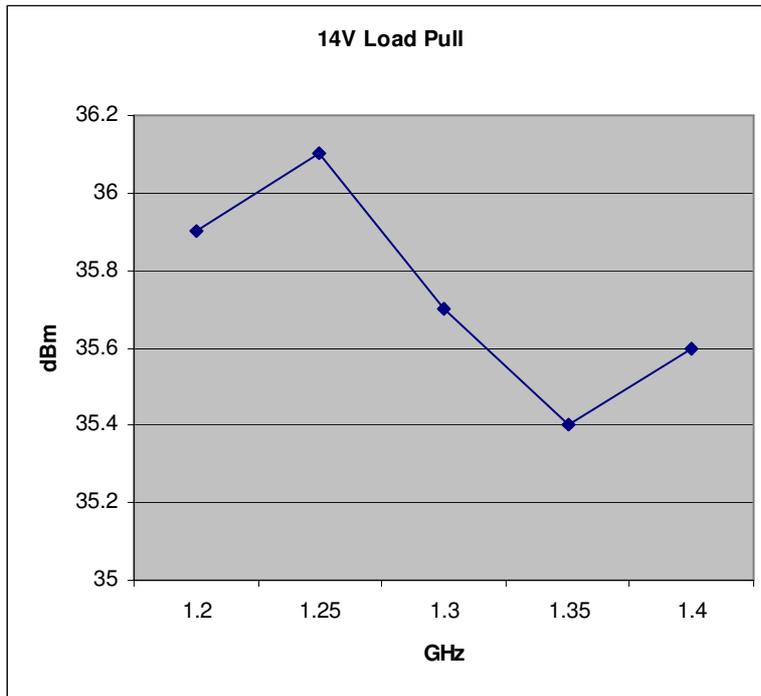
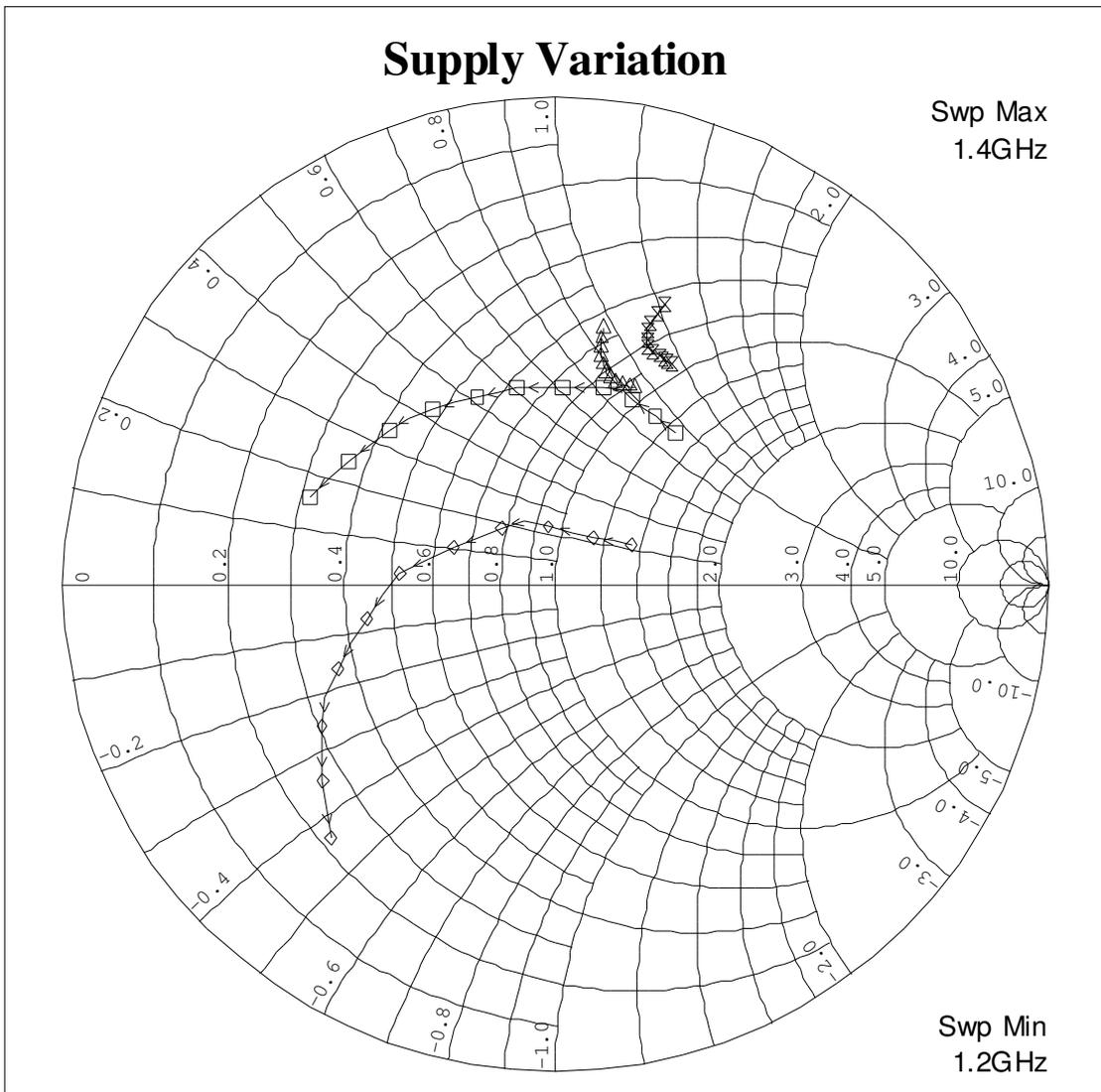


Figure 34. Graphical representation of the output power of the GHz1014-12 biased at 14V.

With this data, it would be possible to design an output match for an amplifier using the GHz1014-12 biased at 14V. By graphically comparing the impedance changes with a change in supply voltage, it becomes evident why it was difficult to tune the data sheet foil pattern for the device to work with a 14V supply voltage. The input impedance changed only slightly with the reduction in supply voltage, but the output impedance moved to a totally different domain of the Smith chart. At the higher end of the frequency band, it even changed from capacitive to inductive. A graphical representation of the measured impedances is shown in Figure 35.



- △ Measured load-pull input impedance (1014 {28V})      ◇ Measured load-pull output impedance (1014 {28V})
- Measured load-pull output impedance (1014 {14V})      × Measured load-pull input impedance (1014 {14V})

Figure 35. Impedance variation with a change in supply voltage. (GHz1014-12) (5Ω Smith Chart.)

#### 4.4.3 Investigative Comparison for the RZ1214B35Y Device.

This device was characterized at a supply voltage of 50V as suggested by the manufacturer. (The data sheet for this device is presented in chapter 8 appendix B.) As before the procedures described in chapter three were used to obtain the impedances that the device

would like on its input and output terminals. The conjugate of these impedances are presented in the tables for comparative purposes. These impedances were now used to design, as described in chapter three, matching foil patterns for the input and output circuits. The matching foil patterns were manufactured, inserted into the test fixture and the performance of the integrated amplifier was evaluated. The measured load-pull data is presented in Table 6 for comparative purposes.

Table 6. RZ1214B35Y load pull data							
Supply voltage (50V)							
Pulse width (300us)							
Duty cycle (1%)							
Frequency	Power in	Power out	Gain	Device input impedance		Device output impedance	
(GHz)	(dBm)	(dBm)	(dB)	Re	Im	Re	Im
1.2	39	46.6	7.6	9.8	2.3	3.1	0.5
1.25	39	46.8	7.8	8.8	1.5	2.9	0.7
1.3	39	46.5	7.5	7.5	1.1	2.7	0.8
1.35	39	46.6	7.6	6.3	1.6	2.5	1.4
1.4	39	46.1	7.1	5.5	2.1	2.5	1.8



#### 4.4.3.1 REFERENCE AMPLIFIER (RZ1214B35Y) IMPLEMENTED WITH DATA SHEET FOIL PATTERNS.

The foil pattern and biasing technique as suggested by the manufacturer was implemented almost exactly on a Rogers 6010, 25mil, ½ oz Copper substrate. This foil pattern however required quite a bit of optimization to achieve the required broadband performance. (About 5 hours of tuning.) The result, including gain and efficiency, is recorded in Table 7. For comparative purposes the optimized input and output foil patterns of this amplifier, where pulled into an electromagnetic simulation computer aided design package (Microwave Office) to get an estimate of the impedances that it presented to the DUT. These impedances are also recorded in Table 7. The result of the optimization process is shown in Figure 36.

Table 7. RZ1214B35Y (Data book foil pattern measured data)								
Supply voltage (50V)								
Pulse width (300us)								
Duty cycle (1%)								
Frequency (GHz)	Power in (dBm)	Power out (dBm)	Gain (dB)	Efficiency (%)	Conjugate foil input impedance		Conjugate foil output impedance	
					Re	Im	Re	Im
1.2	39	44.4	5.4	33	6.1	1.8	2.4	2
1.25	39	45.2	6.2	35	5.9	1.9	2.4	1.7
1.3	39	45.1	6.1	34	5.4	2	2.2	1.4
1.35	39	44.4	5.4	32	4.8	1.9	2.1	1.1
1.4	39	44.3	5.3	31	4.2	1.6	1.9	0.9

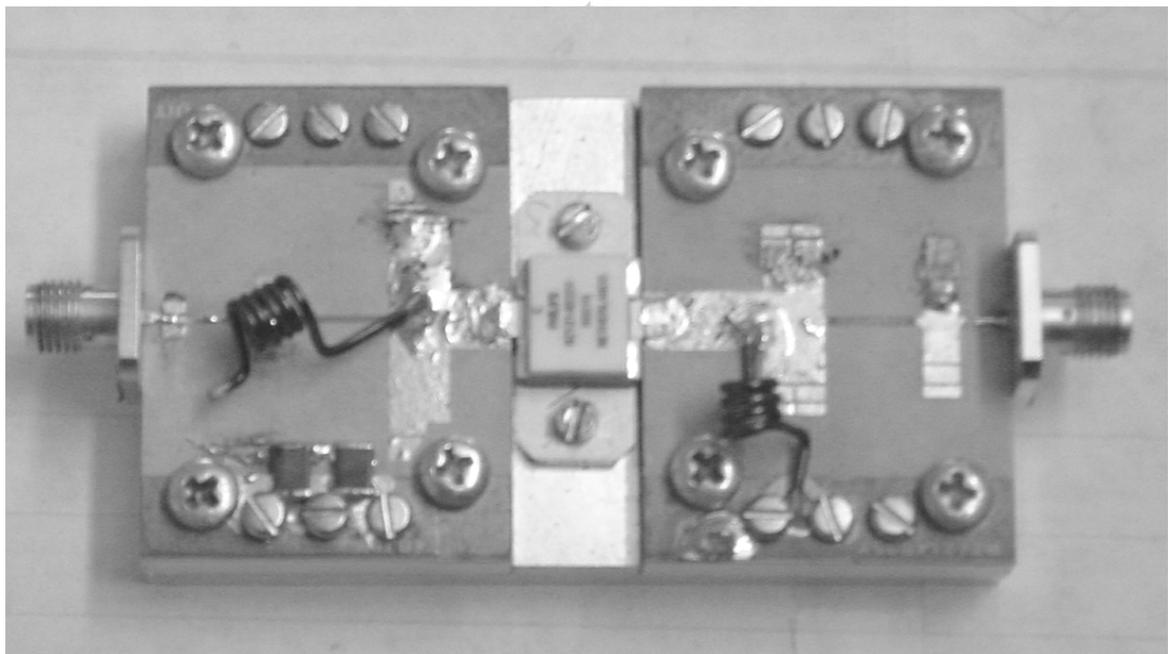


Figure 36. RZ1214B35Y Optimized data sheet foil pattern.

#### 4.4.3.1.1 Evaluation of pulse shape and spectral purity (RZ1214B35Y).

This amplifier had a tendency to oscillate in band and the time gating circuitry proved invaluable for the protection of the device during the optimization procedure. However, once the amplifier was optimized it was stable and no spurious frequency components above 60dB below the carrier was observed. There was still 110mV ringing and overshoot on the supply line and this is the likely cause of the observed disturbances on the leading edge of the output pulse as shown in Figure 37. Using smaller RF chokes can reduce this and since the pulse droop was only about 1dB, one might compromise by using smaller storage capacitors. The use of smaller RF chokes would also improve the rather slow (900ns) rise time of the pulse.

The harmonics of this amplifier was measured up to 10GHz. All the harmonics up to the seventh harmonic was above  $-60\text{dBc}$ , with the second harmonic the strongest at  $-43\text{dBc}$  measured at 1.3GHz. The rather bad harmonic response of this amplifier is the likely explanation for the bad efficiency figures of this amplifier as reflected in Table 7. (Class C amplifiers with well terminated harmonics, essential for good efficiency, usually also has good harmonic spectral behavior.)

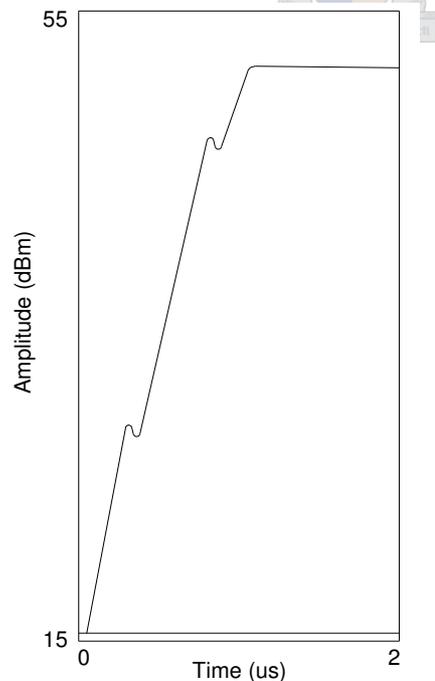


Figure 37. Output pulse leading edge at 1.3GHz. (RZ1214B35Y)

#### 4.4.3.2 EVALUATION OF THE (RZ1214B35Y) AMPLIFIER WITH A MULTIMATCH DESIGNED FOIL PATTERN.

The measured impedances of Table 6 were put into MultiMatch for amplifier synthesis and the most promising topologies were chosen. The foil patterns of these topologies were generated as described in chapter three and exported to an electromagnetic simulator (Microwave Office) for further verification. The same substrate as used for the reference amplifier was chosen for this amplifier to again simplify the size comparison. (Rogers 6010, 25 mil, 1/2oz Cu.) The foil pattern of the input match was manufactured first and used in the test fixture to obtain the device output impedances. These impedances are shown in Table 8 for comparative purposes. The input match foil pattern generated by MultiMatch is shown in Figure 38.

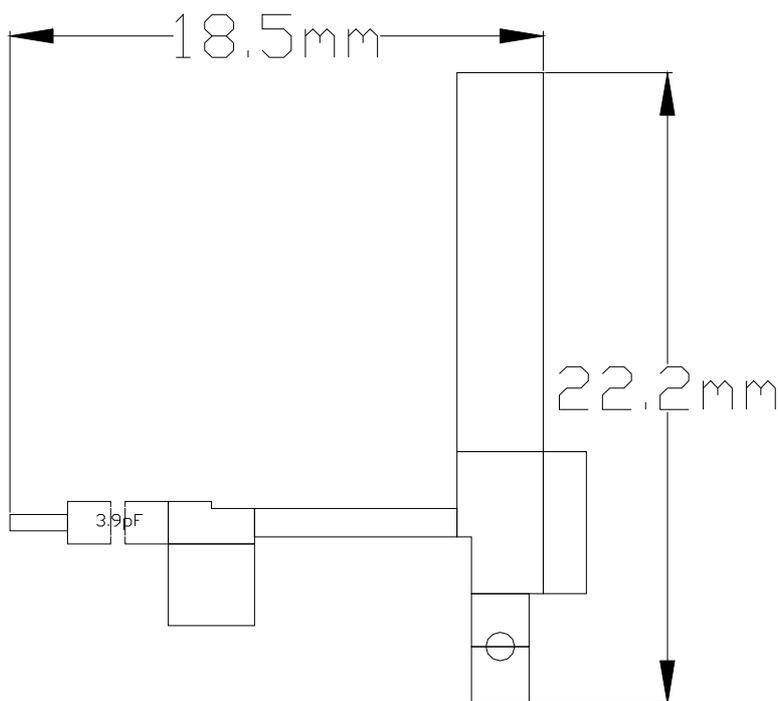


Figure 38. Input match foil pattern generated by MultiMatch from the load pull data measured for the RZ1214B35Y.

The 3.9pF series capacitor shown in Figure 38 is part of the five-element match and a 1% component has been chosen to be on the safe side. The topology of this input match comes as close to the ideal situation as one can wish for. The only observed problem with this match was that it was a bit more sensitive to small dimensional changes than would be tolerable for a mass produced amplifier. It was however easy to optimize it in less than 15 minutes.

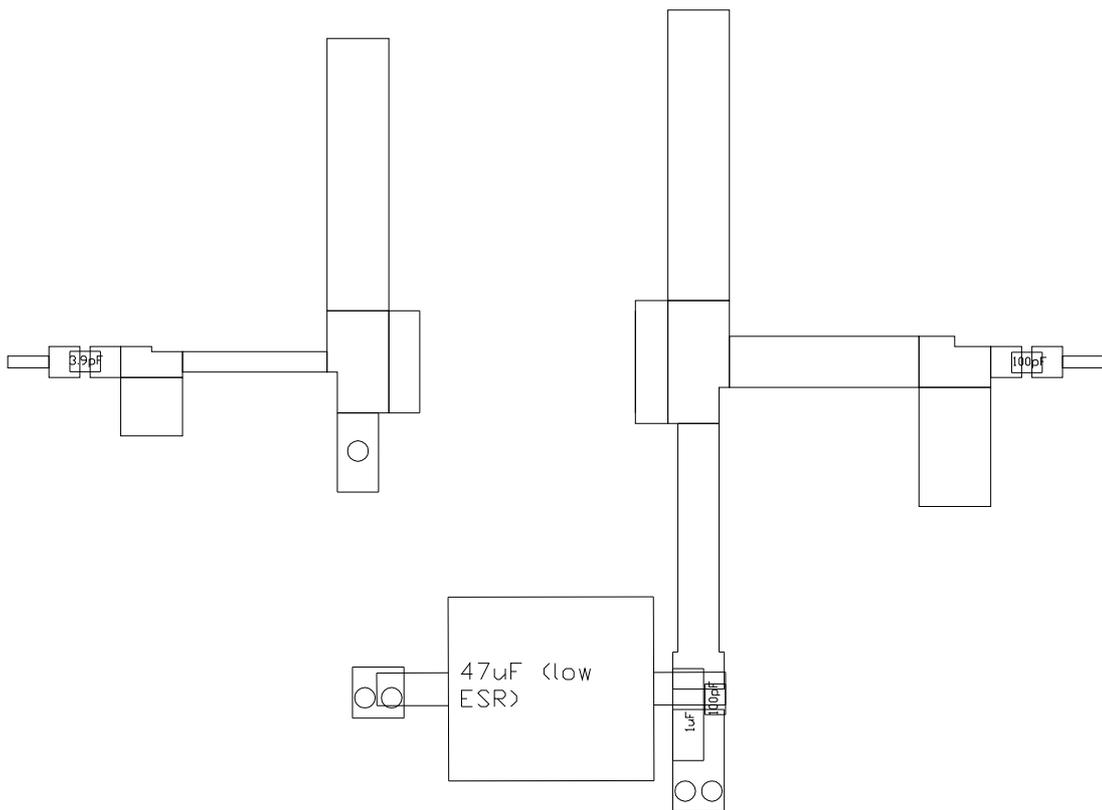


Figure 39. Complete foil pattern for the MultiMatch generated RZ1214B35Y amplifier.

It proved difficult to find a good topology for the output match of this amplifier and a compromise had to be accepted. It was fairly easy to find good matches, but these matches either needed a relatively big RF choke or quarter wave line to bias the transistor or a short line to RF ground had to be put relatively far from the collector tab of the transistor. Eventually the compromise shown in Figure 39 was chosen. This proved to be a good choice as the amplifier produced with it had a clean spectrum with good harmonic suppression. It also produced a good and clean output pulse, the leading edge of which is

shown in Figure 40, and it was insensitive to small dimensional changes. No spurious was observed and the harmonics were all below  $-58\text{dBc}$  with the second harmonic the strongest ( $-58\text{dBc}$ ) at  $1.35\text{GHz}$ . (In the light of this better efficiencies were expected from this amplifier. The relatively low efficiencies suggest that the drive level should be increased in order for the transistor to better approximate a switch over the RF cycle [3,29].)

Table 8. RZ1214B35Y (MM foil measured data)								
Supply voltage (50V)								
Pulse width (300us)								
Duty cycle (1%)								
Frequency (GHz)	Power in (dBm)	Power out (dBm)	Gain (dB)	Efficiency (%)	Conjugate foil input impedance		Conjugate foil output impedance	
					Re	Im	Re	Im
1.2	39	46.1	7.1	38	9.8	1.4	2.9	1.1
1.25	39	46.9	7.9	41	8.3	1.5	3.1	0.9
1.3	39	46.1	7.1	39	7.3	1.4	3.2	0.9
1.35	39	46.8	7.8	40	6.5	1.5	3	1.1
1.4	39	46.2	7.2	39	5.7	1.9	2.1	1.3

The foil patterns were broken up and the various pieces were analyzed in an electromagnetic simulator (Microwave Office). The S-parameter files of these simulations were pulled into a linear simulator (Microwave Office) and the complete matches were analyzed for comparative purposes. The results are presented as part of Table 8.

By comparing the performance figures of the two amplifiers (Table 7 and Table 8) it is clear that the MultiMatch designed amplifier has superior performance with respect to gain flatness and efficiency. The MultiMatch designed amplifier is also superior regarding the shape of the output pulse with a disturbance free rise time of  $150\text{ns}$  as shown in Figure 40.

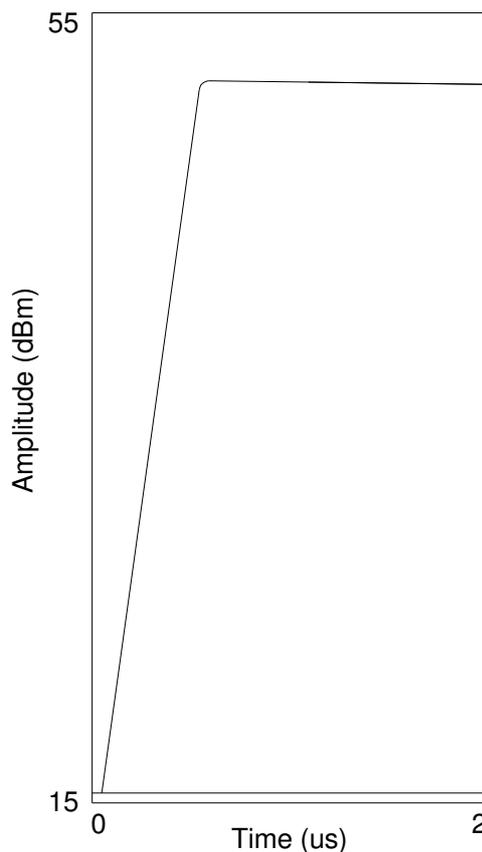


Figure 40. Leading edge response of MultiMatch generated RZ1214B35Y amplifier at 1.3GHz.

#### MTI Performance Evaluation.

The spurious response and pulse shape of this amplifier suggests that it also has very good pulse-to pulse stability and therefore should deliver good MTI performance as well.

#### 4.4.3.2.1 Impedance and Output Power Evaluation. (RZ1214B35Y)

A graphical comparison of the measured load-pull impedances as well as the impedances of the various foil patterns is shown in Figure 41. From the graphical comparison, it is evident that the three impedances do not even follow the same trends, yet they produce similar results. The output impedance of the MultiMatch generated foil pattern is however close to the measured load-pull data in the center of the frequency band. This might explain the good performance results of the amplifier. A graphical comparison of the output power of the amplifiers is presented in Figure 42. From this comparison it can be

seen that the MultiMatch designed amplifier has flatter gain response than the reference amplifier and delivers about 2 dB more power. The MultiMatch designed amplifier also stays within 0.5dB of the power gain of the load pull figures. The data book amplifier constantly produces more than 1dB less power than the load-pull figures.

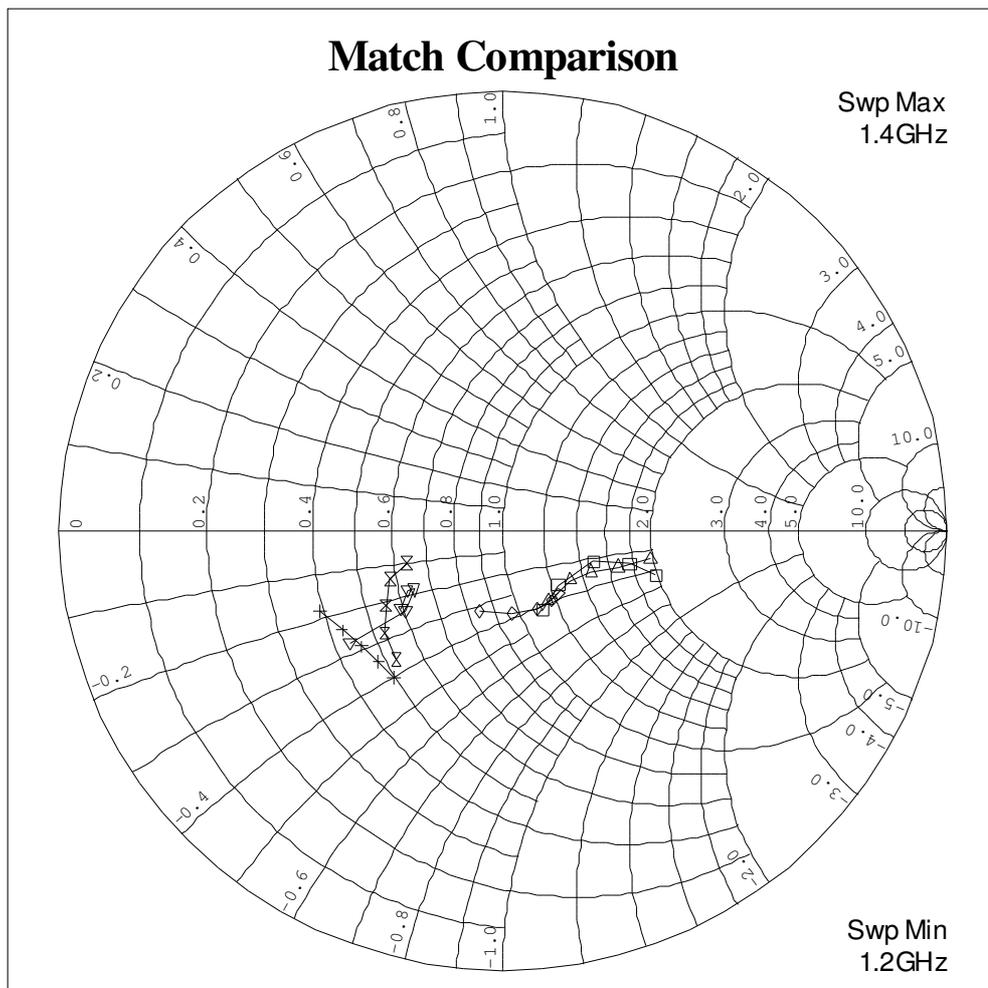


Figure 41. A graphical comparison between the load pull, data sheet foil pattern and the MultiMatch generated foil pattern impedances for the RZ1214b35Y. (5Ω Smith Chart.)

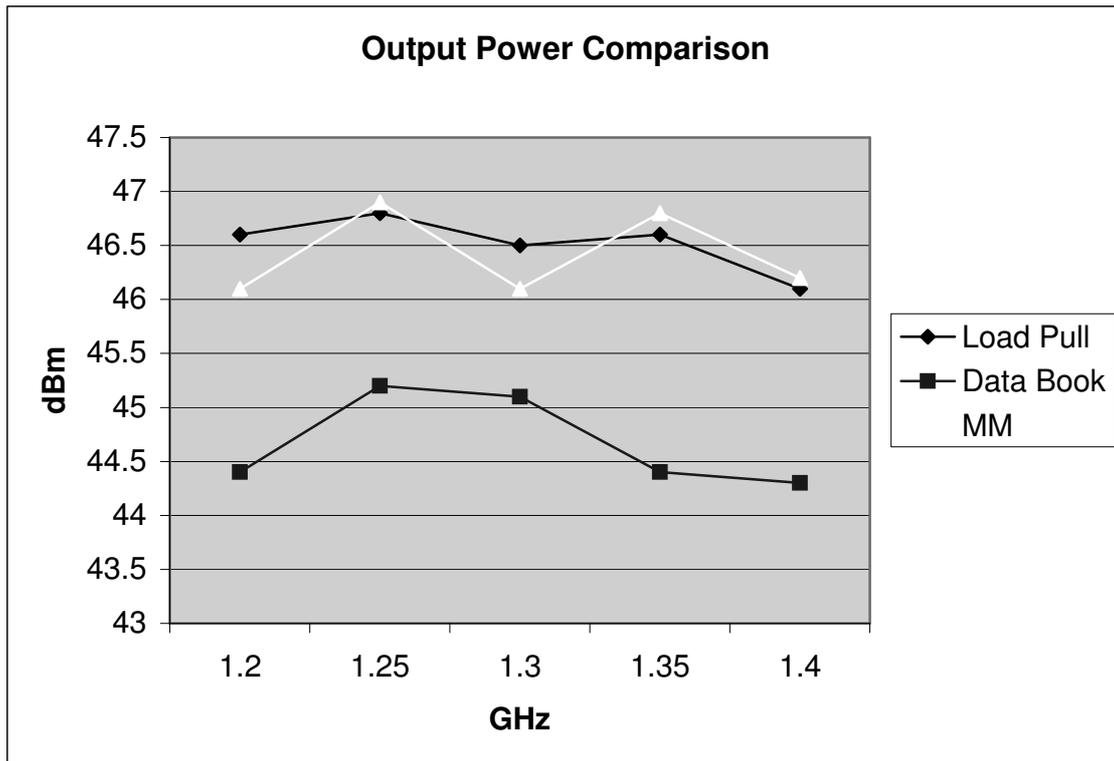


Figure 42. Output Power Comparison (RZ1214B35Y).

From the above comparisons it is evident that the amplifier designed with the aid of MultiMatch has significantly better performance than the data sheet reference amplifier, especially with regard to gain flatness, output power, pulse shape and ease of optimization. The graphical comparison of the impedance data (Figure 41) also demonstrates that the published data in the data sheet does nothing more than provide a general domain on the Smith chart around which the impedance matches have to be designed. Likely, the biggest performance difference between the two amplifiers lies in their harmonic response. The reference amplifier has atrocious harmonic response compared to the MultiMatch designed amplifier which has excellent harmonic content characteristics.

The physical MultiMatch generated matches are shown in Figure 43. By comparing Figure 36 and Figure 43, it can be verified that the matching topologies of the two amplifiers are quite different although the physical sizes are similar.

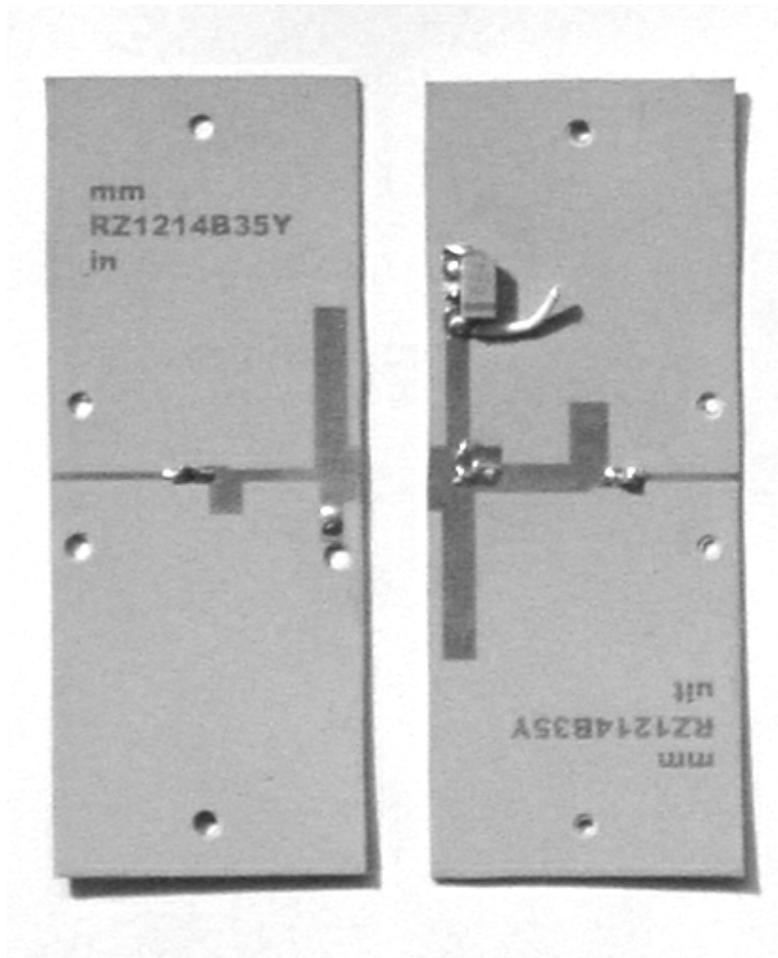


Figure 43. Optimized foil patterns for the MultiMatch generated RZ1214B35Y amplifier.



## 4.5 Conclusions

In this chapter the performance of the TRL test fixture and stub tuner that was designed for the proposed characterization process was evaluated. The performance of the test fixture and stub tuner was shown to exceed the requirements.

It was also shown in this chapter that the performance of the amplifiers designed with the proposed device characterization method and MultiMatch, exceeded the performance of the amplifiers proposed in the data sheets which were used as references (benchmarks). Using the proposed characterization method, it was also demonstrated in this chapter that a device could be used at a different supply rail voltage than that stipulated by the device manufacturer.

## 5 Conclusions

It was the goal of this thesis to establish an affordable design process for solid state high power pulsed RF and microwave amplifiers, suited to mainly radar applications. The main thrust of the investigation was to find a way to reliably characterize a spectrum of pulsed bi-polar devices over several sets of operating conditions at modest cost in order to choose the most cost effective line-up for the required amplifier and its associated power supply. The aim was to get round the low frequency instabilities, transition instabilities and pulse length versus peak power tradeoffs with its associated thermal requirements.

Although we were able to meet the majority of these goals, there is still a need to investigate some in a bit more detail. The main area where some more investigation is needed is in the area of characterizing the devices outside the designated frequency band specified by the manufacturer. Once this is done, one should be in a position to get to an optimum design for the required amplifier quickly and cheaply.

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## 7 Appendix A

### 7.1 MATLAB m files.

#### 7.1.1 TRL

```
function [Sx,GL]=trl(Sthru,Sopen,Sline,Sdut,freq);
```

```
% TRL performs a two-tier TRL calibration for a vector network analyser.
```

```
% The first calibration consist of a normal co-axial SOLT two-port calibration
```

```
% followed by measurements on the TRL calibration standards and the DUT. The
```

```
% function then performs the second tier of the calibration by de-embedding the
```

```
% effect of the TRL test fixture from the DUT measurements using the measurements
```

```
% performed on the TRL calibration standards.
```

```
%
```

```
% The function uses the following input parameters:
```

```
%
```

```
% Sthru Four column matrix containing S-Parameters of the thru measurement on
```

```

%      TRL test fixture.

% Sopen  Four colom matrix containing S-Parameters of the open measurement on

%      TRL test fixture. Only S11 and S22 is of interest here and the S21 and

%      S12 data which will be in the noise floor of the VNA will be discarded.

% Sline  Four colom matrix containing S-Parameters of the line measurement on

%      TRL test fixture.

% Sdut   Four colom matrix containing S-Parameters of the DUT inserted into the

%      TRL test fixture.

% f      Frequencies at which S-Parameters were measured in Hz.

%

% The coloms of the S-Parameter matrix represent [S11 S21 S12 S22].

%

% format: [Sx,GL]=trl(Sthru,Sopen,Sline,Sdut,freq)

%

% The output consists of the de-embedded device S-Parameters (Sx), and the propagation

% constant (GL) of the line standard used in the TRL calibration. The propagation

constant

% can be used to calculate the characteristic impedance of the microstrip calibration

```

% line. Since microstrip is a dispersive transmission line, the characteristic impedance  
% will vary as a function of frequency. The measured S-Parameters will be normalised  
with  
% respect to the actual characteristic impedance of the transmission line calibration  
% standard. By extracting this impedance, the S-Parameter data can be renormalised to  
% 50 Ohm.

%

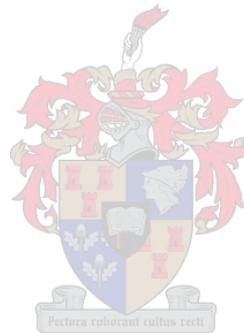
% See TRLPOST.M for some post processing functions that can be performed.

%

% Writer : C. van Niekerk

% Version : 3.50

% Date : 07/ 06/ 1995



% This program is based on the work in the presented in the following paper:

%

% [1] G.F. Engen, C.A. Hoer, "Thru-Reflect-Line: An Improved Technique for

% Calibrating the Dual Six-Port Automatic Network Analyser,"

% IEEE Trans. MTT, Vol. 27, No. 12, December 1979, pp. 987-998

```
% Define the imaginary constant
```

```
i=sqrt(-1);
```

```
% Convert the measured s-parameters of the DEVICE to one variable
```

```
S11d = Sdut(:,1);
```

```
S21d = Sdut(:,2);
```

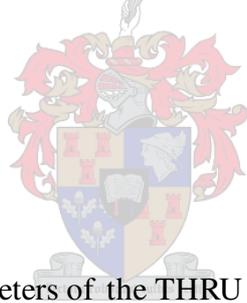
```
S12d = Sdut(:,3);
```

```
S22d = Sdut(:,4);
```

```
% Convert the measured s-parameters of the REFLECT stander to one variable
```

```
S11r = Sopen(:,1);
```

```
S22r = Sopen(:,4);
```



```
% Convert the measured s-parameters of the THRU stander to one variable
```

```
S11t = Sthru(:,1);
```

```
S21t = Sthru(:,2);
```

```
S12t = Sthru(:,3);
```

```
S22t = Sthru(:,4);
```

```
% Convert the measured s-parameters of the LINE stander to one variable
```

```
S11l = Sline(:,1);
```

```
S21l = Sline(:,2);
```

```
S12l = Sline(:,3);
```

```
S22l = Sline(:,4);
```

```
% Compute the wave cascading matrix for the thru standard
```

```
R11t = -(S11t.*S22t - S12t.*S21t)/ S21t;
```

```
R12t = S11t./ S21t;
```

```
R21t = -S22t./ S21t;
```

```
R22t = 1 ./ S21t;
```

```
% Compute the wave cascading matrix for the line standard
```

```
R11l = -(S11l.*S22l - S12l.*S21l)/ S21l;
```

```
R12l = S11l./ S21l;
```

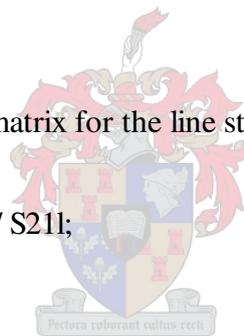
```
R21l = -S22l./ S21l;
```

```
R22l = 1 ./ S21l;
```

```
% Compute the wave cascading matrix for the device standard
```

```
R11m = -(S11d.*S22d - S12d.*S21d)/ S21d;
```

```
R12m = S11d./ S21d;
```



$$R_{21m} = -S_{22d} / S_{21d};$$

$$R_{22m} = 1 / S_{21d};$$

% Calculate the two possible virtual error networks for port A

% and port B using the s-parameters of the thru and line standards

% Determine the number of frequency points

$$n_{\text{freq}} = \text{length}(\text{freq});$$

for n = 1:nfreq

$$R_t = [ R_{11t}(n) \ R_{12t}(n) ; R_{21t}(n) \ R_{22t}(n) ];$$

$$R_l = [ R_{11l}(n) \ R_{12l}(n) ; R_{21l}(n) \ R_{22l}(n) ];$$

$$T = R_l \cdot \text{inv}(R_t);$$

% Solve a set of quadratic equations to get the values of  $r_{11a} / r_{21a}$

% and  $r_{12a} / r_{22a}$

$$A = T(2,1);$$

$$B = T(2,2) - T(1,1);$$

$$C = -T(1,2);$$

$$K_1 = (-B + \sqrt{(B^2) - 4 \cdot A \cdot C}) / (2 \cdot A);$$

$$K_2 = (-B - \sqrt{(B^2) - 4 \cdot A \cdot C}) / (2 \cdot A);$$

% Choose between the two possible roots to get the right values for

% b and c/ a

if abs(K1)<abs(K2)

b = K1;

ca = 1/ K2;

end;

if abs(K2)<abs(K1)

b = K2;

ca = 1/ K1;

end;

% Calculates the propagation constant of the LINE standard.

GL(n) = -log(T(1,1)+T(1,2)\*ca);

% Calculates "a"

w1 = S11r(n);

w2 = S22r(n);

g = 1/ S21t(n);

d = -(S11t(n)\*S22t(n) - S12t(n)\*S21t(n));



```
e = S11t(n);
```

```
f = -S22t(n);
```

```
gamma = (f-d*ca)/(1-e*ca);
```

```
beta_alfa = (e-b)/(d-b*f);
```

```
a = sqrt(((w1-b)*(1+w2*beta_alfa)*(d-b*f))/((w2+gamma)*(1-w1*ca)*(1-e*ca)));
```

```
% Calculates the reflection coefficients at each port to determine the correct
```

```
% sign that should be assigned to a
```

```
R1a = (w1-b)/(a-w1*a*ca);
```

```
R1b = (w1-b)/(w1*a*ca-a);
```

```
% An open is used for the reflection measurement. Use this information to
```

```
% chose the sign of a
```

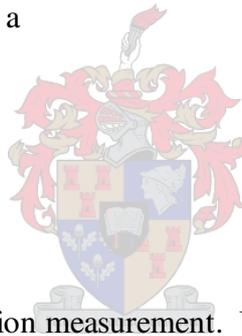
```
if abs(angle(R1a)*180/pi)<90
```

```
    a = a;
```

```
    as(n) = a;
```

```
    c = ca*a;
```

```
end;
```



```
if abs(angle(R1b)*180/ pi)<90
```

```
    a = -a;
```

```
    as(n) = a;
```

```
    c = ca*a;
```

```
end;
```

```
R1(n) = (w1-b)/(a-c*w1);
```

```
alfa = (d-b*f)/(a*(1-e*ca));
```

```
beta = beta_alfa*alfa;
```

```
r22p22 = R11t(n)/(a*alfa + b*gamma);
```

```
IRa = [ 1 -b ; -c a ];
```

```
IRb = [ 1 -beta ; -gamma alfa ];
```



```
Rm = [ R11m(n) R12m(n) ; R21m(n) R22m(n) ];
```

```
Rx = 1/ (r22p22*(alfa-gamma*beta)*(a-b*c))*IRa*Rm*IRb;
```

```
S11x(n) = Rx(1,2)/ Rx(2,2);
```

```
S12x(n) = Rx(1,1) - Rx(1,2)*Rx(2,1)/ Rx(2,2);
```

```
S21x(n) = 1/ Rx(2,2);
```

```
S22x(n) = -Rx(2,1)/ Rx(2,2);
```

end;

Sx=[S11x.' S21x.' S12x.' S22x.'];

### 7.1.2 TRL2

function [Sx,GL]=trl2(Sthru,Sopen,SlimeM,Sdut,freq,fr);

% TRL2 performs a multi-line two-tier TRL calibration for a vector network

% analyser. The calibration differs from the TRL function in that

% provision is made for the use of multiple line standards in order to

% increase the calibration bandwidth and/ or increase accuracy. There is

% no limit on the number of line standards that can be used.

%

% The first calibration consist of a normal co-axial SOLT two-port calibration

% followed by measurements on the TRL calibration standards and the DUT. The

% function then performs the second tier of the calibration by de-embedding the

% effect of the TRL test fixture from the DUT measurements using the measurements

% performed on the TRL calibration standards.

```

%
% The function uses the following input parameters:
%
% Sthru  Four colom matrix containing S-Parameters of the thru measurement on
%        TRL test fixture.
%
% Sopen  Four colom matrix containing S-Parameters of the open measurement on
%        TRL test fixture. Only S11 and S22 is of interest here and the S21 and
%        S12 data which will be in the noise floor of the VNA will be discarded.
%
% SlineM A cell array consisting of four colom matrixes containing S-Parameters
%        of the different line measurements on the TRL test fixture.
%        The cell matrix is build up by specifying:
%
%        SlineM{ 1 }=Sline1, SlineM{ 2 }=Sline2,...,SlineM{ k }=Slinek
%
% Sdut   Four colom matrix containing S-Parameters of the DUT inserted into the
%        TRL test fixture.
%
% f      Frequencies at which S-Parameters were measured in Hz.

```

```

% fr    Vector containing the frequencies in Hz where one line
%
%
%
% The coloms of the S-Parameter matrix represent [S11 S21 S12 S22].
%
%
% format: [Sx,GL]=trl2(Sthru,Sopen,SlineM,Sdut,freq,fr)
%
%
% The output consists of the de-embedded device S-Parameters (Sx), and the propagation
% constant (GL) of the line standard used in the TRL calibration. The propagation
constant
% can be used to calculate the characteristic impedance of the microstrip calibration
% line. Since microstrip is a dispersive transmission line, the characteristic impedance
% will vary as a function of frequency. The measured S-Parameters will be normalised
with
% respect to the actual characteristic impedance of the transmission line calibration
% standard. By extracting this impedance, the S-Parameter data can be renormalised to
% 50 Ohm.
%

```



% See TRLPOST.M for some post processing functions that can be performed.

%

% Writer : C. van Niekerk

% Version : 3.50

% Date : 07/ 06/ 1995

% This program is based on the work in the presented in the following paper:

%

% [1] G.F. Engen, C.A. Hoer, "Thru-Reflect-Line: An Improved Technique for

% Calibrating the Dual Six-Port Automatic Network Analyser,"

% IEEE Trans. MTT, Vol. 27, No. 12, December 1979, pp. 987-998

% Define the imaginary constant



i=sqrt(-1);

% Convert the measured s-parameters of the DEVICE to one variable

S11d = Sdut(:,1);

S21d = Sdut(:,2);

S12d = Sdut(:,3);

S22d = Sdut(:,4);

% Convert the measured s-parameters of the REFLECT standard to one variable

S11r = Sopen(:,1);

S22r = Sopen(:,4);

% Convert the measured s-parameters of the THRU standard to one variable

S11t = Sthru(:,1);

S21t = Sthru(:,2);

S12t = Sthru(:,3);

S22t = Sthru(:,4);

% Convert the measured s-parameters of the LINE standard to one variable

%



% The different line standards used in the calibration is combined here by

% using the frequency range for which they are assigned.

fr=[min(freq) fr max(freq)];

for n=2:length(fr)

    k=find( freq(find(freq <= fr(n))) >= fr(n-1));

    S11l(k) = SlineM{n-1}(k,1);

```

S21l(k) = SlineM{n-1}(k,2);

S12l(k) = SlineM{n-1}(k,3);

S22l(k) = SlineM{n-1}(k,4);

end;

% Compute the wave cascading matrix for the thru standard

R11t = -(S11t.*S22t - S12t.*S21t)/ S21t;

R12t = S11t./ S21t;

R21t = -S22t./ S21t;

R22t = 1 ./ S21t;

% Compute the wave cascading matrix for the line standard

R11l = -(S11l.*S22l - S12l.*S21l)/ S21l;

R12l = S11l./ S21l;

R21l = -S22l./ S21l;

R22l = 1 ./ S21l;

% Compute the wave cascading matrix for the device standard

R11m = -(S11d.*S22d - S12d.*S21d)/ S21d;

R12m = S11d./ S21d;

```



$$R_{21m} = -S_{22d} / S_{21d};$$

$$R_{22m} = 1 / S_{21d};$$

% Calculate the two possible virtual error networks for port A

% and port B using the s-parameters of the thru and line standards

% Determine the number of frequency points

$$n_{\text{freq}} = \text{length}(\text{freq});$$

for n = 1:nfreq

$$R_t = [ R_{11t}(n) \ R_{12t}(n) ; R_{21t}(n) \ R_{22t}(n) ];$$

$$R_l = [ R_{11l}(n) \ R_{12l}(n) ; R_{21l}(n) \ R_{22l}(n) ];$$

$$T = R_l \cdot \text{inv}(R_t);$$

% Solve a set of quadratic equations to get the values of  $r_{11a} / r_{21a}$

% and  $r_{12a} / r_{22a}$

$$A = T(2,1);$$

$$B = T(2,2) - T(1,1);$$

$$C = -T(1,2);$$

$$K_1 = (-B + \sqrt{(B^2) - 4 \cdot A \cdot C}) / (2 \cdot A);$$

$$K_2 = (-B - \sqrt{(B^2) - 4 \cdot A \cdot C}) / (2 \cdot A);$$

% Choose between the two possible roots to get the right values for

% b and c/ a

if abs(K1)<abs(K2)

b = K1;

ca = 1/ K2;

end;

if abs(K2)<abs(K1)

b = K2;

ca = 1/ K1;

end;

% Calculates the propagation constant of the LINE standard.

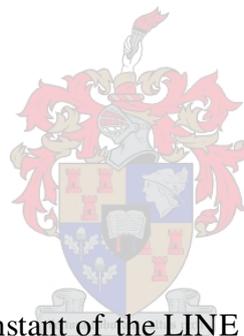
$GL(n) = -\log(T(1,1) + T(1,2) * ca);$

% Calculates "a"

w1 = S11r(n);

w2 = S22r(n);

g = 1/ S21t(n);



$$d = -(S11t(n)*S22t(n) - S12t(n)*S21t(n));$$

$$e = S11t(n);$$

$$f = -S22t(n);$$

$$\text{gamma} = (f-d*ca)/(1-e*ca);$$

$$\text{beta\_alfa} = (e-b)/(d-b*f);$$

$$a = \text{sqrt}(((w1-b)*(1+w2*\text{beta\_alfa})*(d-b*f))/((w2+\text{gamma})*(1-w1*ca)*(1-e*ca)));$$

% Calculates the reflection coefficients at each port to determine the correct

% sign that should be assigned to a

$$R1a = (w1-b)/(a-w1*a*ca);$$

$$R1b = (w1-b)/(w1*a*ca-a);$$

% An open is used for the reflection measurement. Use this information to

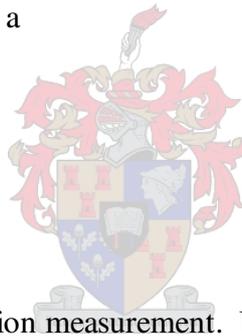
% chose the sign of a

if abs(angle(R1a)\*180/pi)<90

$$a = a;$$

$$\text{as}(n) = a;$$

$$c = ca*a;$$



```

end;

if abs(angle(R1b)*180/ pi)<90

    a = -a;

    as(n) = a;

    c = ca*a;

end;

R1(n) = (w1-b)/( a-c*w1);

alfa = (d-b*f)/( a*(1-e*ca));

beta = beta_alfa*alfa;

r22p22 = R11t(n)/( a*alfa + b*gamma);

IRa = [ 1 -b ; -c a ];

IRb = [ 1 -beta ; -gamma alfa ];

Rm = [ R11m(n) R12m(n) ; R21m(n) R22m(n) ];

Rx = 1/ (r22p22*(alfa-gamma*beta)*(a-b*c))*IRa*Rm*IRb;

S11x(n) = Rx(1,2)/ Rx(2,2);

S12x(n) = Rx(1,1) - Rx(1,2)*Rx(2,1)/ Rx(2,2);

```



```
S21x(n) = 1/ Rx(2,2);
```

```
S22x(n) = -Rx(2,1)/ Rx(2,2);
```

```
end;
```

```
Sx=[S11x.' S21x.' S12x.' S22x.'];
```

### 7.1.3 TRLstone

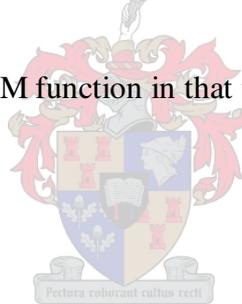
```
function [Sx,freq,GL]=trlstone(ThruFile,OpenFile,LineFile,DeviceFile);
```

```
% TRLSTONE performs a two-tier TRL calibration for a vector network analyser. The
```

```
% function differs from the TRL.M function in that the measured data is read from
```

```
% Touchstone format text files.
```

```
%
```



```
% The first calibration consist of a normal co-axial SOLT two-port calibration
```

```
% followed by measurements on the TRL calibration standards and the DUT. The
```

```
% function then performs the second tier of the calibration by de-embedding the
```

```
% effect of the TRL test fixture from the DUT measurements using the measurements
```

```
% performed on the TRL calibration standards.
```

```
%
```

```

% The function uses the following input parameters:

%

% ThruFile    S-Parameters of the thru measurement on TRL test fixture.

% OpenFile    S-Parameters of the open measurement on TRL test fixture. Only S11

%             and S22 is of interest here and the S21 and S12 data which will be

%             in the noise floor of the VNA will be discarded.

% LineFile    S-Parameters of the line measurement on TRL test fixture.

% DeviceFile  S-Parameters of the Device under test

% f           Frequencies at which S-Parameters were measured in Hz.

%

% format: [Sx,freq,GL]=trlstone(ThruFile,OpenFile,LineFile,DeviceFile);

%

% The output consists of the de-embedded device S-Parameters (Sx), the measurement

% frequencies (freq) in Hz and the propagation constant (GL) of the line standard used in

% the TRL calibration. The propagation constant can be used to calculate the

% characteristic

% impedance of the microstrip calibration line. Since microstrip is a dispersive

% transmission line, the characteristic impedance will vary as a function of frequency.

```

% The measured S-Parameters will be normalised with respect to the actual characteristic  
% impedance of the transmission line calibration standard. By extracting this impedance,  
% the S-Parameter data can be renormalised to 50 Ohm.

%

% See TRLPOST.M for some post processing functions that can be performed.

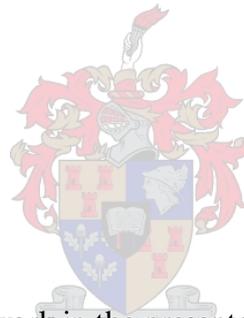
%

% Writer : C. van Niekerk

% Version : 3.50

% Date : 07/06/1995

%



% This program is based on the work in the presented in the following paper:

%

% [1] G.F. Engen, C.A. Hoer, "Thru-Reflect-Line: An Improved Technique for

% Calibrating the Dual Six-Port Automatic Network Analyser,"

% IEEE Trans. MTT, Vol. 27, No. 12, December 1979, pp. 987-998

i=sqrt(-1); % Define the imaginary constant

% Load the s-parameters of the TRL calibration set. All complex data is stored

% in terms of their real and imaginary parts

```
[open,freq]=ldstone(OpenFile,1); % Refelection measurement using open circiuted  
launchers
```

```
[thru,freq]=ldstone(ThruFile,1); % Zero lenght through measurement
```

```
[line,freq]=ldstone(LineFile,1); % 1/ 4 wavelength transmission line
```

% Get the device s-parameter data. The data is in the same format as that

% of the TRL calibration set.

```
[device,freq]=ldstone(DeviceFile,1);
```

% Convert the measured s-parameters of the DEVICE to one variable

```
S11d = device(:,1);
```

```
S21d = device(:,2);
```

```
S12d = device(:,3);
```

```
S22d = device(:,4);
```

% Convert the measured s-parameters of the REFLECT standerd to one variable

```
S11r = open(:,1);
```

```
S22r = open(:,4);
```

% Convert the measured s-parameters of the THRU standerd to one variable

```
S11t = thru(:,1);
```

```
S21t = thru(:,2);
```

```
S12t = thru(:,3);
```

```
S22t = thru(:,4);
```

```
% Convert the measured s-parameters of the LINE standard to one variable
```

```
S11l = line(:,1);
```

```
S21l = line(:,2);
```

```
S12l = line(:,3);
```

```
S22l = line(:,4);
```

```
% Compute the wave cascading matrix for the thru standard
```

```
R11t = -(S11t.*S22t - S12t.*S21t)/ S21t;
```

```
R12t = S11t/ S21t;
```

```
R21t = -S22t/ S21t;
```

```
R22t = 1 ./ S21t;
```

```
% Compute the wave cascading matrix for the line standard
```

```
R11l = -(S11l.*S22l - S12l.*S21l)/ S21l;
```

```
R12l = S11l/ S21l;
```



$$R_{21l} = -S_{22l} / S_{21l};$$

$$R_{22l} = 1 / S_{21l};$$

% Compute the wave cascading matrix for the device standard

$$R_{11m} = -(S_{11d} * S_{22d} - S_{12d} * S_{21d}) / S_{21d};$$

$$R_{12m} = S_{11d} / S_{21d};$$

$$R_{21m} = -S_{22d} / S_{21d};$$

$$R_{22m} = 1 / S_{21d};$$

% Calculate the two possible virtual error networks for port A

% and port B using the s-parameters of the thru and line standards

% Determine the number of frequency points

$$n_{\text{freq}} = \text{length}(\text{freq});$$

for n = 1:nfreq

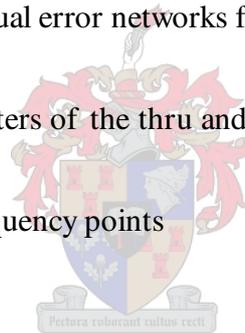
$$R_t = [ R_{11t}(n) \ R_{12t}(n) ; R_{21t}(n) \ R_{22t}(n) ];$$

$$R_l = [ R_{11l}(n) \ R_{12l}(n) ; R_{21l}(n) \ R_{22l}(n) ];$$

$$T = R_l * \text{inv}(R_t);$$

% Solve a set of quadratic equations to get the values of  $r_{11a} / r_{21a}$

% and  $r_{12a} / r_{22a}$



$$A = T(2,1);$$

$$B = T(2,2) - T(1,1);$$

$$C = -T(1,2);$$

$$K1 = (-B + \sqrt{(B^2) - 4*A*C}) / (2*A);$$

$$K2 = (-B - \sqrt{(B^2) - 4*A*C}) / (2*A);$$

% Choose between the two possible roots to get the right values for

% b and c/a

if abs(K1)<abs(K2)

$$b = K1;$$

$$ca = 1 / K2;$$

end;

if abs(K2)<abs(K1)

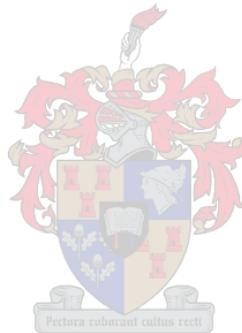
$$b = K2;$$

$$ca = 1 / K1;$$

end;

% Calculates the propagation constant of the LINE standard.

$$GL(n) = -\log(T(1,1) + T(1,2)*ca);$$



% Calculates "a"

w1 = S11r(n);

w2 = S22r(n);

g = 1/ S21t(n);

d = -(S11t(n)\*S22t(n) - S12t(n)\*S21t(n));

e = S11t(n);

f = -S22t(n);

gamma = (f-d\*ca)/(1-e\*ca);

beta\_alfa = (e-b)/(d-b\*f);

a = sqrt(((w1-b)\*(1+w2\*beta\_alfa)\*(d-b\*f))/((w2+gamma)\*(1-w1\*ca)\*(1-e\*ca)));

% Calculates the reflection coefficients at each port to determine the correct

% sign that should be assigned to a

R1a = (w1-b)/(a-w1\*a\*ca);

R1b = (w1-b)/(w1\*a\*ca-a);

% An open is used for the reflection measurement. Use this information to

% chose the sign of a

```
if abs(angle(R1a)*180/ pi)<90
```

```
  a = a;
```

```
  as(n) = a;
```

```
  c = ca*a;
```

```
end;
```

```
if abs(angle(R1b)*180/ pi)<90
```

```
  a = -a;
```

```
  as(n) = a;
```

```
  c = ca*a;
```

```
end;
```

```
R1(n) = (w1-b)/ (a-c*w1);
```

```
alfa = (d-b*f)/ (a*(1-e*ca));
```

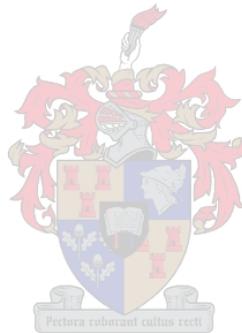
```
beta = beta_alfa*alfa;
```

```
r22p22 = R11t(n)/ (a*alfa + b*gamma);
```

```
IRa = [ 1 -b ; -c a ];
```

```
IRb = [ 1 -beta ; -gamma alfa ];
```

```
Rm = [ R11m(n) R12m(n) ; R21m(n) R22m(n) ];
```



$$R_x = 1 / (r^{22} p^{22} (\alpha - \gamma \beta)^{(a-b \cdot c)}) \cdot I R_a \cdot R_m \cdot I R_b;$$

$$S_{11x}(n) = R_x(1,2) / R_x(2,2);$$

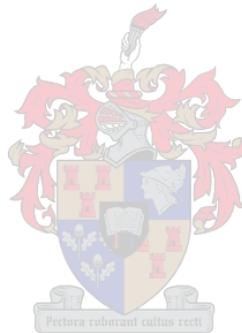
$$S_{12x}(n) = R_x(1,1) - R_x(1,2) \cdot R_x(2,1) / R_x(2,2);$$

$$S_{21x}(n) = 1 / R_x(2,2);$$

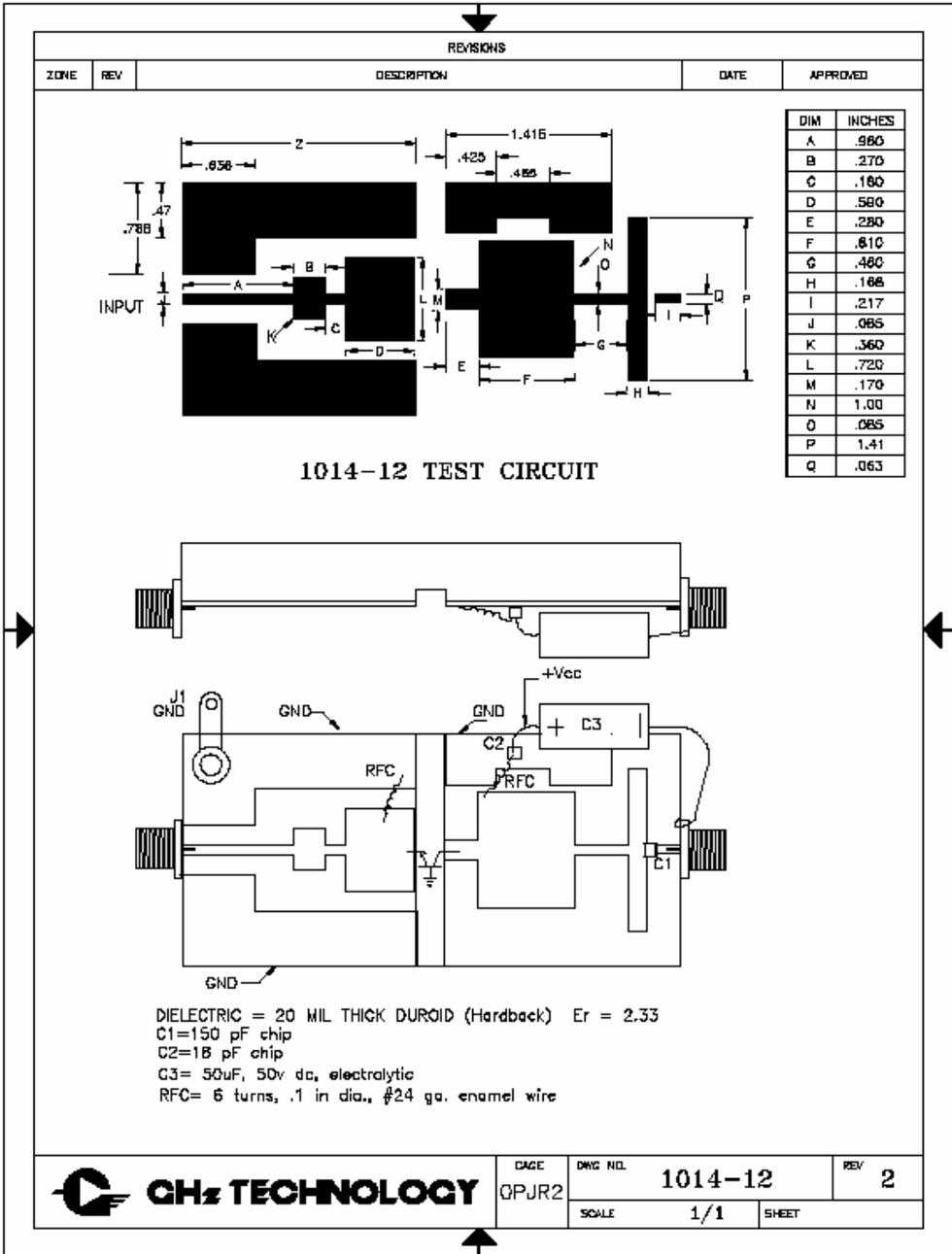
$$S_{22x}(n) = -R_x(2,1) / R_x(2,2);$$

end;

$$S_x = [S_{11x} \cdot S_{21x} \cdot S_{12x} \cdot S_{22x}];$$







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8.2 Philips RZ1214B35Y Data Sheet

**DISCRETE SEMICONDUCTORS**

**DATA SHEET**

**RZ1214B35Y**  
NPN microwave power transistor

Product specification  
Supersedes data of June 1992

1997 Feb 18

**Philips**  
Semiconductors



**PHILIPS**

## NPN microwave power transistor

RZ1214B35Y

## FEATURES

- Interdigitated structure provides high emitter efficiency
- Diffused emitter ballasting resistor providing excellent current sharing and withstanding a high VSWR
- Gold metallization realizes very stable characteristics and excellent lifetime
- Multicell geometry gives good balance of dissipated power and low thermal resistance
- Internal input matching ensures good stability and allows an easier design of wideband circuits.

## APPLICATIONS

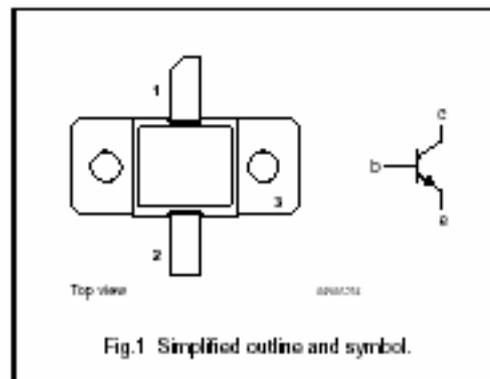
- Common base class-C wideband pulsed power amplifiers for L-band radar applications in the 1.2 to 1.4 GHz band.

## DESCRIPTION

NPN silicon planar epitaxial microwave power transistor in a SOT443A metal ceramic flange package with the base connected to the flange.

## PINNING - SOT443A

PIN	DESCRIPTION
1	collector
2	emitter
3	base connected to flange



## QUICK REFERENCE DATA

Microwave performance up to  $T_{\text{amb}} = 25\text{ }^{\circ}\text{C}$  in a common base class-C wideband amplifier.

MODE OF OPERATION	f (GHz)	V <sub>CC</sub> (V)	P <sub>L</sub> (W)	G <sub>p</sub> (dB)	$\eta_c$ (%)	Z <sub>i</sub> ; Z <sub>L</sub> ( $\Omega$ )
Class-C; $t_p = 150\text{ }\mu\text{s}$ ; $\delta = 5\%$	1.2 to 1.4	60	$\geq 35$	$\geq 7$	$\geq 30$	see Fig 4

## WARNING

Product and environmental safety - toxic materials

This product contains beryllium oxide. The product is entirely safe provided that the BeO slab is not damaged. All persons who handle, use or dispose of this product should be aware of its nature and of the necessary safety precautions. After use, dispose of as chemical or special waste according to the regulations applying at the location of the user. It must never be thrown out with the general or domestic waste.

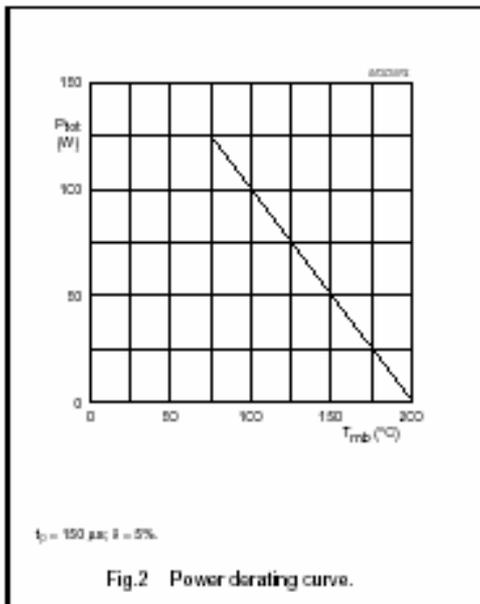
## NPN microwave power transistor

RZ1214B35Y

## LIMITING VALUES

In accordance with the Absolute Maximum Rating System (IEC 134).

SYMBOL	PARAMETER	CONDITIONS	MIN.	MAX.	UNIT
$V_{CB0}$	collector-base voltage	open emitter	-	65	V
$V_{CE0}$	collector-emitter voltage	open base	-	15	V
$V_{CES}$	collector-emitter voltage	$R_{EF} = 0 \Omega$	-	60	V
$V_{EB0}$	emitter-base voltage	open collector	-	3	V
$I_C$	collector current (DC)	$t_p \leq 150 \mu\text{s}; 8 \leq \delta\%$	-	3	A
$P_{tot}$	total power dissipation	$T_{mb} \leq 75^\circ\text{C};$ $t_p \leq 150 \mu\text{s}; 8 \leq \delta\%$	-	125	W
$T_{stg}$	storage temperature		-65	+200	$^\circ\text{C}$
$T_j$	operating junction temperature		-	200	$^\circ\text{C}$
$T_{sld}$	soldering temperature	at 0.2 mm from the case; $t \leq 10 \text{ s}$	-	235	$^\circ\text{C}$



## NPN microwave power transistor

RZ1214B35Y

## THERMAL CHARACTERISTICS

 $T_j = 75^\circ\text{C}$  unless otherwise specified

SYMBOL	PARAMETER	CONDITIONS	MAX.	UNIT
$R_{\theta(j-c)}$	thermal resistance from junction to mounting-base		5	K/W
$R_{\theta(c-h)}$	thermal resistance from mounting-base to heatsink	note 1	0.2	K/W
$Z_{\theta(j-h)}$	thermal resistance from junction to heatsink	$t_p = 100 \mu\text{s}$ ; $\delta = 10\%$ ; notes 1 and 2	1	K/W

## Notes

- See 'Mounting recommendations in the General part of handbook SC19a'.
- Equivalent thermal impedance under pulsed microwave operating conditions.

## CHARACTERISTICS

 $T_j = 25^\circ\text{C}$  unless otherwise specified.

SYMBOL	PARAMETER	CONDITIONS	MIN.	MAX.	UNIT
$V_{(BR)CBO}$	collector-base breakdown voltage	$I_C = 20 \text{ mA}$ ; $I_E = 0$	65	-	V
$V_{(BR)CES}$	collector-emitter breakdown voltage	$I_C = 20 \text{ mA}$ ; $R_{\theta(j-c)} = 0$	60	-	V
$V_{(BR)EBO}$	emitter-base breakdown voltage	$I_C = 0$ ; $I_E = 3 \text{ mA}$	3	-	V
$I_{CBO}$	collector cut-off current	$V_{CB} = 50 \text{ V}$ ; $I_E = 0$	-	2	mA
$I_{EBO}$	emitter cut-off current	$V_{EB} = 1.5 \text{ V}$ ; $I_C = 0$	-	0.2	mA

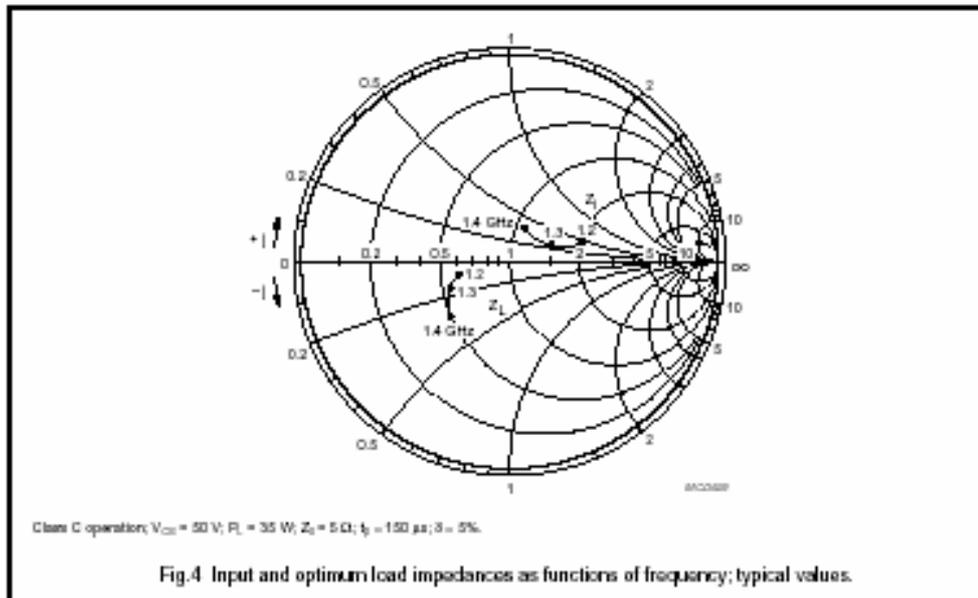
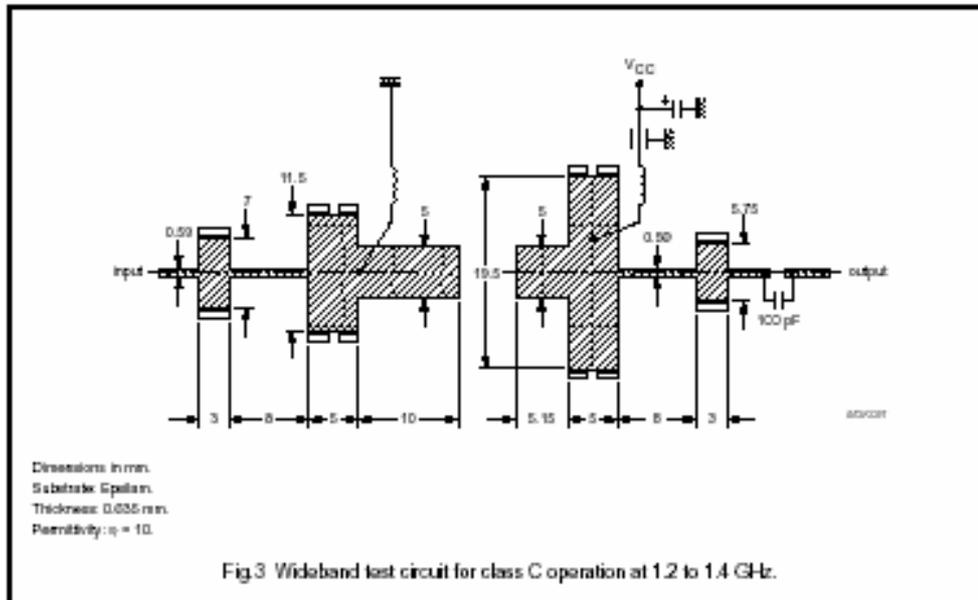
## APPLICATION INFORMATION

The transistors are 100% tested under the following conditions

MODE OF OPERATION	CONDITIONS	f (GHz)	$V_{CC}$ (V)	$P_L$ (W)	$G_p$ (dB)	$\gamma_c$ (%)	$Z_i$ ; $Z_L$ ( $\Omega$ )
Class-C	$t_p = 150 \mu\text{s}$ ; $\delta = 5\%$	1.2 to 1.4	50	typ.40; >35	typ.7.8; >7	typ.35; >35	see Fig 4
	$t_p = 300 \mu\text{s}$ ; $\delta = 10\%$	1.2 to 1.4	50	typ.40;	typ.7	typ.35	see Fig 4

NPN microwave power transistor

RZ1214B35Y





NPN microwave power transistor

RZ1214B35Y

## DEFINITIONS

Data Sheet Status	
Objective specification	This data sheet contains target or goal specifications for product development.
Preliminary specification	This data sheet contains preliminary data; supplementary data may be published later.
Product specification	This data sheet contains final product specifications.
Limiting values	
Limiting values given are in accordance with the Absolute Maximum Rating System (IEC 134). Stress above one or more of the limiting values may cause permanent damage to the device. These are stress ratings only and operation of the device at these or at any other conditions above those given in the Characteristics sections of the specification is not implied. Exposure to limiting values for extended periods may affect device reliability.	
Application information	
Where application information is given, it is advisory and does not form part of the specification.	

## LIFE SUPPORT APPLICATIONS

These products are not designed for use in life support appliances, devices, or systems where malfunction of these products can reasonably be expected to result in personal injury. Philips customers using or selling these products for use in such applications do so at their own risk and agree to fully indemnify Philips for any damages resulting from such improper use or sale.

## 8.3 MAX881R Data Sheet

29-7372 Rev 2-688



# MAXIM

## Low-Noise Bias Supply in $\mu$ MAX with Power-OK for GaAsFET PA

MAX881R

### General Description

The MAX881R low-noise, inverting power supply is designed for biasing GaAsFET power amplifiers in portable wireless applications. This device is a charge-pump inverter followed by a negative linear regulator. The input voltage range is 2.5V to 5.5V. The output is preset at -2.0V or can be set, using two resistors, to any voltage from -0.5V to  $(-V_{IN} + 0.6V)$ . It can deliver up to 4mA. The internal linear regulator also filters the output to 1mVp-p ripple and noise.

Other features include a power-OK (POR) output that signals when the negative voltage is within 7.5% of its set point. It protects the GaAsFET by not allowing power to be applied to the GaAsFET's drain until it is properly biased. The signal can be routed either to a microcontroller or directly to a switch at the GaAsFET drain. The MAX881R is available in a space-saving 10-pin  $\mu$ MAX package.

### Applications

- Cell Phones
- PCS Phones
- PHS Phones
- Wireless Handsets
- Wireless Modems
- Two-Way Pagers
- Mobile Radios
- Wireless Computers

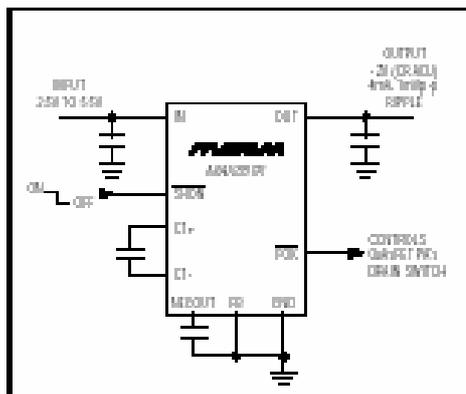
### Features

- + Small  $\mu$ MAX Package
- + 1mVp-p Output Voltage Ripple and Noise
- + Power-OK Signal to Control GaAsFET Drain Switch
- + 0.05 $\mu$ A Logic-Controlled Shutdown
- + 1ms Guaranteed Start-Up
- + 2.5V to 5.5V Input
- + -0.5V to  $(-V_{IN} + 0.6V)$  Output at up to 4mA
- + Operates with One 4.7 $\mu$ F and Three 0.22 $\mu$ F Capacitors (no Inductors needed)

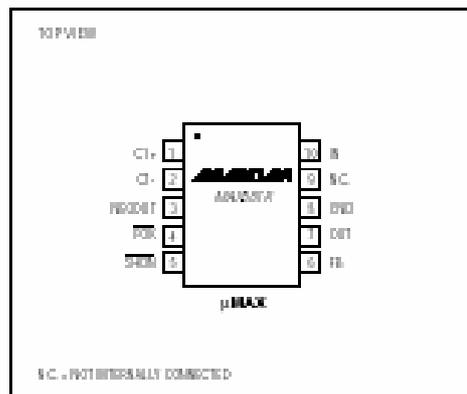
### Ordering Information

PART	TEMP. RANGE	PIN-PACKAGE
MAX881REUB	-40°C to +85°C	10 $\mu$ MAX

### Typical Operating Circuit



### Pin Configuration



Maxim Integrated Products 1

For free samples & the latest literature: <http://www.maxim-ic.com>, or phone 1-800-998-8800. For small orders, phone 408-737-7600 ext. 3468.

## Low-Noise Bias Supply in $\mu$ MAX with Power-OK for GaAsFET PA

### ABSOLUTE MAXIMUM RATINGS

IN to GND	-0.3V to +6V	Operating Temperature Range	-40°C to +85°C
SHDN to GND	-0.3V to +6V	Junction Temperature	+150°C
POK to GND	-0.3V to +1.2V	Storage Temperature Range	-65°C to +165°C
CI+ to GND	-0.3V to (V <sub>IN</sub> + 0.3V)	Lead Temperature (soldering, 10sec)	+300°C
CI-, NEEOOUT, OUT, FB to GND	-6V to (V <sub>IN</sub> + 0.3V)		
Continuous Power Dissipation (T <sub>A</sub> = +T <sub>0</sub> °C)			
10-Pin $\mu$ MAX (derate 5.6mW/°C above +70°C)	.....	444mW	

**Note 1:** The output may be shorted to NEEOOUT or GND if the package power dissipation is not exceeded. Typical short-circuit current is 35mA.

Stresses beyond those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. These are stress ratings only, and functional operation of the device at these or any other conditions beyond those indicated in the operational sections of the specifications is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.

### ELECTRICAL CHARACTERISTICS

[Circuit of Figure 3, V<sub>IN</sub> = +3.0V, FB = GND, R<sub>L</sub> =  $\infty$ , SHDN = FL, T<sub>A</sub> = -40°C to +85°C, unless otherwise noted. Typical values are at T<sub>A</sub> = +25°C.] (Note 2)

PARAMETER	SYMBOL	CONDITIONS	MIN	TYP	MAX	UNITS	
Supply Voltage Range	V <sub>IN</sub>		2.5		5.5	V	
Pre-set Output Voltage	V <sub>OUT</sub>	V <sub>IN</sub> $\geq$ 2.7V, I <sub>OUT</sub> = 0 to 4mA	-2.1	-2.0	-1.9	V	
Adjustable Output Voltage Range	V <sub>OUT</sub>	V <sub>IN</sub> $\geq$ 2.5V, I <sub>OUT</sub> = 0 to 4mA	-(V <sub>IN</sub> - 0.6)		-0.5	V	
FB Voltage	V <sub>FB</sub>	V <sub>IN</sub> $\geq$ 2.5V, I <sub>OUT</sub> = 0 to 4mA	T <sub>A</sub> = +25°C	-0.515	-0.5	-0.485	V
			T <sub>A</sub> = 0°C to +85°C	-0.525		-0.475	
			T <sub>A</sub> = -40°C to +85°C	-0.535		-0.465	
FB Input Current		V <sub>IN</sub> = 0.5V	-10	-100	nA		
Supply Current	I <sub>Q</sub>		500	950	$\mu$ A		
Shutdown Supply Current	I <sub>SHUT</sub>	SHDN = GND	0.05	1	$\mu$ A		
Output Load Regulation		V <sub>IN</sub> $\geq$ 2.7V, I <sub>OUT</sub> = 0 to 4mA	2	6	mV/mA		
Output Ripple		I <sub>OUT</sub> = 4mA, circuit of Figure 3b		1	mVpp		
Oscillator Frequency	f <sub>OSC</sub>		80	100	120	kHz	
POK Threshold		FB = OUT	90	92.5	95	% of V <sub>OUT</sub>	
POK Output Level		V <sub>IN</sub> $\geq$ 2.5V, sinking 1mA		100		mV	
POK Off Leakage Current		V <sub>POK</sub> = 11V		1		$\mu$ A	
SHDN Input High Voltage	V <sub>H</sub>	V <sub>IN</sub> = 5.5V	2.2			V	
SHDN Input Low Voltage	V <sub>L</sub>	V <sub>IN</sub> = 2.5V		0.35		V	
SHDN Input Current	I <sub>SHDN</sub>	Connected to IN or GND		+1		$\mu$ A	
SHDN Input Capacitance	C <sub>IN</sub>			10		pF	
Start-Up Time	t <sub>START</sub>	V <sub>IN</sub> = 3V, R <sub>L</sub> = 500 $\Omega$ , V <sub>SHDN</sub> = 0 to V <sub>IN</sub> , POK goes low		1		ms	

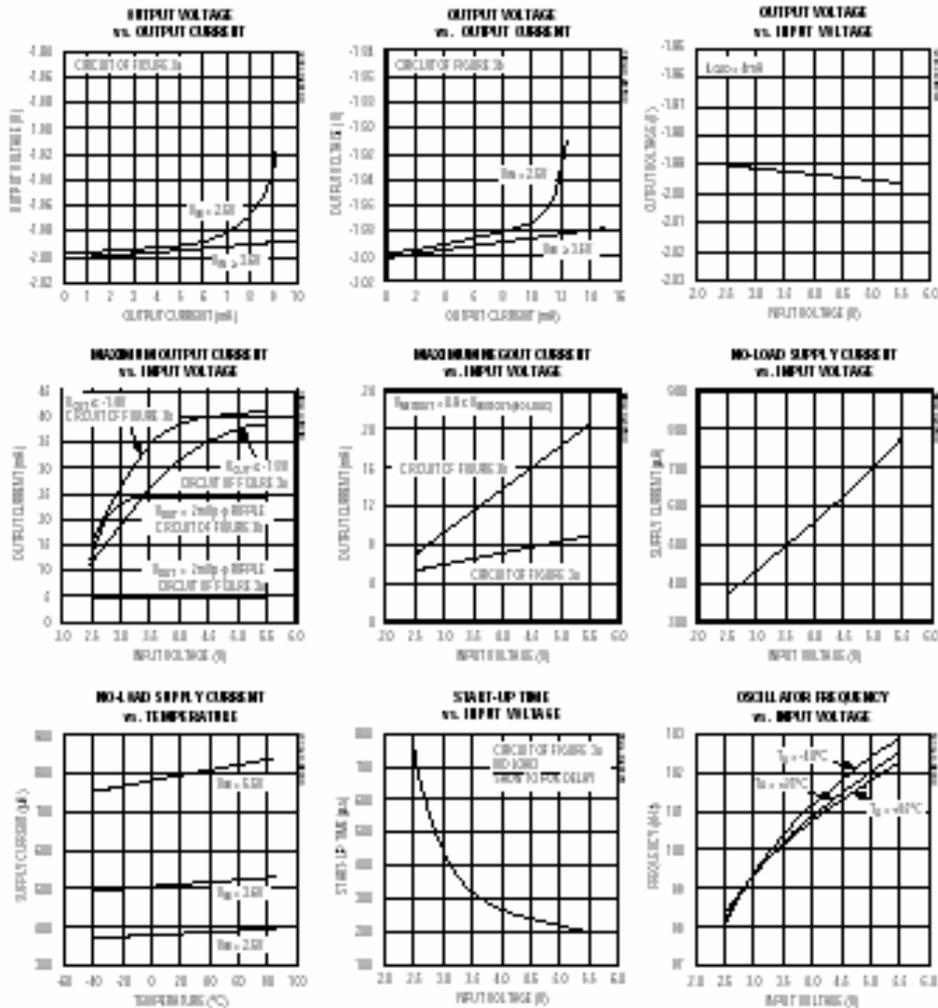
**Note 2:** Specifications to -40°C are guaranteed by design, not production tested.

# Low-Noise Bias Supply in $\mu$ MAX with Power-OK for GaAsFET PA

## Typical Operating Characteristics

(Circuit of Figure 3,  $V_{BI} = 3.0V$ ,  $T_A = +25^\circ C$ , unless otherwise noted.)

MAX881R



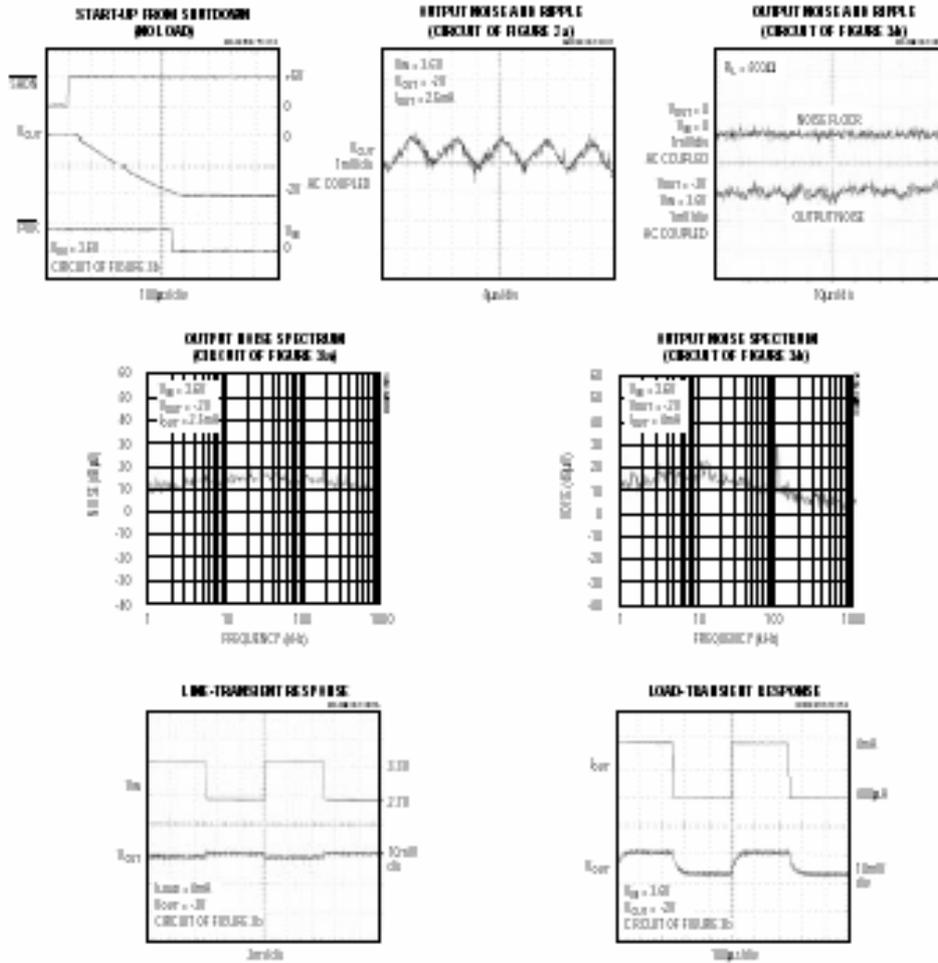
**MAXIM**

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# Low-Noise Bias Supply in $\mu$ MAX with Power-OK for GaAsFET PA

## Typical Operating Characteristics (continued)

(Circuit of Figure 3,  $V_{DD} = 1.0V$ ,  $T_A = +25^\circ C$ , unless otherwise noted.)



## Low-Noise Bias Supply in $\mu$ MAX with Power-OK for GaAsFET PA

### Pin Description

MAX881R

PIN	NAME	FUNCTION
1	C1+	Positive Terminal for C1
2	C1-	Negative Terminal for C1
3	NEGOUT	Negative Output Voltage (unregulated)
4	POK	Active-Loss, Open-Drain Power-OK Output. Goes low when OUT reaches 92.5% of its set value.
5	SHDN	Active-Loss, Logic-Level Shutdown Input. Connect to IN for normal operation. Do not leave this pin unconnected.
6	FB	Dual-Mode™ Feedback Input. When FB is connected to GND, the output is preset to -2V. To select other voltages, connect FB to an external resistor-divider (Figure 4). Do not leave this pin unconnected.
7	OUT	Regulated Negative Output Voltage
8	GND	Ground
9	N.C.	No Connection. Not internally connected.
10	IN	Positive Power-Supply Input

Dual-Mode is a trademark of Maxim Integrated Products.

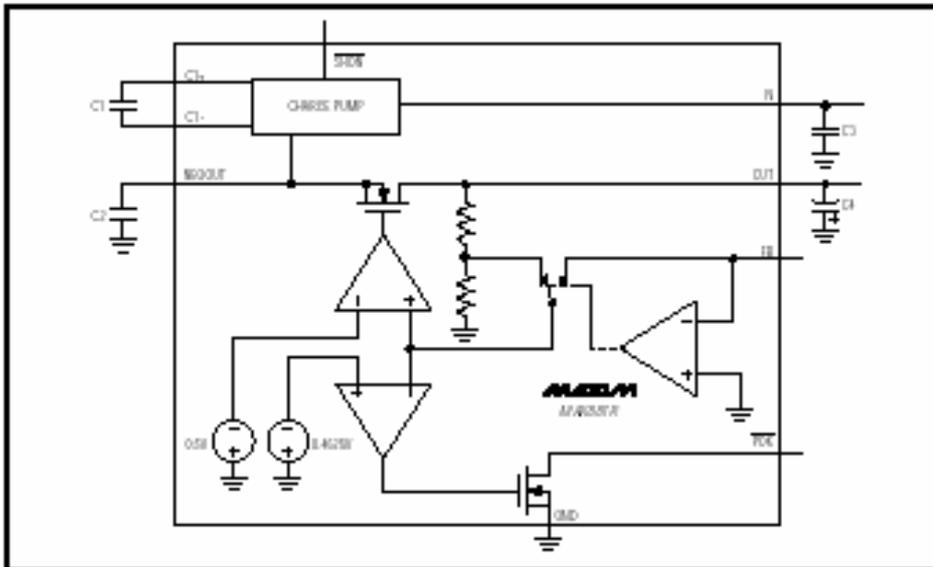


Figure 3. Functional Diagram

MAXIM

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## Low-Noise Bias Supply in $\mu$ MAX with Power-OK for GaAsFET PA

MAX881R

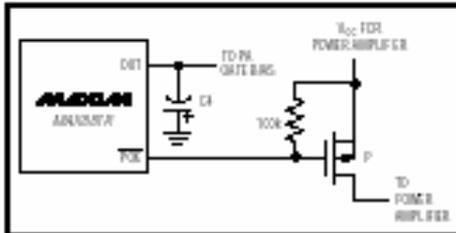


Figure 2. Using the POK Function

### Detailed Description

The MAX881R, a low-noise, inverting, regulated charge-pump power supply, is designed for biasing GaAsFET devices such as power-amplifier modules in cellular handsets.

The applied input voltage ( $V_{IN}$ ) is inverted to a negative voltage at NEGOUT by a capacitive charge pump. This voltage is regulated by an internal linear regulator at OUT (Figure 1). With FB connected to GND,  $V_{OUT}$  is regulated at  $-2V$ . Alternatively, use a voltage divider at FB to adjust the output voltage between  $-0.5V$  and  $-(V_{IN} - 0.6V)$  (see the section *Setting the Output Voltage*). The internal linear regulator reduces the ripple noise induced by the charge-pump inverter to  $1mV_{p-p}$  at OUT (circuit of Figure 3b). In addition, the excellent AC rejection of the linear regulator attenuates noise from the incoming supply.

### Power-OK Signal

The MAX881R has an active-low, open-drain, power-OK (POK) output. This output goes low when OUT reaches 92.5% of the regulated output voltage. POK can be used to drive the gate of a P-MOSFET that switches power to the GaAsFET power amplifier (Figure 2), thereby ensuring that the power amplifier is not powered before the required negative bias voltage is present.

Use a  $50k\Omega$  or larger pull-up resistor to signal a logic high when POK goes high impedance.

### Shutdown Mode

The MAX881R features a shutdown mode that reduces supply current to less than  $1\mu A$  over temperature. SPCRN is an active-low, logic-level input. Start-up time coming out of shutdown mode is typically 0.5ms. OUT and NEGOUT are switched to GND in shutdown mode.

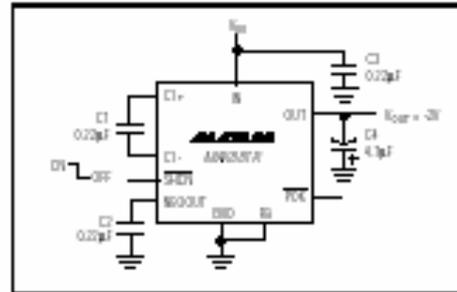


Figure 3a. Standard Application Circuit for Minimum Capacitor Values

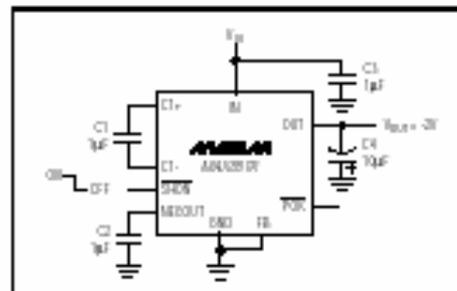


Figure 3b. Standard Application Circuit for Minimum Output Noise

### Applications Information

#### Setting the Output Voltage

Select either a fixed or adjustable output for the MAX881R. Connect FB to GND for a fixed  $-2V$  output (Figure 3). Select an alternative output voltage by connecting FB to the midpoint of a resistor divider from OUT to GND (Figure 4). When operating under full load (4mA), the voltage at IN should be at least  $0.6V$  higher than the absolute voltage required at OUT. Note that the minimum input voltage required for operation is  $2.5V$ , regardless of the desired output voltage. Choose  $R1$  to be between  $100k\Omega$  and  $400k\Omega$  and calculate  $R2$ . For greater accuracy, use resistors with 1% or better tolerance.

$$R2 = R1 (2 \times |V_{out}| - 1)$$

## Low-Noise Bias Supply in $\mu$ MAX with Power-OK for GaAsFET PA

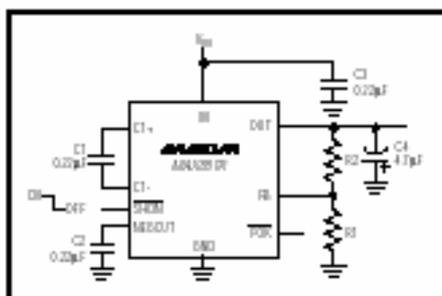


Figure 4. Adjustable Output Configuration

### Capacitors

Use capacitors with a low effective series resistance (ESR) to maintain a low dropout voltage ( $V_{IN} - V_{OUT}$ ). The overall dropout voltage is a function of the output resistance of the charge pump and the voltage drop across the linear regulator (N-channel pass transistor). At the 100kHz charge-pump switching frequency, output resistance is a function of the value of C1 and the ESR of C1 and C2. Therefore, increasing C1 and minimizing the ESR of the charge-pump capacitors minimizes dropout voltage.

The output resistance of the entire circuit (in dropout) is approximately:

$$R_{OUT} = R_{\Omega} + 4 \times ESR_{C1} + ESR_{C2} + 1 / (f_s \times C1) + R_{\Omega(\text{linear regulator})}$$

Where  $R_{\Omega(\text{linear regulator})}$  (the output impedance of the linear regulator) is approximately 2 $\Omega$  and  $R_{\Omega}$  (the resis-

tance of the internal switches) is typically 10 $\Omega$ . When regulating, the output resistance of the circuit is simply the linear-regulator load regulation (2mV/mA).

C1, C2, and C3 should be 0.22 $\mu$ F capacitors with less than 0.4 $\Omega$  ESR. C4 should be a 4.7 $\mu$ F capacitor with less than 0.1 $\Omega$  ESR. Larger capacitor values can be used (C1 = C2 = C3 = 1 $\mu$ F, C4 = 10 $\mu$ F) to reduce output noise and ripple (1mVp-p), at the expense of cost and board space. All capacitors should be either ceramic or surface-mount chip tantalum (Figures 3a and 3b).

### Layout and Grounding

Good layout is important for good noise performance. To optimize the layout:

- 1) Mount all components as close together as possible.
- 2) Keep traces short to minimize parasitic inductance and capacitance, especially connections to FB.
- 3) Use a ground plane.

### Noise and Ripple Measurement

Accurately measuring the output noise and ripple is a challenge. Slight momentary differences in ground potential between the circuit and the oscilloscope (which result from the charge pump's switching action) cause ground currents in the probe's wires, inducing sharp voltage spikes. For best results, measure directly across the output capacitor (C4). Do not use the ground lead of the probe; instead, remove the probe's lip cover and touch the ground ring on the probe directly to C4's ground terminal. This direct connection gives the most accurate noise and ripple measurement.

### Chip Information

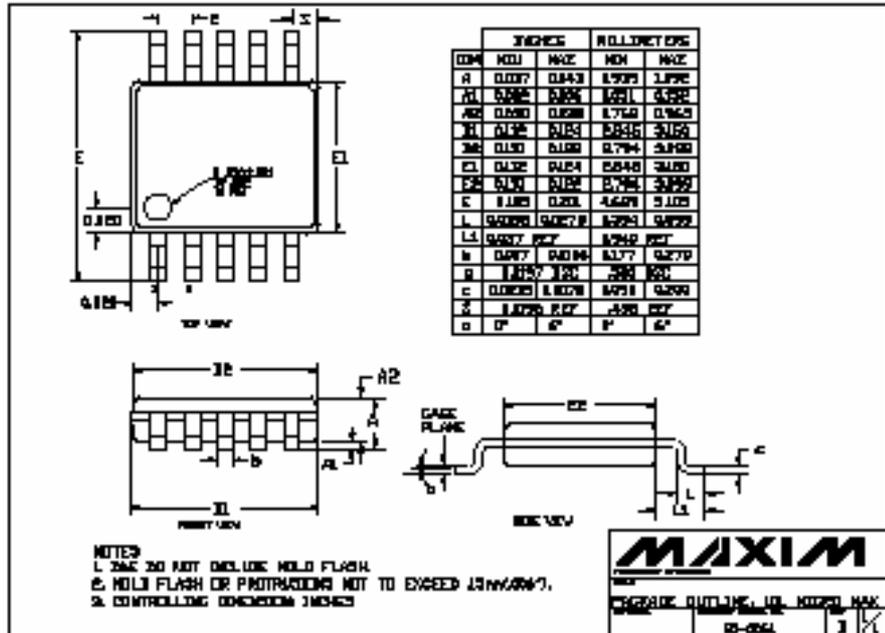
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MAX881R

# Low-Noise Bias Supply in $\mu$ MAX with Power-OK for GaAsFET PA

MAX881R

Package Information



## 9 Appendix C

### 9.1 Supportive information

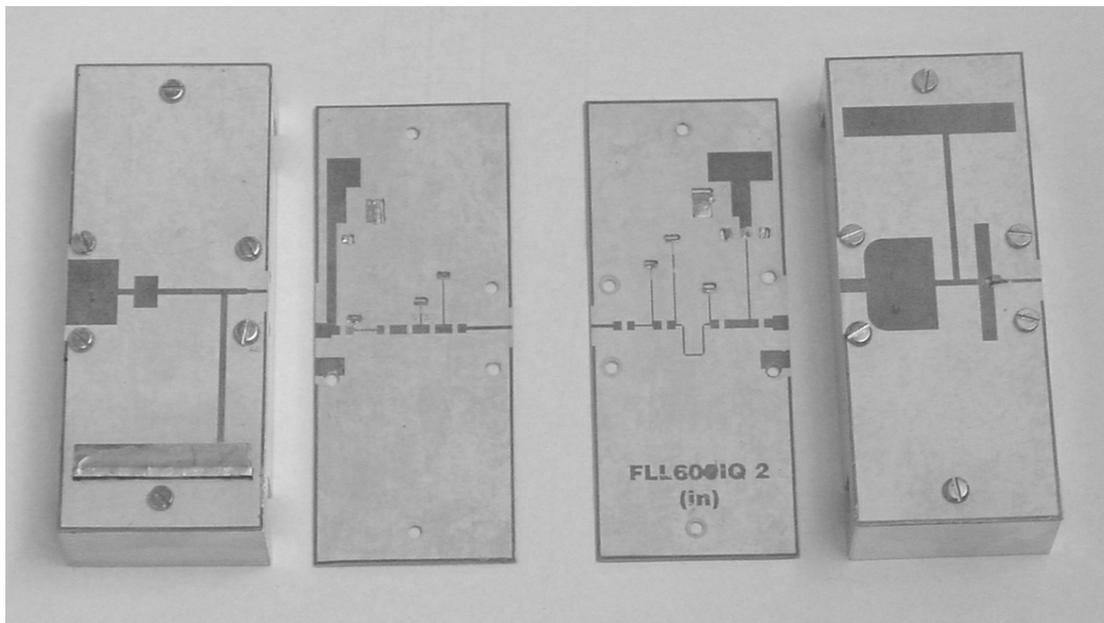


Figure 44. Examples of matching foils for evaluation.

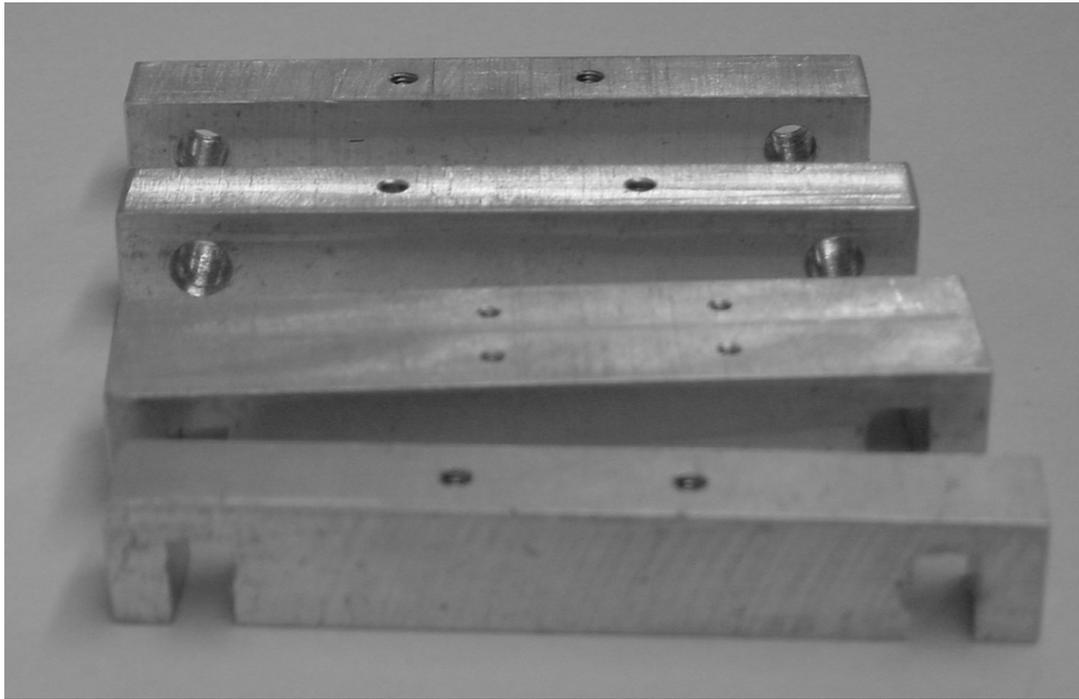


Figure 45. Examples of device mounting inserts.

